

# 12 MOS Model, level 903

## 12.1 Introduction

### General Remarks

MOS Model 9 is a compact MOS-transistor model, intended for the simulation of circuit behaviour with emphasis on analogue applications. The model gives a complete description of all transistor-action related quantities: nodal currents and charges, noise-power spectral densities and weak-avalanche currents. The equations describing these quantities are based on the gradual-channel approximation with a number of first-order corrections for small-size effects. The consistency is maintained by using the same carrier-density and electrical-field expressions in the calculation of all model quantities. Model 9 only provides a model for the intrinsic transistor. Junction charges and leakage currents are not included. They are covered by the separate **Juncap** model. Similarly, interconnect capacitances are deferred to the **Intcap** or **ConnectDPEM** model.

### Structural Elements of Model 9

Model 9 is separable into a number of relatively independent parts, namely

- **Preprocessing:** The complete set of all the parameters, as they occur in the equations for the various electrical quantities, is denoted as the set of actual parameters, usually called the "miniset". Each of these actual parameters can be determined by purely electrical measurements. Since most of these parameters scale with geometry and temperature the process as a whole is characterized by an enlarged set of parameters, which is denoted as the set of reference and scaling parameters, usually called the "maxiset". This set of parameters contains most of the actual parameters for a reference device, a large set of sensitivity coefficients and the reference conditions. From this, the actual parameters for an arbitrary transistor under non-reference conditions are obtained by applying a set of transformation rules to the reference parameters. The transformation rules describe the dependencies of the actual parameters on the length, width, and temperature. This procedure is called preprocessing, as it is normally done only once, prior to the actual electrical simulation.
- **Clipping:** For very uncommon geometries or temperatures, the preprocessing rules may generate parameters that are outside a physically realistic range or that may create difficulties in the numerical evaluation of the model, for example division by zero. In order to prevent this, all parameters are limited to a pre-specified range directly after the preprocessing. This procedure is called clipping.
- **Current equations:** These are all expressions needed to obtain the nodal currents as a function of the bias conditions. They are segmentable in equations for the channel current and for the bulk current. For the channel current many auxiliary equations are needed, e.g. equations for the threshold voltage including back-bias dependency and small-size correc-

tions, for the channel-conductance including mobility reduction and velocity saturation effects, and for the subthreshold region. These finally lead to an expression for the channel current  $I_{DS}$ . Due to the small device dimensions, high electrical fields occur, in particular in the vicinity of the drain. The carriers that are responsible for the channel current, can gain sufficient energy from this electrical field to induce electron-hole-pair creation. In turn, for an n-channel device, these extra electrons contribute to the channel current as do the holes to the bulk current. Vice versa, the same holds for p-channel devices.

- **Charge equations:** These are all the equations that are used to calculate the charge quantities  $Q_D$ ,  $Q_G$ ,  $Q_S$ , and  $Q_B$ , which are assigned to the nodes. To a large degree the same auxiliary expressions are used as for the current equations. In a few instances deviations were necessary for numerical reasons.
- **Noise equations:** The total noise output of a transistor consists of a thermal- and a flicker-noise part. They create fluctuations in the channel current. Because of the capacitive coupling between gate and channel region, also current fluctuations in the gate current are induced. These two aspects are covered in Model 9 by assigning two correlated noise-current sources, one connected between drain and source, the other one between gate and source, and an uncorrelated noise-current source between drain and source. The correlated current sources are directional!
- **Embedding model 9:** The electrical model only describes the behaviour of an n-channel device. Therefore, any p-channel device and its bias conditions have to be mapped onto those of an equivalent n-channel transistor. This mapping comprises a number of sign-changes. Also, the model describes a symmetrical device, i.e. the source and drain nodes can be interchanged without changing the electrical properties. The assignment of source and drain to the channel nodes is based on the voltages of these nodes: for an n-channel transistor the node at the highest potential is called the drain. In a circuit simulator the nodes are denoted by their network numbers, based on the circuit configuration. Again, a transformation is necessary involving a number of sign changes, including the directional noise-current sources.

### 12.1.1 Changes from MOS level 902

- A new flicker noise model has been added, which can be selected by setting the switch NFMOD to 1. Selecting the default value NFMOD = 0 yields the previous level 902 flicker noise model. In this way backwards compatibility is achieved.

- The coefficients  $W_{DOG}$  and  $f_{\theta_1}$  have been put in their logical position in the list of scaling parameters.
- In Pstar 4.0, two bugs have been fixed. First, the  $\theta_3$ -clipping is removed and is circumvented by using suitable ‘hyp-functions’. Second, the back-bias range described by the model is extended from  $-0.5\phi_B$  to  $-0.9\phi_B$ .

### New geometry scaling rules

- New scaling rules have been implemented in MOS Model 9 for the parameters in the electrical model indicated in the table below. These new scaling rules lead to a considerably improved modelling accuracy, especially for devices with pocket implantations.

Parameter description	Parameter electrical model	New parameter geometrical model
Gain factor	$\beta$	$f_{\beta, 1}, L_{P, 1}$ $f_{\beta, 2}, L_{P, 2}$
Body effect at low back-bias	$K_0$	$S_{L2;K_0}$
Body effect at high back-bias	$K$	$S_{L2;K}$
Threshold voltage	$V_{T0}$	$S_{L3;V_{T0}}$
Drain-induced barrier-lowering	$\gamma_{00}$	$S_{L2;\gamma_{00}}$
Mobility reduction	$\theta_1$	$g_{\theta_1}$

- The default values of the new parameters have been chosen in such a way that the adapted model is backwards compatible. If they are not specified, you won’t notice the change.

## 12.2 Physics

### 12.2.1 Comments and Physical Background

#### Current Model

A key parameter in any MOST model is the threshold voltage. Basically this voltage results from a balance between the gate and the substrate charge. The expression (12.5) used in this model has been obtained via calculation of the depletion charge in a substrate with a threshold adjustment implant. In this calculation the Gaussian-type doping profile has been replaced by a box-type profile. Since the depletion charge is determined by the integral substrate doping rather than by the actual profile, such a simplification is allowed in practice [1]. The parameter  $V_{SBX}$  is the back-bias value, at which the implanted layer becomes fully depleted. In addition the above result has the advantage that the parameters  $K_0$  and  $K$  can be easily determined from the slope of the  $V_T$  versus  $V_{SB}$  plot. Figure 34 gives a typical result for an implanted p-type substrate.

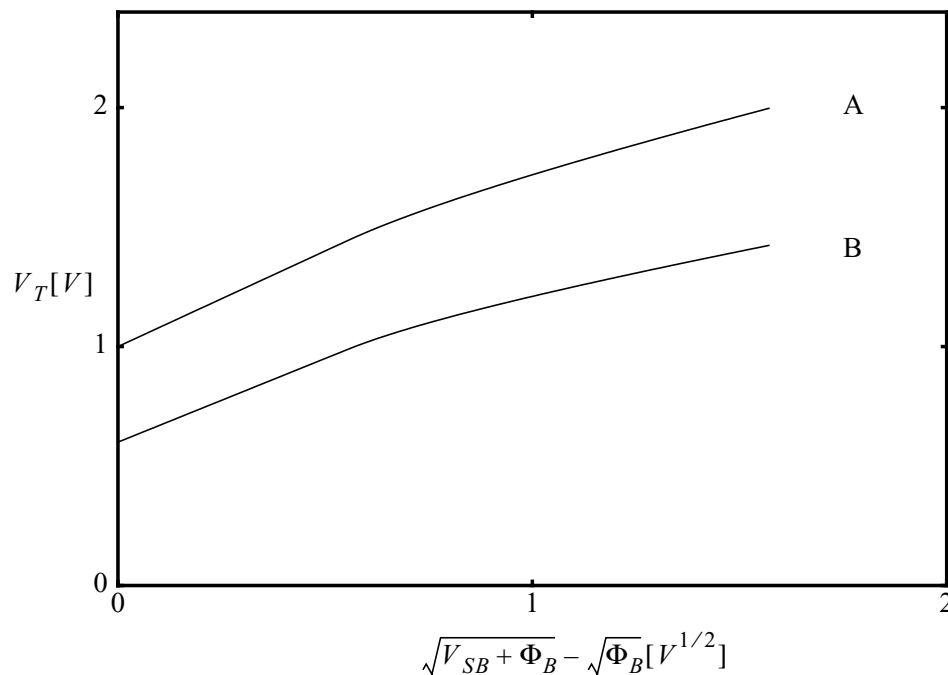


Figure 34: Threshold voltage  $V_T$  vs. back bias voltage for two different processes

Furthermore, relation (12.5) even holds for a situation, where the substrate doping increases at larger depth. This might occur for a p-channel device in a retrograde well. However usu-

ally the threshold voltage of a p-channel is controlled by a single body coefficient. In this case  $K = K_0$  and  $\Delta V_{T0} = K_0 \cdot (u_s - u_{s0})$ , and Eq. (12.5) has to be used.

The easiest way to implement the single body coefficient in the model is by making  $K = K_0$  and giving  $V_{SBX}$  a high value (e.g. 100).

In small devices the above threshold voltage usually is changed due to two effects. In short-channel devices depletion from the source and drain junctions causes less gate charge to be required to turn on the transistors. On the other hand in narrow-channel devices the extension of the depletion layer under the isolation causes more gate charge to be required to form a channel. Usually these effects can be modeled by geometrical preprocessing rules:

$$\begin{aligned}\tilde{V}_{T0} &= V_{T0R} + (T_{KD} - T_{KR}) \cdot S_{T;V_{T0}} \\ V_{T0} &= \tilde{V}_{T0} + \left(\frac{1}{L_E} - \frac{1}{L_{ER}}\right) \cdot S_{L;V_{T0}} + \left(\frac{1}{L_E^2} - \frac{1}{L_{ER}^2}\right) \cdot S_{L;V_{T0}} + \left(\frac{1}{W_E} - \frac{1}{W_{ER}}\right) \cdot S_{W;V_{T0}} \\ K &= K_R + \left(\frac{1}{L_E} - \frac{1}{L_{ER}}\right) \cdot S_{L;K} + \left(\frac{1}{W_E} - \frac{1}{W_{ER}}\right) \cdot S_{W;K}\end{aligned}$$

etc., which follow from physical considerations [1]. When measuring the threshold voltage of p-channel transistors a so called roll-up of this parameter is found as the length decreases. As for the Philips processes this effect is quite significant the preprocessing rule has been altered. For n-channels the advantage is that so called enhanced roll-down of the parameter  $V_{T0}$  can now also easily be modelled. Figure 35 is a picture of  $V_{T0}$  vs.  $1/L_{\text{eff}}$  for a p-channel. At large values of drain bias the drain depletion layer further expands and may affect in case of short channels the potential barrier between the source region and the channel area. Consequently the subthreshold current increases with drain bias. In order to guarantee a smooth transition between the latter operation mode and the strong inversion mode, the above effect is interpreted as an apparent change of the threshold voltage or as an increase of the effective gate drive. This drain bias voltage dependence is expressed in detail, by the first part of Eq. (12.11). At higher back bias voltage the drain-induced effect further increases according to Eq. (12.8). For a uniform substrate doping, the latter expression follows from an approximate solution of the 2-D Poisson equation [1]. In this case  $\eta_{\gamma} = 1$ . For an implanted substrate no satisfactory analytic expression has been obtained yet. However empirically it is found that Eq. (12.8) adequately describes measured subthreshold characteristics, the value of  $\eta_{\gamma} = 2$  is used. This is shown in Figure 36. Once an inversion layer has been formed at higher values of gate bias, an increase of drain bias induces an additional increase of inversion charge at the drain end of the channel (static feedback effect). This can be interpreted as another change of effective gate drive and has been modeled by the second part of Eq. (12.11). From first order

calculations and experimental results the exponent  $\eta_{DS}$  is found to have a value of  $1/2$ . In order to guarantee a smooth transition between subthreshold and strong-inversion mode, the model constant  $V_{GTX} = \sqrt{2}/2$  has been introduced in (12.11). When  $V_{GT1} \leq V_{GTX}$ , the subthreshold effect dominates. However, when  $V_{GT1} \geq V_{GTX}$ , the latter effect soon is overtaken by the static feedback effect. Note that  $\gamma_0$  for implanted substrates strongly increases with back bias, while  $\gamma_1$  does not depend on  $V_{SB}$ . This implies that the increase of  $\gamma_0$  with  $V_{SB}$  cannot continue beyond some high  $V_{SB}$  value. Otherwise large nonmonotonic behaviour of  $I_{DS}$  versus  $V_{SB}$  would be observed. Since the limitation of  $\gamma_0$  usually occurs outside the practical range of  $V_{SB}$  values, a simple purely mathematical limiting procedure has been chosen.

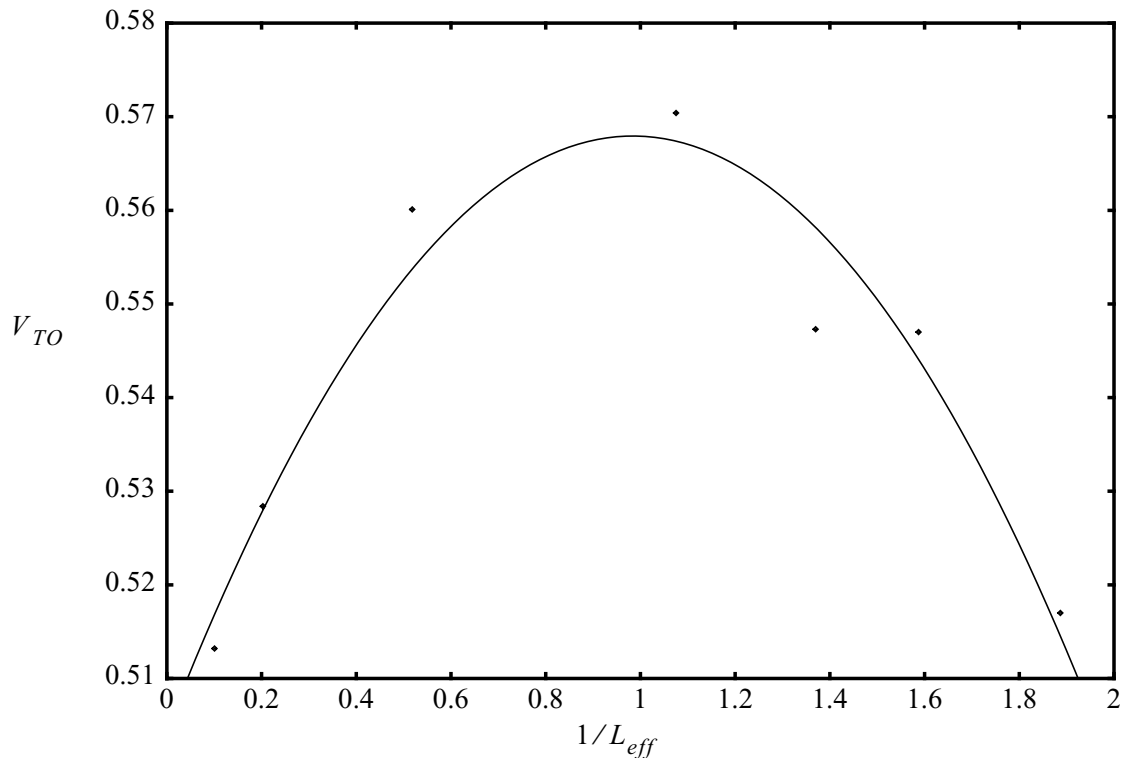


Figure 35: Influence of the effective channel length on  $V_{T0}$  for a p-channel device

In Figure 36 it is further shown that the subthreshold slope depends on the back bias applied. This is caused by the fact that the gate control of the potential barrier between source and channel is affected by the value of the depletion charge [2]. For uniformly doped substrates the slope factor  $m$  is given by Eq. (12.14), where the exponent  $\eta_m$  equals 1. The latter result follows from a straight forward solution of Poisson's equation. For implanted substrates the situation is more complicated. Empirically it is found that Eq. (12.14) still suffices, provided that the value of  $\eta_m$  is taken 2 (follows from Figure 36 as well).

A smooth transition between the subthreshold current and the current in strong inversion is further guaranteed by the manipulation given in Eqs. (12.15) and (12.16) [3]. When  $V_{GT2}$  is negative (subthreshold regime)  $G_1$  becomes small and a Taylor expression of Eq. (12.16) results in an exponential dependence of the drain current on gate bias. On the other hand, when  $V_{GT2} = kT/q$ , (strong inversion regime),  $G \gg 1$  and  $V_{GT3}$  simply reduces to the linear relation Eq. (12.13).

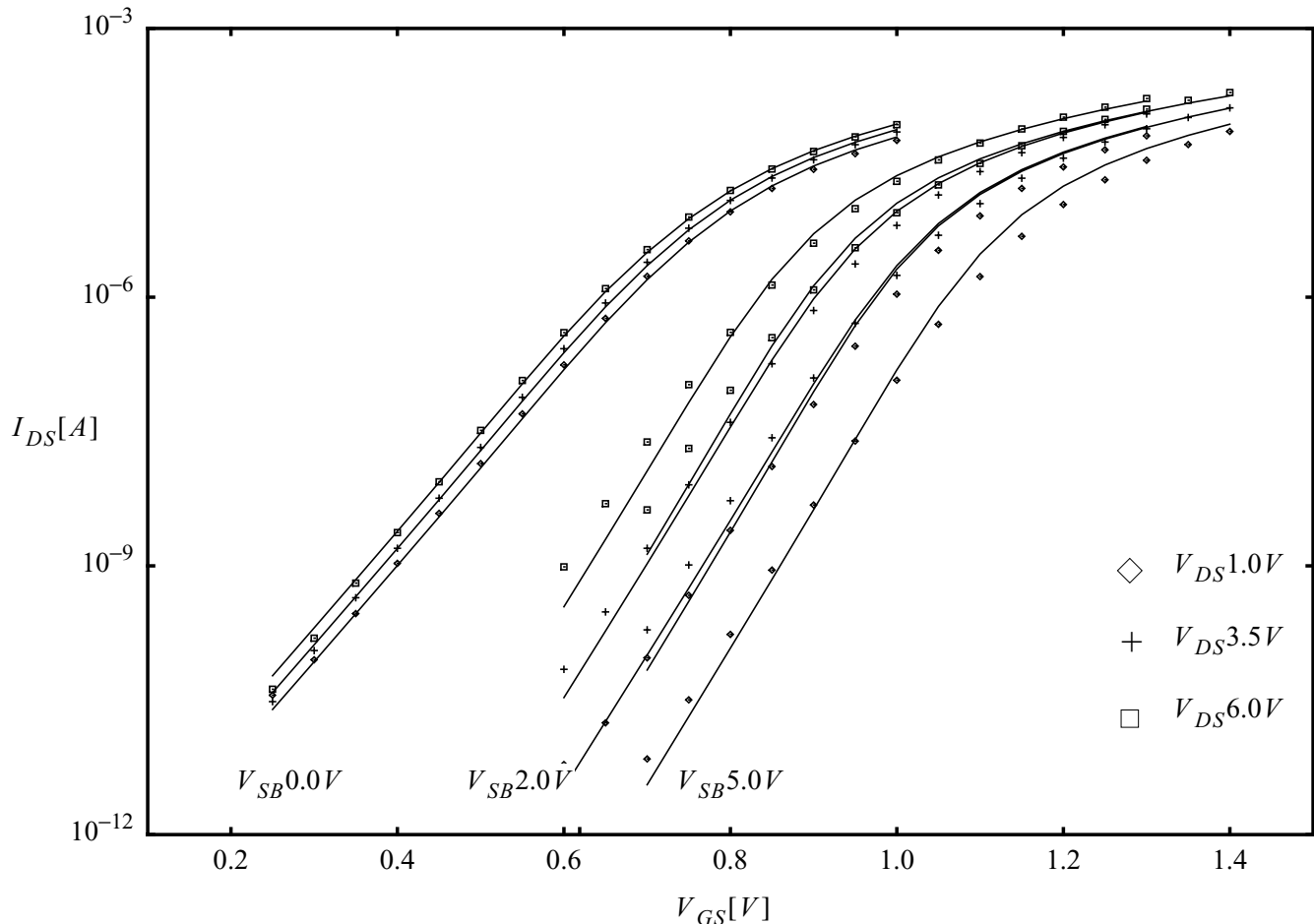


Figure 36: Calculated and measured subthreshold chars. for n-channel transistor, at different back bias voltages (0, 2 and 5 Volts); the calculated characteristics are presented by fully drawn lines, the measured characteristics are presented by marks!

Next comes the effect of the backbias on the  $I_{DS} - V_{DS}$  characteristics. When the drain bias is increased, the depletion charge under the drain end of the channel is increased too. Since the latter increase causes a decrease of the mobile carrier charge, the drain current and its saturation voltage are affected too. Taking into account velocity saturation, the saturation voltage expression Eq. (12.20) of model 7 is maintained. However the representation of the depletion

charge effect via the  $\delta$ -term in Eq. (12.19) becomes more complicated in case of implanted substrates. For further details we refer to [1]. Note that if  $K = K_0$ , Eq. (12.19) reduces to the simple expression used in model 7.

Although the saturation voltage expression Eq. (12.20) from model 7 has been adopted for physics based reasons, for analog application a slight modification is required. If Eq. (12.20) is substituted in the current expression and for instance, the static feedback effect according to Eq. (12.11) is taken into account, the calculated drain conductance agrees very well with the measured values in the linear and the saturation region, but near  $V_{DSS}$  large deviations occur. This is shown in Figure 37.

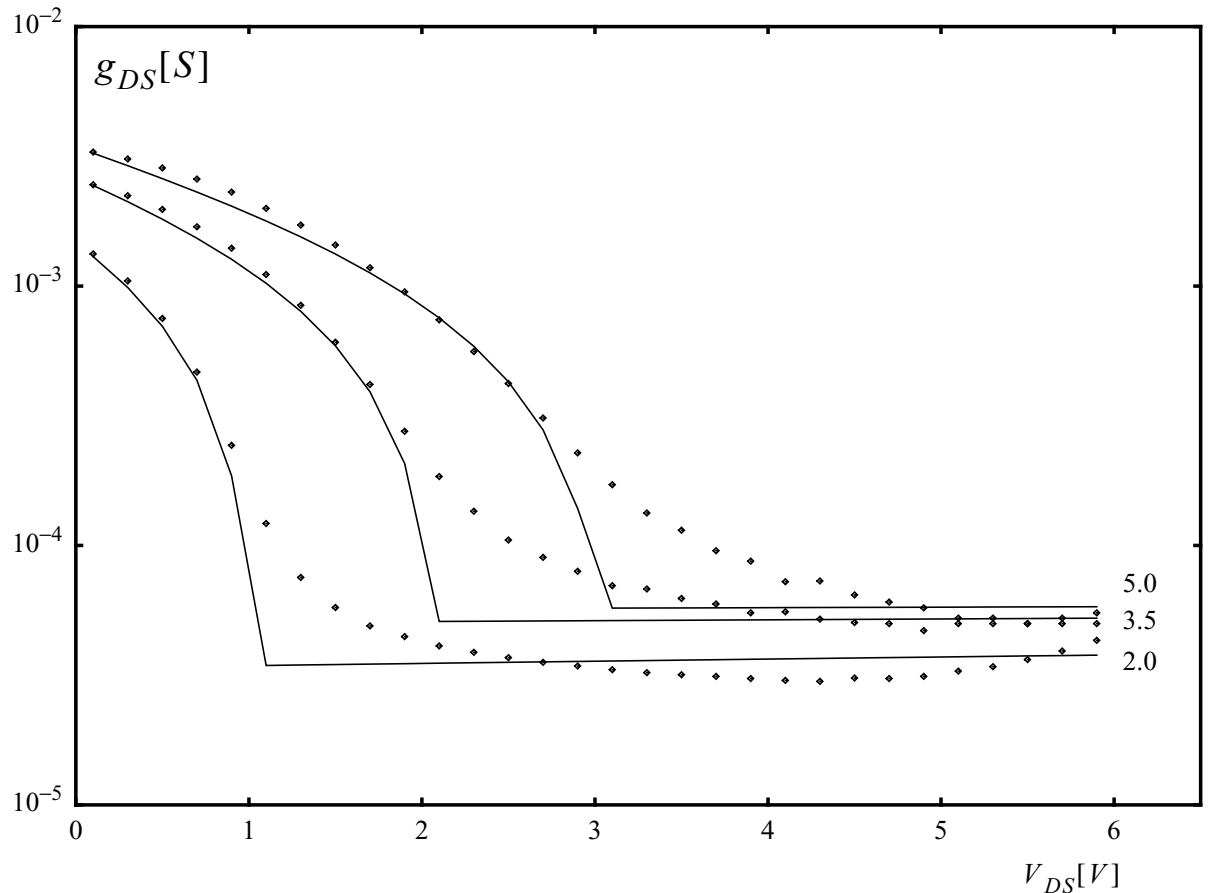


Figure 37: Drain conductance vs. drain-source voltage

These are caused by the fact that the underlying procedure for calculation  $V_{DSS}$  does not require continuity of the second derivative of  $I_{DS}$ . Since no satisfactory physical arguments can be given to provide this continuity and mathematical arguments lead to too low values of  $V_{DSS}$ , continuity of the second derivative of  $I_{DS}$  has been enforced by introducing Eqs. (12.24) and (12.23). In fact these equations cause a round off of the sudden transition of  $V_{DSS}$ , which

is controlled by the model constant  $\lambda_3$ . A value  $\lambda_3 = 0.3$  has been chosen to compromise between inaccuracies in drain conductance and the current value at small values of  $V_{DS}$ . Figure 38 gives the model variable  $V_{DS1}$  as a function of  $V_{DS}$ . One of the major shortcomings of model 7 for analog applications is the neglect of channel length reduction at increased values of  $V_{DS}$ . This causes the drain conductance calculated according to the static feed back mechanism to depend incorrectly on  $V_{GS}$  for long n-channel and p-channel devices.

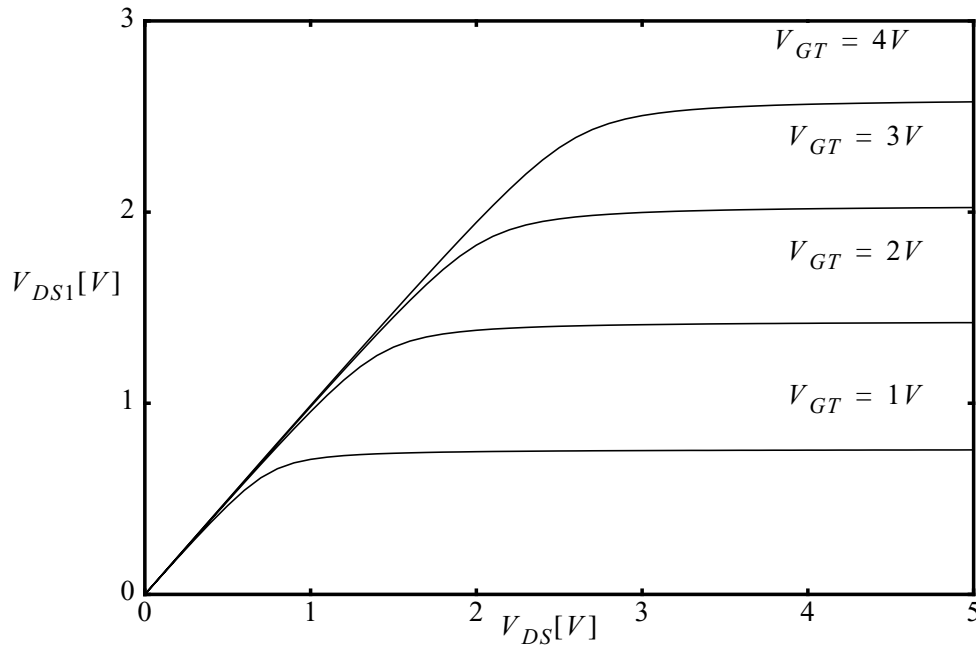


Figure 38: Model variable  $V_{DS1}$  as a function of the drain-source voltage  $V_{DS}$

From the many published formulations for channel length shortening, which all lack a strict physics base, Eq. (12.26), which is a modification of one proposal [1], has been found to give the best results in practice. This is shown for the drain conductance of p-channel devices in Figure 39. Although the present formulations give satisfactory results for all practical situations, the measured drain conductance of short-channel n-type devices shows some anomalies, which cannot be explained by the present model. As shown by Figure 40, the saturated drain conductance increases at high values of  $V_{DS}$ , whereas the calculated values decrease with  $V_{DS}$ .

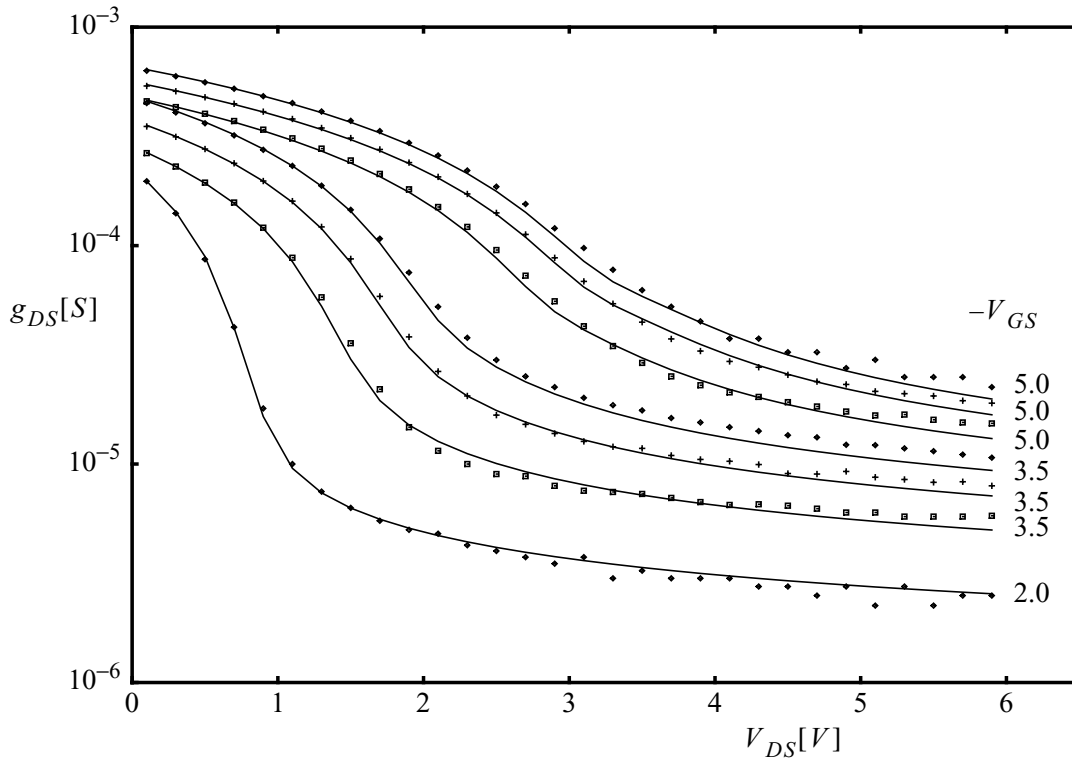


Figure 39: Drain conductance as a function of the drain-source voltage  $V_{DS}$  for p-channel transistors at different back bias voltages (0, 2 and 5 Volts); the calculated characteristics are presented by fully drawn lines, the measured characteristics are presented by marks!

A second anomaly appearing only in short-channel n-type transistors, is the increase of  $g_{DS}$  at larger values of  $V_{SB}$ . In contrast to this, the model forecasts in agreement with experimental findings for p-channel (see Figure 39) and longer n-channel devices a decrease of  $g_{DS}$  with  $V_{SB}$ .

Since one single expression Eq. (12.27) for the current is used to cover all ranges of bias voltages, the manipulation Eq. (12.26) is needed to obtain a correct saturation of the subthreshold current. While the saturation voltage  $V_{DSS}$  increases with  $V_{GS}$  in strong inversion, in the sub-

threshold region the current saturates according to:  $1 - \exp\left(\frac{-V_{DS}}{\phi_T}\right)$

This difference in saturation is enforced by the manipulation according to Eq. (12.26).

Despite all the improvements discussed above, the current equation Eq. (12.27) still has the same form as in model 7 with the exception of the mobility reduction term  $\theta_2 (u_s - u_{s0})$ . The present formulation, which is based on physical arguments [1] has the advantage that its effect on the characteristics disappears, when  $V_{SB}$  approaches zero.

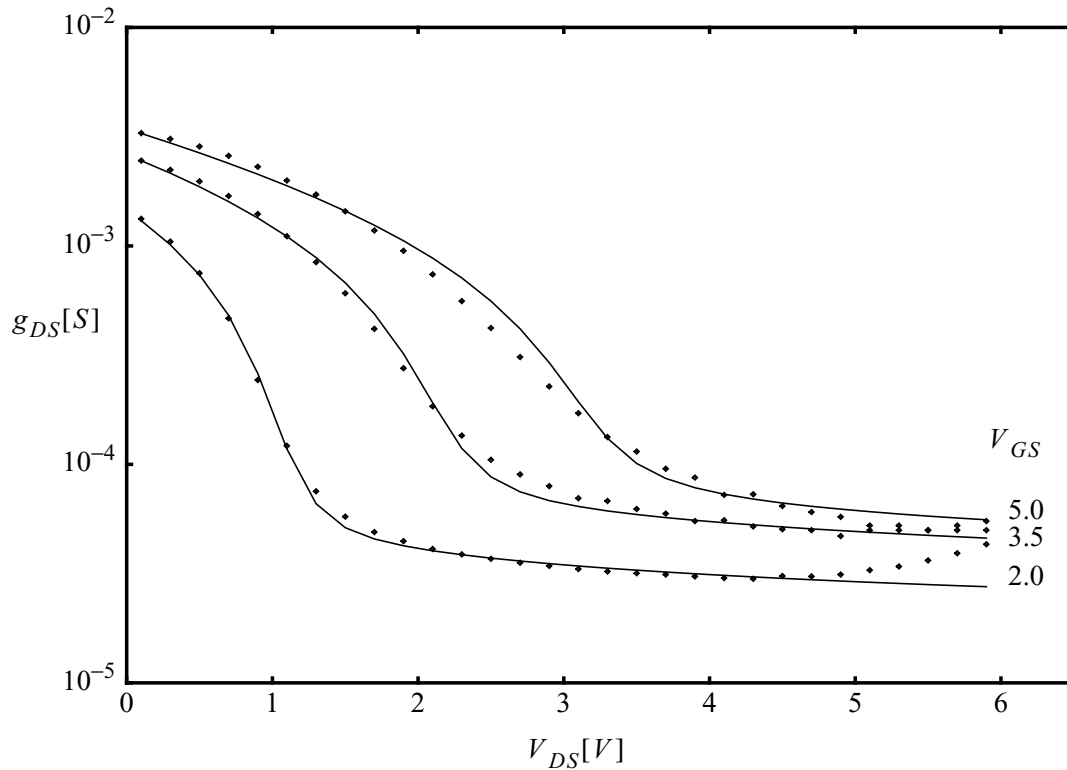


Figure 40: Calculated and measured drain conductance vs. drain-source for n-channel transistor at back bias voltage  $V_{SB}=0$  Volt; the calculated characteristics are presented by fully drawn lines, the measured characteristics are presented by marks!

Therefore, the value of  $\theta_2$  does not affect the value of  $\beta$  during parameter extraction. Similar to their use in model 7,  $\theta_1$  and  $\theta_3$  originally represent mobility reduction due the normal and lateral field. However a calculation of the effects of a source and drain series resistance in the characteristics of short-channel devices has shown that Eq. (12.27) can be maintained provided that a much wider significance is assigned to the parameters  $\theta_1$  and  $\theta_3$  [1]. Generally their value is determined by:

$$\theta_1 = \theta_{10} + (R_S + R_D) \cdot \beta$$

$$\theta_3 \approx \theta_{30} - R_D \cdot \beta$$

In the above relations  $\theta_{10}$  and  $\theta_{30}$  are the original mobility reduction parameters,  $(R_S + R_D) \cdot \beta$  and  $R_D \cdot \beta$  represent the effect of the series resistance. This result makes it possible to take the effects of series resistance into account and leads to geometrical scaling rules for  $\theta_1$  and  $\theta_3$ . Recently, the effect of dogboning (the phenomenon that the contacted area of a narrow device is broader than the channel) on the series resistance, and thus on  $\theta_1$  has led to an additional term in the scaling rule for devices that exhibit dogboning [5] and [6].

The inclusion of series resistance in the  $\theta$  parameters saves internal nodes in the model, thus reducing CPU time during circuit simulation. In addition the form of the model suits the usual measuring procedures. Generally  $(R_S + R_D)$  can be obtained from the slope of a plot of  $\theta_1$  versus  $\beta$ , using a series of MOSFETs with a fixed width and varying channel length. The intercept with the  $\theta_1$ -axis yields  $\theta_{10}$ . An example is given in Figure 41.

### **New technologies**

In new CMOS technologies the dopant concentration varies along the channel due to e.g. pocket implants. Consequently the mobility, and thus the gain factor  $\beta_{sq}$  becomes a function of channel length. To take this effect into account the geometrical scaling rules of the gain factor, the threshold voltage, the drain-induced barrier-lowering parameter  $\gamma_{00}$  and of the mobility reduction parameter  $\theta_1$  have been adapted. At the same time a quadratic term in the geometrical scaling rules of the body-effect factors has been added.

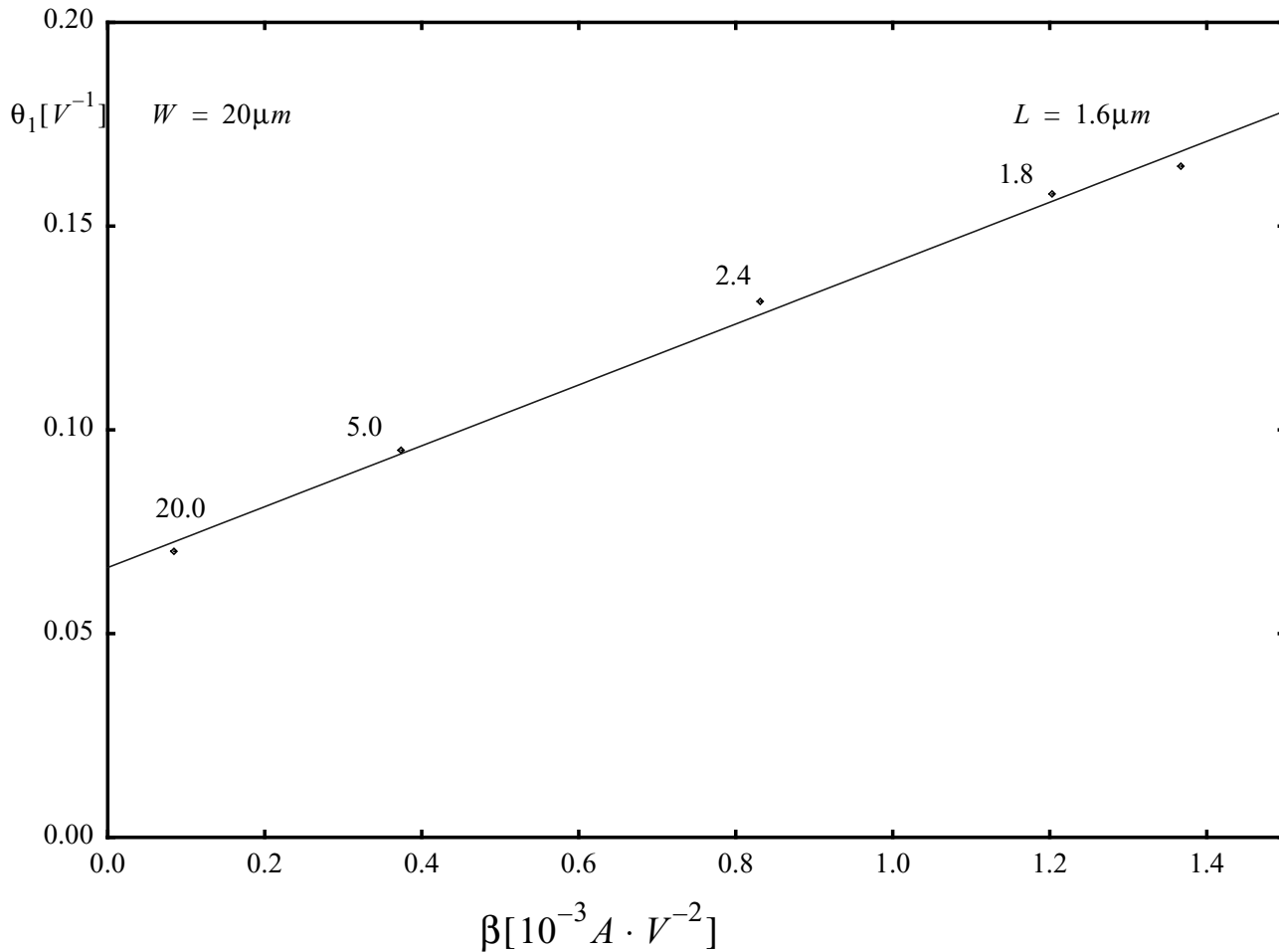


Figure 41:  $\theta_1$  vs.  $\beta$  for obtaining  $R_S + R_D$

### Charge Model

Compared to model 7 the calculations of the charges  $Q_S$  and  $Q_D$  is based on a more firm physical basis. In fact the results Eqs. (12.38) and (12.39) are obtained from the definitions:

$$Q_S = -\frac{1}{L} \int_0^L qn(x) \left(1 - \frac{x}{L}\right) dx$$

$$Q_D = -\frac{1}{L} \int_0^L qn(x) \frac{x}{L} dx$$

which have been derived along different lines of approach [3] and [4]. In the above relations the integration with respect to  $x$  can be replaced by integrating with respect to the potential  $V$ , making use of the current equation. This has the advantage that the charge equations become compatible to the drain current equations. Generally the Eqs. (12.38) and (12.39) produce expressions for the major capacitances, which agree with published measured characteristics. An example is given in Figure 42. However, compared to model 7,  $Q_S$  and  $Q_D$  and their derivatives do not cause numerical problems, when the transistor switches from the forward to the inverse mode ( $V_{DB} \leq V_{SB}$ ). This is illustrated by the 3-D plot of Figure 43, where the drain charge (normalized with respect to the gate oxide capacitance value) is given as a function of  $V_D$  and  $V_S$ . Since the  $V_S = V_D$  line forms the boundary between the forward and the inverse mode, actually the left-hand part of the figure shows the  $Q_S$  expression. At the boundary a smooth transition between  $Q_S$  and  $Q_D$  is observed. At low values of  $V_{SB}$  and  $V_{DB}$  the MOSFET operates in the linear mode. Therefore at  $V_{SB} = V_{DB} = 0$  Volt the maximum value of  $Q_D$  is reached. At low values of  $V_{SB}$  and high values of  $V_{DB}$ , the transistor operates in the forward saturation mode. In this case  $Q_D$  has a lower value than for the inverse saturation mode [1]. When both  $V_{SB}$  and  $V_{DB}$  are large, the device operates in the subthreshold mode and the active charges are virtually zero within the scale of this figure. Actually the charges considered decrease exponentially towards zero owing to the  $V_{GT3}$  term.

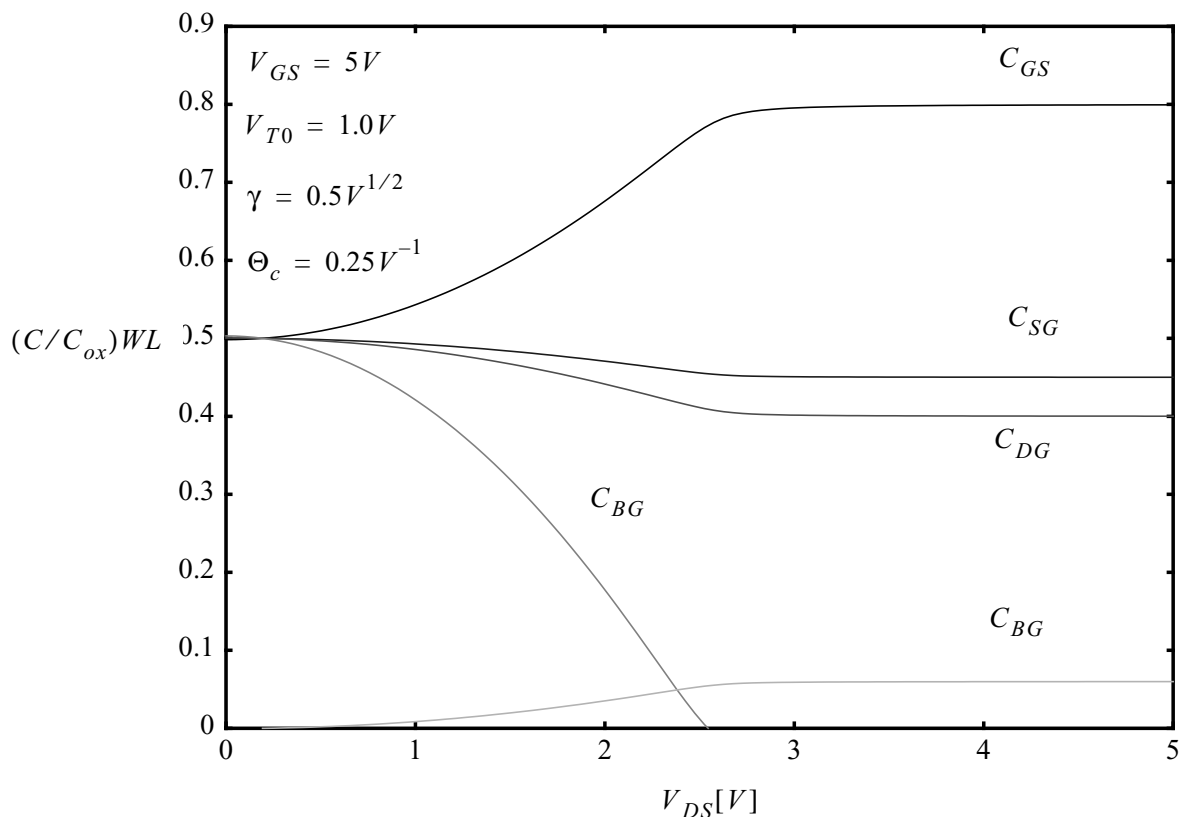


Figure 42: Capacitances as a function of drain-source voltage

Although generally the charges behave in a compatible manner to the drain current, one exception must be emphasized. For reasons of avoiding numerical problems, the  $\delta$ -expression Eq. (12.19) has to be changed. This is caused by the fact that Eq. (12.19) is not the derivative of the threshold expression Eq. (12.7). This inequality then causes  $dQ_D / dV_S$  and  $dQ_S / dV_D$  to become discontinuous at  $V_{SB} = V_{DB}$ . In model 7 this fact has caused major problems. Fortunately, since  $Q_S$  and  $Q_D$  are hardly dependent on the value of  $\delta$ , a simple solution can be found by defining for the charge model only:

$$\delta = \frac{dV_T}{dV_S}$$

However this is not the only measure to be taken to guarantee continuity of the charge derivatives at all boundaries of bias conditions. In fact the threshold expression Eq. (12.5) has the problem that its second derivative is discontinuous at  $V_{SBX}$ . Therefore if  $\delta$  is defined according to the above definition, discontinuity problems in the capacitance expressions have to be

expected. Therefore for implementation in a circuit simulator, the physical relations Eq. (12.5) has been replaced by a more smooth mathematical relation, which produces in practice deviations of the threshold voltage less than 5 milli-Volts.

The bulk charge given in Eq. (12.42) has been obtained from a solution of Poisson's equation applied to the depletion layer. The result has been plotted in Figure 44. Compared to model 7, the present  $Q_B$  is a more symmetrical function of  $V_{SB}$  and  $V_{DB}$ . When  $V_{SB}$  and  $V_{DB}$  are low, an inversion layer exists. In this case the negative charge of  $Q_B$  increases with  $V_{DS}$ , but does not depend on  $V_{GB}$ . At large values of  $V_{DB}$ , saturation occurs and  $Q_D$  hardly increases further. When a back bias  $V_{SB}$  is applied,  $Q_B$  increases again due to the expanding depletion layer. Finally at large values of  $V_{SB}$  the device operates in the subthreshold mode, where  $Q_B$  no longer depends on  $V_{SB}$  or  $V_{DB}$ , but only on the variable  $V_{GB}$  [1], [2].

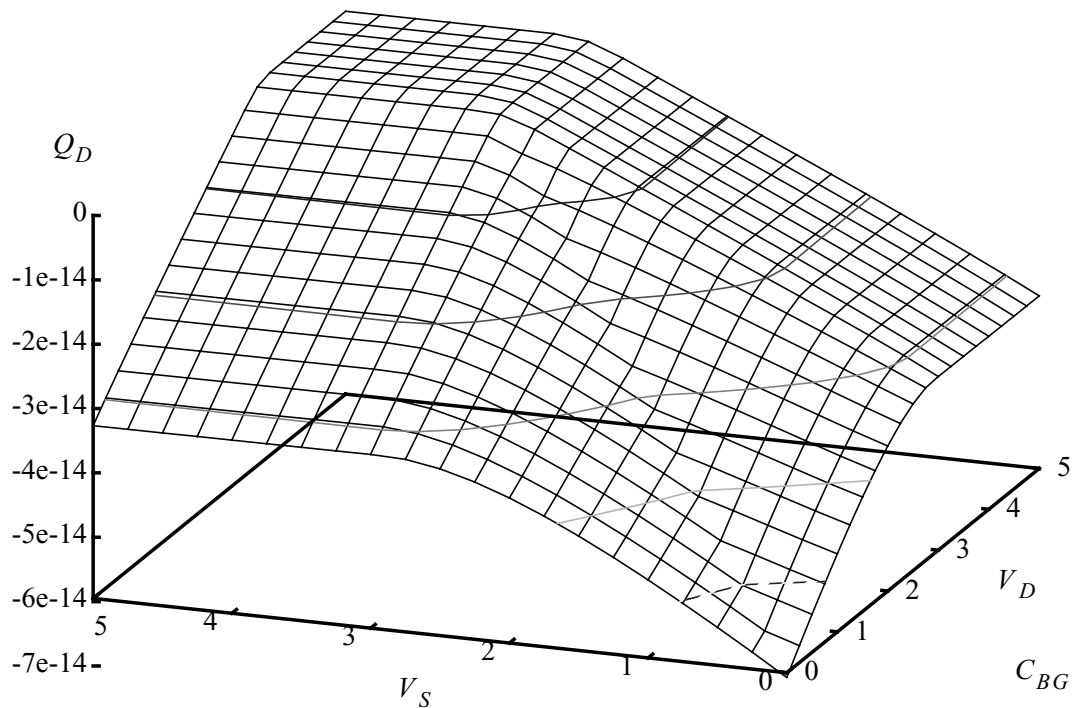


Figure 43: Drain charge as a function of  $V_D$  and  $V_S$

Since some derivatives of the physical expressions Eq. (12.42) produce discontinuities at some boundaries, for implementation in a circuit simulator the above equations are modified by applying several hyp-functions. For details we refer to the specific section on this subject.

Finally, we remark that the above charge model is quasi-static. A phase-shift between drain current and gate voltage is not taken into account. This implies that for a few applications at high frequencies approaching the cut-off frequency, errors in a.c. calculations have to be expected.

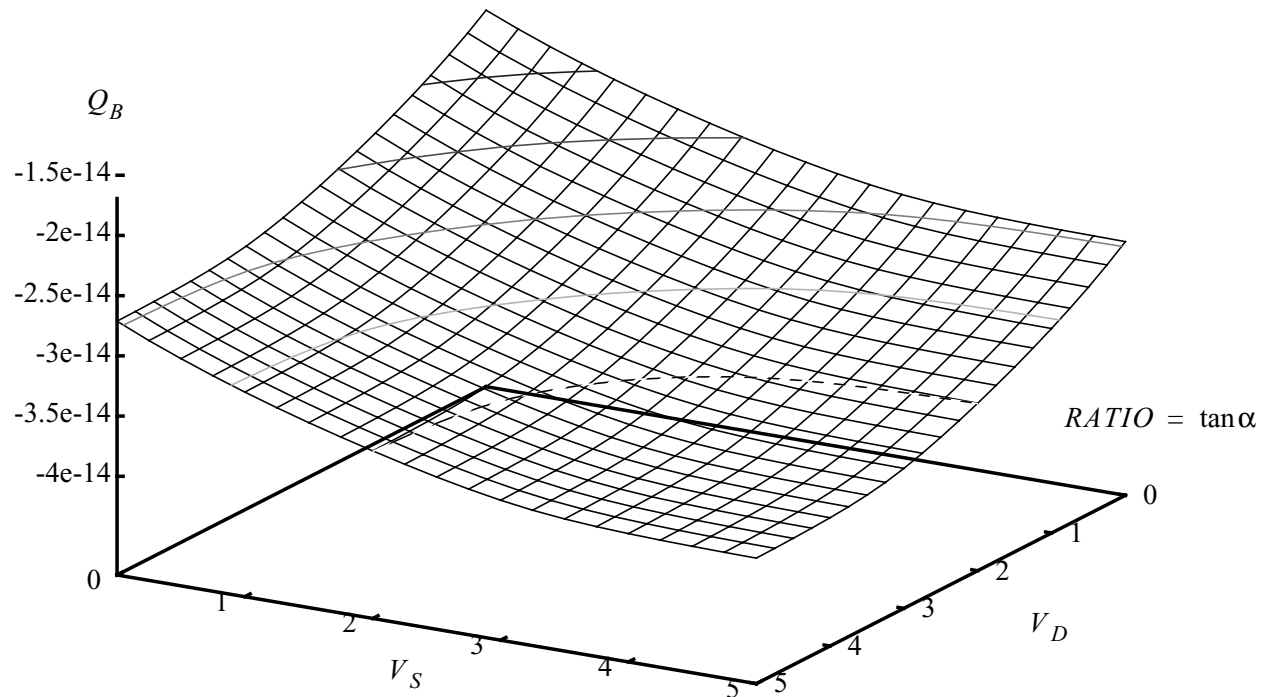


Figure 44: Bulk charge  $Q_B$  as a function of  $V_S$  and  $V_D$

## Noise Model

Since the MOSFET channel can be considered as a non-linear resistor, the channel current is subject to thermal noise. In these equations  $f$  represents the operation frequency of the transistor. Let thermal-noise current sources be parallel connected to each infinitesimal short element of the channel, it can be shown [1] that the noise spectral density, which is defined by:

$$\langle \Delta I_{th}^2 \rangle = \int_0^{\infty} S_{th}(f) df,$$

is given by a generalized Nyquist relation:

$$S_{th} = \frac{4 \cdot k \cdot T_{KD}}{L^2} \int_0^L g(x) dx,$$

where  $g(x)$  is the local specific channel conductance. Elaborating the latter integral via a transform of the  $x$ -variable into the potential  $V(x)$ , we obtain the first equation from (12.51). In fact the latter result only applies to the strong inversion mode of operation. In the sub-threshold mode the channel is not present and current transport occurs via emission of carriers across the source-channel potential barrier. Therefore in this region shot noise have been observed:

$$S_{sh} = 2 \cdot q \cdot I_{DS}$$

Making use of the generalized gate-drive definition (12.16), we can show that the second equation from (12.51) has the same quantitative value as the shot noise expression. In this way continuity of the noise model is assured along all possible modes of operation. Often a noise level in excess of the Nyquist value is observed. The reason for this is not yet clear! Therefore a parameter  $N_T$  has been introduced; usually  $4k T_{KD} < N_T < 8k T_{KD}$ . Owing to capacitive coupling between gate and channel, the fluctuating channel current induces noise in the gate terminal at high frequencies. Unfortunately the calculation of this component from first principles is too complicated to provide a result applicable to circuit simulation. It is more practical to derive the desired result from an equivalent circuit presentation given in Figure 45. Owing to the mentioned capacitive coupling, a part of the channel is present as a resistance in series with the gate input capacitance:

$$R_i = \frac{1}{3 \cdot g_m}$$

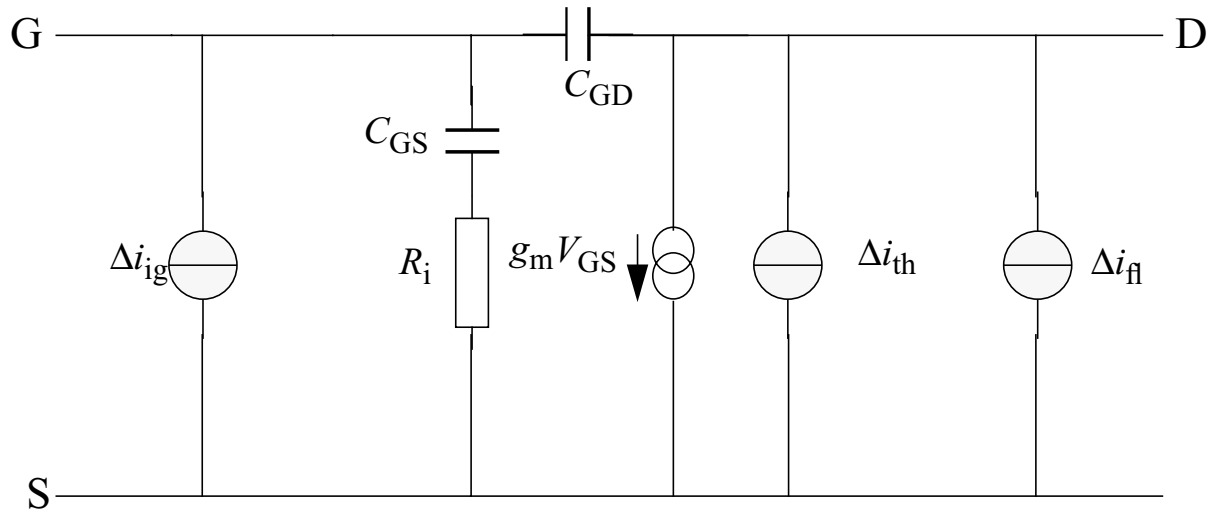


Figure 45: Noise current sources in the electrical scheme of the MOS transistor

It can be easily shown that the latter resistance produces an input noise current with a spectral density given by Eqn. (12.59). In addition, since  $\Delta i_{th}$  and  $\Delta i_{ig}$  have the same physical source, both spectral densities are correlated. This is expressed by Eqs. (12.60) and (12.61). Usually thermal noise is not the only source of noise present. At low frequencies flicker (or  $1/f$ ) noise  $\Delta i_{fl}$  becomes dominant in MOSFETs.

A typical noise spectrum is given in Figure 46.

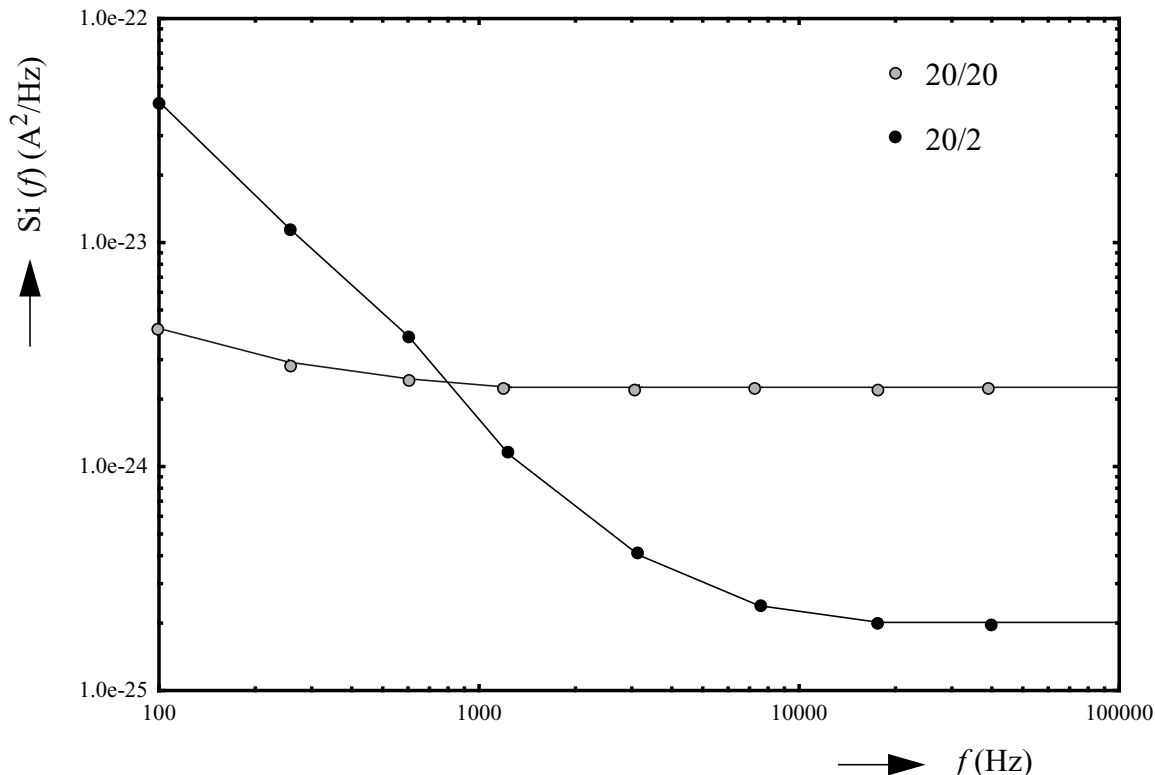


Figure 46: Noise Spectrum for a MOSFET

Generally this type of noise has been interpreted in terms of trapping via surface states or in terms of mobility fluctuation. In MOS MODEL 9, level 903, one can choose between two flicker noise models, selectable via the switch NFMOD.

Selecting NFMOD = 0 activates the flicker noise model of MOS MODEL 9, level 902. This model assumes the input-referred voltage noise:

$$S_{fl}/g_m^2$$

to be bias independent. In practice, however, it was found that there is a bias dependence of this input-referred voltage noise, in particular for p-channels. The noise parameter  $N_{FR}$  for this model is determined for the most useful bias condition, namely  $V_T < V_{GS} < V_T + 1.0V$  and  $V_{DS}$  above the saturation voltage. Care should be taken with the outcome of the model at other bias conditions!

NFMOD =1 selects the new flicker noise model, which distinguishes level 903 from level 902. The model, described in detail in [7], [8], [9] assumes trapping of charge carriers in traps located at various depths in the gate oxide. The trapping causes both the mobility and the carrier number to fluctuate in a correlated fashion. Each trapping center is associated with a Lorentzian noise spectral density with a particular knee-frequency. The distribution of trapping depths causes the individual Lorentzians to merge into a  $1/f$  spectrum. The model is valid in all operating regions of the MOSFET. Some modelling results are shown in Figure 47.

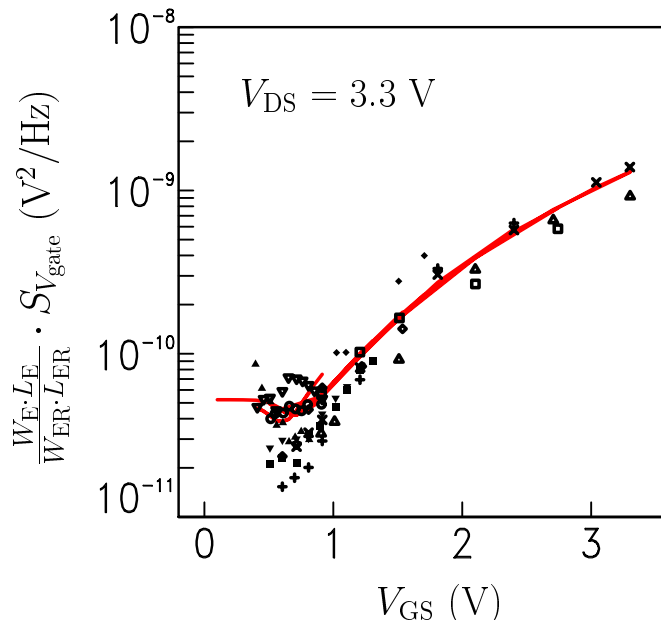


Figure 47: The input-referred  $1/f$  noise at 1 Hz, multiplied by  $W_E L_E / (W_{ER} L_{ER})$ , as a function of gate-source voltage, for C075 p-channel MOSFETs. Different symbols correspond to measurements on 11 different geometries. The solid line represents the new  $1/f$  noise model (NFMOD = 1).

This  $1/f$  noise model is also found in BSIM3v3. In the subthreshold regime however, the implementation differs slightly from the BSIM3v3 implementation: (i) the correct expression for  $N''$  is used, and (ii) the transition between weak and strong inversion regimes has been smoothed. The BSIM3v3  $1/f$  noise parameters NOIA (in  $V^{-1}m^{-3}$ ), NOIB (in  $V^{-1}m^{-1}$ ) and NOIC (in  $V^{-1}m$ ) are found by multiplying the MOS MODEL 9 parameters  $N_{FAR}$ ,  $N_{FBR}$  and  $N_{FCR}$  by the factor:

$$0.01 \times W_{ER} \times L_{ER} \times \gamma_{oxide}$$

where  $\gamma_{oxide} = 10^{10} \text{ m}^{-1}$  is the attenuation coefficient of the electron wave function in the gate oxide.

## 12.2.2 Basic Equations

The equations listed in the following sections, are the basic equations of MOST model 9 without any adaptation necessary for numerical reasons. As such they form the base for parameter extraction. The definitions of the hyp functions, which provide for a smooth clipping, are found in appendix *A Hyp functions*.

### Current Equations

$$u_s = \sqrt{V_{SB} + \phi_B} \quad (12.1)$$

$$u_{s0} = \sqrt{\phi_B} \quad (12.2)$$

$$u_{st} = \sqrt{V_{SBT} + \phi_B} \quad (12.3)$$

$$u_{sx} = \sqrt{V_{SBX} + \phi_B} \quad (12.4)$$

$$\Delta V_{T0} = \begin{cases} K_0 \cdot (u_s - u_{s0}), & u_s < u_{sx} \\ \left[ 1 - \left( \frac{K}{K_0} \right)^2 \right] \cdot K_0 \cdot u_{sx} - K_0 \cdot u_{s0} \\ + K \cdot \sqrt{u_s^2 - \left[ 1 - \left( \frac{K}{K_0} \right)^2 \right] \cdot u_{sx}^2}, & u_s \geq u_{sx} \end{cases} \quad (12.5)$$

$$V_{T1} = V_{T0} + \Delta V_{T0} \quad (12.6)$$

$$u_{s1} = \begin{cases} u_s, & u_s \leq u_{st} \\ u_{st}, & u_s > u_{st} \end{cases} \quad (12.7)$$

$$\gamma_0 = \gamma_{00} \cdot \left( \frac{u_{s1}}{u_{s0}} \right)^{\eta_r} \quad (12.8)$$

$$V_{GT1} = \begin{cases} V_{GS} - V_{T1}, & V_{GS} \geq V_{T1} \\ 0, & V_{GS} < V_{T1} \end{cases} \quad (12.9)$$

$$V_{GTX} = \frac{1}{2} \cdot \sqrt{2} \quad (12.10)$$

$$\Delta V_{T1} = -\gamma_0 \cdot \frac{V_{GTX}^2}{V_{GTX}^2 + V_{GT1}^2} \cdot V_{DS} - \gamma_1 \cdot \frac{V_{GT1}^2}{V_{GTX}^2 + V_{GT1}^2} \cdot V_{DS}^{\eta_{DS}} \quad (12.11)$$

$$V_{T2} = V_{T1} + \Delta V_{T1} \quad (12.12)$$

$$V_{GT2} = V_{GS} - V_{T2} \quad (12.13)$$

$$m = 1 + m_0 \cdot \left( \frac{u_{s0}}{u_{s1}} \right)^{\eta_m} \quad (12.14)$$

$$G_1 = \exp\left( \frac{V_{GT2}}{2 \cdot m \cdot \phi_T} \right) \quad (12.15)$$

$$V_{GT3} = 2 \cdot m \cdot \phi_T \cdot \ln(1 + G_1) \quad (12.16)$$

$$\lambda_1 = 0.3 \quad (12.17)$$

$$\lambda_2 = 0.1 \quad (12.18)$$

$$\delta_1 = \frac{\lambda_1}{u_s} \cdot \left\{ K + \frac{(K_0 - K) \cdot V_{SBX}^2}{V_{SBX}^2 + (\lambda_2 \cdot V_{GT1} + V_{SB})^2} \right\} \quad (12.19)$$

$$V_{DSS1} = \frac{V_{GT3}}{1 + \delta_1} \cdot \frac{2}{1 + \sqrt{1 + \frac{2 \cdot \theta_3 \cdot V_{GT3}}{1 + \delta_1}}} \quad (12.20)$$

$$\lambda_3 = 0.3 \quad (12.21)$$

$$V_{DSSX} = 1 \quad (12.22)$$

$$\epsilon_3 = \lambda_3 \cdot \frac{V_{DSS1}}{V_{DSSX} + V_{DSS1}} \quad (12.23)$$

$$V_{DS1} = \text{hyp}_5(V_{DS}; V_{DSS1}, \epsilon_3) \quad (12.24)$$

$$G_2 = 1 + \alpha \cdot \ln\left(1 + \frac{V_{DS} - V_{DS1}}{V_P}\right) \quad (12.25)$$

$$G_3 = \frac{\zeta_1 \cdot \left\{ 1 - \exp\left(\frac{-V_{DS}}{\phi_T}\right) \right\} + G_1 \cdot G_2}{\frac{1}{\zeta_1} + G_1} \quad (12.26)$$

$$I_{DS} = \beta \cdot G_3 \cdot \frac{V_{GT3} \cdot V_{DS1} - \left(\frac{1 + \delta_1}{2}\right) \cdot V_{DS1}^2}{\{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\} \cdot (1 + \theta_3 \cdot V_{DS1})} \quad (12.27)$$

$$V_{DSA} = a_3 \cdot V_{DSS1} \quad (12.28)$$

$$I_{AVL} = \begin{cases} 0, & V_{DS} \leq V_{DSA} \\ I_{DS} \cdot a_1 \cdot \exp\left(\frac{-a_2}{V_{DS} - V_{DSA}}\right), & V_{DS} > V_{DSA} \end{cases} \quad (12.29)$$

### Charge Equations

$$V_{DB} = V_{DS} + V_{SB} \quad (12.30)$$

$$u_d = \sqrt{V_{DB} + \phi_B} \quad (12.31)$$

$$\Delta V_{T0d} = \begin{cases} K_0 \cdot (u_d - u_{s0}), & u_d < u_{sx} \\ \left[ 1 - \left(\frac{K}{K_0}\right)^2 \right] \cdot K_0 \cdot u_{sx} - K_0 \cdot u_{s0} \\ + K \cdot \sqrt{u_d^2 - \left[ 1 - \left(\frac{K}{K_0}\right)^2 \right] \cdot u_{sx}^2}, & u_d \geq u_{sx} \end{cases} \quad (12.32)$$

$$V_{T1d} = V_{T0} + \Delta V_{T0a} \quad (12.33)$$

$$\delta_2 = \frac{\partial V_{T2}}{\partial V_{SB}} - \frac{\partial V_{T2}}{\partial V_{GS}} - \frac{\partial V_{T2}}{\partial V_{DS}} \quad (12.34)$$

$$V_{DSS2} = \frac{V_{GT3}}{1 + \delta_2} \cdot \frac{2}{1 + \sqrt{1 + \frac{2 \cdot \theta_3 \cdot V_{GT3}}{1 + \delta_2}}} \quad (12.35)$$

$$V_{DS2} = \begin{cases} V_{DS}, & V_{DS} \leq V_{DSS2} \\ V_{DSS2}, & V_{DS} > V_{DSS2} \end{cases} \quad (12.36)$$

$$F_J = \frac{(1 + \delta_2) \cdot (1 + \theta_3 \cdot V_{DS2}) \cdot V_{DS2}}{2 \cdot V_{GT3} - (1 + \delta_2) \cdot V_{DS2}} \quad (12.37)$$

$$Q_D = -C_{OX} \cdot \left[ \frac{1}{2} \cdot V_{GT3} + (1 + \delta_2) \cdot V_{DS2} \cdot \left( \frac{1}{12} \cdot F_J - \frac{1}{60} \cdot F_J^2 - \frac{1}{3} \right) \right] \quad (12.38)$$

$$Q_S = -C_{OX} \cdot \left[ \frac{1}{2} \cdot V_{GT3} + (1 + \delta_2) \cdot V_{DS2} \cdot \left( \frac{1}{12} \cdot F_J - \frac{1}{60} \cdot F_J^2 - \frac{1}{6} \right) \right] \quad (12.39)$$

$$V_{GB} = V_{GS} + V_{SB} \quad (12.40)$$

$$V_{FB} = V_{T0} - \phi_B - K_0 \sqrt{\phi_B} \quad (12.41)$$

$$Q_{BS} = \begin{cases} -C_{OX} \cdot (V_{GB} - V_{FB}), & V_{GB} < V_{FB} \\ -C_{OX} \cdot K_0 \left\{ -\frac{K_0}{2} + \sqrt{\frac{K_0^2}{4} + (V_{GB} - V_{FB})} \right\}, & V_{FB} \leq V_{GB} \leq V_{SB} + V_{T1} \\ -C_{OX} \cdot K_0 \left\{ -\frac{K_0}{2} + \sqrt{\frac{K_0^2}{4} + (V_{SB} + V_{T1} - V_{FB})} \right\}, & V_{GB} > V_{SB} + V_{T1} \end{cases} \quad (12.42)$$

$$Q_{BD} = \begin{cases} -C_{OX} \cdot (V_{GB} - V_{FB}), & V_{GB} < V_{FB} \\ -C_{OX} \cdot K_0 \left\{ -\frac{K_0}{2} + \sqrt{\frac{K_0^2}{4} + (V_{GB} - V_{FB})} \right\}, & V_{FB} \leq V_{GB} \leq V_{DS2} + V_{SB} + V_{T1d} \\ -C_{OX} \cdot K_0 \left\{ -\frac{K_0}{2} + \sqrt{\frac{K_0^2}{4} + (V_{DS2} + V_{SB} + V_{T1d} - V_{FB})} \right\}, & V_{GB} > V_{DS2} + V_{SB} + V_{T1d} \end{cases} \quad (12.43)$$

$$Q_B = \frac{1}{2} \cdot (Q_{BS} + Q_{BD}) \quad (12.44)$$

$$Q_G = -(Q_S + Q_D + Q_B) \quad (12.45)$$

### Noise Equations

In these equations  $f$  represents the operation frequency of the transistor.

$$g_m = \frac{\partial I_{DS}}{\partial V_{GS}} \quad (12.46)$$

$$F_I = \frac{(1 + \delta_1) \cdot (1 + \theta_3 \cdot V_{DS1}) \cdot V_{DS1}}{2 \cdot V_{GT3} - (1 + \delta_1) \cdot V_{DS1}} \quad (12.47)$$

$$h_3 = \beta \cdot G_3 \cdot \left[ \frac{V_{GT3} - \frac{1}{2} \cdot (1 + \delta_1) \cdot V_{DS1}}{\{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\} \cdot (1 + \theta_3 \cdot V_{DS1})} \right] \quad (12.48)$$

$$h_4 = 1 + \theta_3 \cdot V_{DS1} + \frac{1}{3} \cdot F_I^2 \quad (12.49)$$

$$h_5 = \frac{V_{DSS1}}{2 \cdot \phi_T} \quad (12.50)$$

$$S_{th} = \begin{cases} N_T \cdot h_3 \cdot h_4 & h_4 < h_5 \\ N_T \cdot h_3 \cdot h_5 & h_4 \geq h_5 \end{cases} \quad (12.51)$$

$$\text{if NFMOD} = 0 \text{ then: } S_{fl} = N_F \cdot \frac{g_m^2}{f} \quad (12.52)$$

if NFMOD = 1 then equations: (12.53), (12.54), (12.55), (12.56), (12.57) and (12.58).

$$N_0 = \frac{\epsilon_{ox}}{qt_{ox}} \cdot V_{GT3} \quad (12.53)$$

$$N_L = \frac{\epsilon_{ox}}{qt_{ox}} \cdot (V_{GT3} - V_{DS1}) \quad (12.54)$$

$$N'' = \frac{\epsilon_{ox}}{qt_{ox}} \cdot \phi_T \cdot (m_0 + 1) \quad (12.55)$$

$$S_{wi} = N_{FA} \cdot \frac{\phi_T \cdot I_{DS}^2}{f \cdot N''^2} \quad (12.56)$$

$$S_{si} = \frac{\phi_T \cdot q^2 \cdot I_{DS} \cdot \beta \cdot t_{ox}^2}{f \cdot \epsilon_{ox}^2 \cdot \{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\}} \quad (12.57)$$

$$\cdot \left[ N_{FA} \cdot \ln \frac{N_0 + N''}{N_L + N''} + N_{FB} \cdot (N_0 - N_L) + \frac{1}{2} \cdot N_{FC} \cdot (N_0^2 - N_L^2) \right]$$

$$+ \frac{\phi_T \cdot I_{DS}^2}{f} \cdot \frac{G_2 - 1}{G_2} \cdot \left\{ \frac{N_{FA} + N_{FB} \cdot N_L + N_{FC} \cdot N_L^2}{(N_L + N'')^2} \right\}$$

$$S_{fl} = \frac{S_{si} \cdot S_{wi}}{S_{si} + S_{wi}} \quad (12.58)$$

$$S_{ig} = N_T \cdot \frac{(2 \cdot \pi \cdot f \cdot C_{OX})^2}{3 \cdot g_m} \cdot \left\{ 1 + 0.075 \cdot \left( \frac{2 \cdot \pi \cdot f \cdot C_{OX}}{g_m} \right)^2 \right\}^{-1} \quad (12.59)$$

$$\rho_{igth} = 0.4j \quad (12.60)$$

$$S_{igth} = \rho_{igth} \cdot \sqrt{S_{ig} \cdot S_{th}} \quad (12.61)$$

## 12.3 Symbols, parameters and constants

The symbolic representation and the programming names of the quantities listed in the following sections, have been chosen in such a way to express their purpose and relations to other quantities and to preclude ambiguity and inconsistency.

### 12.3.1 Glossary of used symbols

All parameters which refer to the reference transistor and/or the reference temperature have a symbol with the subscript R and a programming name ending with R. All characters 0 (zero) in subscripts of parameters are represented by the capital letter O in the programming name. Scaling parameters are indicated by  $S$  with a subscript where the variables on which the parameter depends, precede a semicolon whereas the parameter succeeds it, e.g.  $S_{T,L;01}$ . Generally, voltages related to energy levels are indicated by  $\phi$ , exponents by  $\eta$ , the small smoothing parameters by  $\varepsilon$  and the model constants by  $\lambda$ . In the programming names, the greek characters are abbreviated by the first three letters of their names, e.g.  $\beta$  by BET.

The drain, gate, source and bulk terminals are indicated by D, G, S and B respectively.

The electrical variables are split into the external electrical variables which represent the electrical quantities, observed at the nodes of the physical device, and the internal electrical variables.

## External Electrical Variables

The definitions of the external electrical variables are illustrated in Figure 48.

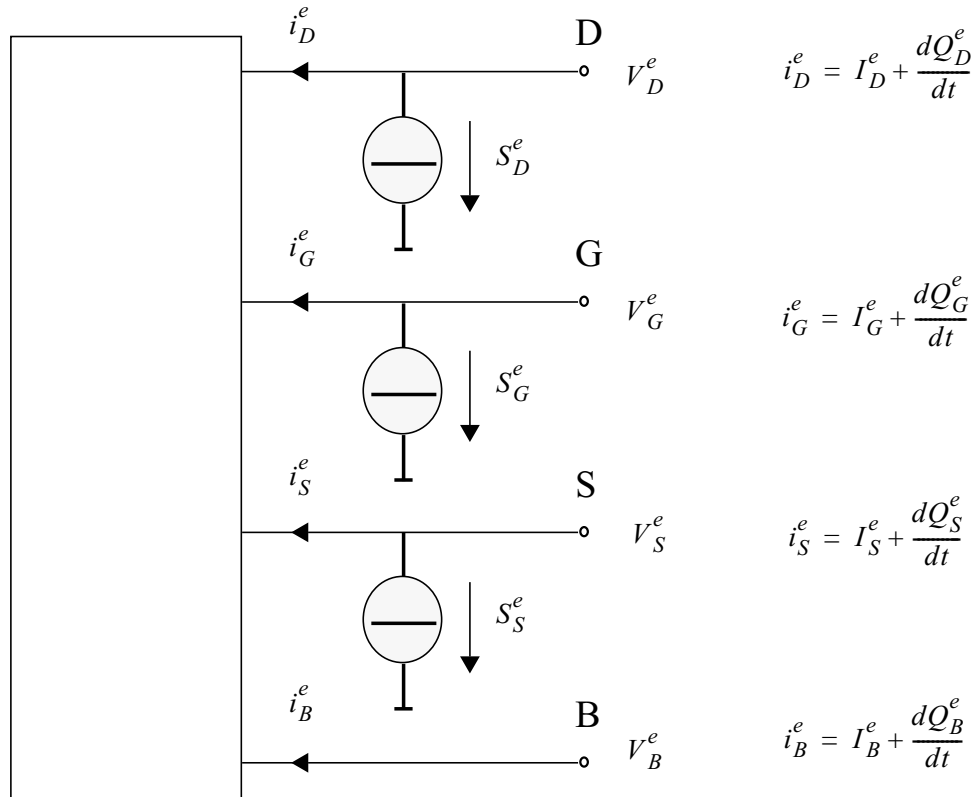


Figure 48: Definition of the external electrical variables

No.	Variable	Prog. Name	Units	Description
1	$V_D^e$	VDE	V	Potential applied to the drain node
2	$V_G^e$	VGE	V	Potential applied to the gate node
3	$V_S^e$	VSE	V	Potential applied to the source node
4	$V_B^e$	VBE	V	Potential applied to the bulk node
5	$I_D^e$	IDE	A	DC current into the drain
6	$I_G^e$	IGE	A	DC current into the gate
7	$I_S^e$	ISE	A	DC current into the source
8	$I_B^e$	IBE	A	DC current into the bulk
9	$Q_D^e$	QDE	C	Charge in the device attributed to the drain node
10	$Q_G^e$	QGE	C	Charge in the device attributed to the gate node
11	$Q_S^e$	QSE	C	Charge in the device attributed to the source node
12	$Q_B^e$	QBE	C	Charge in the device attributed to the bulk node
13	$S_D^e$	SDE	A <sup>2</sup> s	Spectral density of the noise current into the drain
14	$S_G^e$	SGE	A <sup>2</sup> s	Spectral density of the noise current into the gate
15	$S_S^e$	SSE	A <sup>2</sup> s	Spectral density of the noise current into the source

---

No.	Variable	Prog. Name	Units	Description
16	$S_{DG}^e$	SDGE	A <sup>2</sup> s	Cross spectral density of the noise current into the drain and the noise current into the gate
17	$S_{GS}^e$	SGSE	A <sup>2</sup> s	Cross spectral density of the noise current into the gate and the noise current into the source
18	$S_{SD}^e$	SSDE	A <sup>2</sup> s	Cross spectral density of the noise current into the source and the noise current into the drain

**Internal Electrical Variables**

<b>No.</b>	<b>Variable</b>	<b>Progr. Name</b>	<b>Units</b>	<b>Description</b>
1	$V_{DS}$	VDS	V	Drain-to-source voltage applied to the equivalent n-MOS
2	$V_{GS}$	VGS	V	Gate-to-source voltage applied to the equivalent n-MOS
3	$V_{SB}$	VSB	V	Source-to-bulk voltage applied to the equivalent n-MOS
4	$I_{DS}$	IDS	A	DC current through the channel flowing from drain to source
5	$I_{AVL}$	IAVL	A	DC current flowing from drain to the bulk due to the weak-avalanche effect
6	$Q_D$	QD	C	Charge in the equivalent n-MOS attributed to the drain node
7	$Q_G$	QG	C	Charge in the equivalent n-MOS attributed to the gate node
8	$Q_S$	QS	C	Charge in the equivalent n-MOS attributed to the source node
9	$Q_B$	QB	C	Charge in the equivalent n-MOS attributed to the bulk node
10	$S_{th}$	STH	$A^2s$	Spectral density of the thermal-noise current of the channel
11	$S_{fl}$	SFL	$A^2s$	Spectral density of the flicker-noise current of the channel
12	$S_{ig}$	SIG	$A^2s$	Spectral density of the noise current induced in the gate
13	$S_{igth}$	SIGTH	$A^2s$	Cross spectral density of the noise current induced in the gate and the thermal-noise current of the channel

## 12.3.2 Parameters and clipping

### Parameters of the geometrical model

These parameters correspond to the geometrical model (MN, MP).

No.	Symbol	Progr. Name	Units	Description
1		LEVEL	-	Must be 903
2	$L_{ER}$	LER	m	Effective channel length of the reference transistor
3	$W_{ER}$	WER	m	Effective channel width of the reference transistor
4	$\Delta L_{PS}$	LVAR	m	Difference between the actual and the programmed poly-silicon gate length
5	$\Delta L_{overlap}$	LAP	m	Effective channel length reduction per side due to the lateral diffusion of the source/drain dopant ions
6	$\Delta W_{OD}$	WVAR	m	Difference between the actual and the programmed field-oxide opening
7	$\Delta W_{narrow}$	WOT	m	Effective reduction of the channel width per side due to the lateral diffusion of the channel-stop dopant ions
8	$T_R$	TR	°C	Temperature at which the parameters for the reference transistor have been determined
9	$V_{T0R}$	VTOR	V	Threshold voltage at zero back-bias for the reference transistor at the reference temperature
10	$S_{T;V_{T0}}$	STVTO	VK <sup>-1</sup>	Coefficient of the temperature dependence $V_{T0}$
11	$S_{L;V_{T0}}$	SLVTO	Vm	Coefficient of the length dependence of $V_{T0}$
12	$S_{L2;V_{T0}}$	SL2VTO	Vm <sup>2</sup>	Second coefficient of the length dependence of $V_{T0}$
13	$S_{L3;V_{T0}}$	SL3VTO	V	Third coefficient of the length dependence of $V_{T0}$

No.	Symbol	Progr. Name	Units	Description
14	$S_{W;V_{T0}}$	SWVTO	Vm	Coefficient of the width dependence of $V_{T0}$
15	$K_{0R}$	KOR	$V^{1/2}$	Low-backbias body factor for the reference transistor
16	$S_{L;K_0}$	SLKO	$V^{1/2}m$	Coefficient of the length dependence of $K_0$
17	$S_{L2;K_0}$	SL2KO	$V^{1/2}m^2$	Second coefficient of the length dependence of $K_0$
18	$S_{W;K_0}$	SWKO	$V^{1/2}m$	Coefficient of the width dependence of $K_0$
19	$K_R$	KR	$V^{1/2}$	High-backbias body factor for the reference transistor
20	$S_{L;K}$	SLK	$V^{1/2}m$	Coefficient of the length dependence of $K$
21	$S_{L2;K}$	SL2K	$V^{1/2}m^2$	Second coefficient of the length dependence of $K$
22	$S_{W;K}$	SWK	$V^{1/2}m$	Coefficient of the width dependence of $K$
23	$\phi_{BR}$	PHIBR	V	Surface potential at strong inversion for the reference transistor at the reference temperature
24	$V_{SBXR}$	VSBR	V	Transition voltage for the dual-k-factor model for the reference transistor
25	$S_{L;V_{SBX}}$	SLVSBX	Vm	Coefficient of the length dependence of $V_{SBX}$
26	$S_{W;V_{SBX}}$	SWVSBX	Vm	Coefficient of the width dependence $V_{SBX}$
27	$\beta_{sq}$	BETSQ	$AV^{-2}$	Gain factor for an infinite square transistor at the reference temperature
28	$\eta_\beta$	ETABET	-	Exponent of the temperature dependence of the gain factor
29	$L_{P,1}$	LP1	m	Characteristic length of first profile
30	$f_{\beta,1}$	FBET1	-	Relative mobility decrease due to first profile

No.	Symbol	Progr. Name	Units	Description
31	$L_{P,2}$	LP2	m	Characteristic length of second profile
32	$f_{\beta,2}$	FBET2	-	Relative mobility decrease due to second profile
33	$\theta_{1R}$	THE1R	$V^{-1}$	Coefficient of the mobility reduction due to the gate-induced field for the reference transistor at the reference temperature
34	$S_{T;\theta_1,R}$	STTHE1R	$V^{-1}K^{-1}$	Coefficient of the temperature dependence of $\theta_1$ for the reference transistor
35	$S_{L;\theta_1,R}$	SLTHE1R	$V^{-1}m$	Coefficient of the length dependence of $\theta_1$ at the reference temperature
36	$S_{T,L;\theta_1}$	STLTHE1	$V^{-1}mK^{-1}$	Coefficient of the temperature dependence of the length dependence of $\theta_1$
37	$g_{\theta_1}$	GTHE1	-	Parameter that selects either the old ( $g_{\theta_1} = 0$ ) or the new ( $g_{\theta_1} = 1$ ) scaling rule of $\theta_1$
38	$S_{W;\theta_1}$	SWTHE1	$V^{-1}m$	Coefficient of the width dependence of $\theta_1$
39	$W_{DOG}$	WDOG	m	Characteristic drawn gate width, below which dogboning appears
40	$f_{\theta_1}$	FTHE1	-	Coefficient describing the geometry dependence of $\theta_1$ for $W < W_{DOG}$
41	$\theta_{2R}$	THE2R	$V^{-1/2}$	Coefficient of the mobility reduction due to the back-bias for the reference transistor at the reference temperature
42	$S_{T;\theta_2,R}$	STTHE2R	$V^{-1/2}K^{-1}$	Coefficient of the temperature dependence of $\theta_2$ for the reference transistor
43	$S_{L;\theta_2,R}$	SLTHE2R	$V^{-1/2}m$	Coefficient of the length dependence of $\theta_2$ at the reference temperature
44	$S_{T,L;\theta_2}$	STLTHE2	$V^{-1/2}mK^{-1}$	Coefficient of the temperature dependence of the length dependence of $\theta_2$

No.	Symbol	Progr. Name	Units	Description
45	$S_{W;\theta_2}$	SWTHE2	$V^{-1/2}m$	Coefficient of the width dependence of $\theta_2$
46	$\theta_{3R}$	THE3R	$V^{-1}$	Coefficient of the mobility reduction due to the lateral field for the reference transistor at the reference temperature
47	$S_{T;\theta_3,R}$	STTHE3R	$V^{-1}K^{-1}$	Coefficient of the temperature dependence of $\theta_3$ for the reference temperature
48	$S_{L;\theta_3,R}$	SLTHE3R	$V^{-1}m$	Coefficient of the length dependence of $\theta_3$ at the reference temperature
49	$S_{T,L;\theta_3}$	STLTHE3	$V^{-1}mK^{-1}$	Coefficient of the temperature dependence of the length dependence of $\theta_3$
50	$S_{W;\theta_3}$	SWTHE3	$V^{-1}m$	Coefficient of the width dependence of $\theta_3$
51	$\gamma_{1R}$	GAM1R	$V^{(1-\eta_{DS})}$	Coefficient for the drain induced threshold shift for large gate drive for the reference transistor
52	$S_{L;\gamma_1}$	SLGAM1	$V^{(1-\eta_{DS})}m$	Coefficient of the length dependence of $\gamma_1$
53	$S_{W;\gamma_1}$	SWGAM1	$V^{(1-\eta_{DS})}m$	Coefficient of the width dependence of $\gamma_1$
54	$\eta_{DSR}$	ETADSR	-	Exponent of the $V_{DS}$ dependence of $\gamma_1$ for the reference transistor
55	$\alpha_R$	ALPR	-	Factor of the channel-length modulation for the reference transistor
56	$\eta_\alpha$	ETAALP	-	Exponent of the length dependence of $\alpha$
57	$S_{L;\alpha}$	SLALP	$m^{\eta_\alpha}$	Coefficient of the length dependence of $\alpha$
58	$S_{W;\alpha}$	SWALP	$m$	Coefficient of the width dependence of $\alpha$
59	$V_{PR}$	VPR	$V$	Characteristic voltage of the channel-length modulation for the reference transistor

No.	Symbol	Progr. Name	Units	Description
60	$\gamma_{0R}$	GAM0OR	-	Coefficient of the drain induced threshold shift at zero gate drive for the reference transistor
61	$S_{L;\gamma_{00}}$	SLGAM0O	m <sup>2</sup>	Coefficient of the length dependence of $\gamma_{00}$
62	$S_{L2;\gamma_{00}}$	SL2GAM0O	-	Second coefficient of the length dependence of $\gamma_{00}$
63	$\eta_{\gamma R}$	ETAGAMR	-	Exponent of the back-bias dependence of $\gamma_0$ for the reference transistor
64	$m_{0R}$	MOR	-	Factor of the subthreshold slope for the reference transistor at the reference temperature
65	$S_{T;m_0}$	STMO	K <sup>-1</sup>	Coefficient of the temperature dependence of $m_0$
66	$S_{L;m_0}$	SLMO	m <sup>1/2</sup>	Coefficient of the length dependence of $m_0$
67	$\eta_{mR}$	ETAMR	-	Exponent of the back-bias dependence of $m$ for the reference transistor
68	$\zeta_{1R}$	ZET1R	-	Weak-inversion correction factor for the reference transistor
69	$\eta_{\zeta}$	ETAZET	-	Exponent of the length dependence of $\zeta_1$
70	$S_{L;\zeta_1}$	SLZET1	m <sup><math>\eta_{\zeta}</math></sup>	Coefficient of the length dependence of $\zeta_1$
71	$V_{SBTR}$	VSBTTR	V	Limiting voltage of the $V_{SB}$ dependence of $m$ and $\gamma_0$ for the reference transistor
72	$S_{L;V_{SBT}}$	SLVSBT	Vm	Coefficient of the length dependence of $V_{SBT}$
73	$a_{1R}$	A1R	-	Factor of the weak-avalanche current for the reference transistor at the reference temperature
74	$S_{T;a_1}$	STA1	K <sup>-1</sup>	Coefficient of the temperature dependence of $a_1$

No.	Symbol	Progr. Name	Units	Description
75	$S_{L;a_1}$	SLA1	m	Coefficient of the length dependence of $a_1$
76	$S_{W;a_1}$	SWA1	m	Coefficient of the width dependence of $a_1$
77	$a_{2R}$	A2R	V	Exponent of the weak-avalanche current for the reference transistor
78	$S_{L;a_2}$	SLA2	Vm	Coefficient of the length dependence of $a_2$
79	$S_{W;a_2}$	SWA2	Vm	Coefficient of the width dependence of $a_2$
80	$a_{3R}$	A3R	-	Factor of the drain-source voltage above which weak-avalanche occurs, for the reference transistor
81	$S_{L;a_3}$	SLA3	m	Coefficient of the length dependence of $a_3$
82	$S_{W;a_3}$	SWA3	m	Coefficient of the width dependence of $a_3$
83	$t_{ox}$	TOX	m	Thickness of the gate-oxide layer. $t_{ox}$ is used for calculation of 1/f noise and $C_{ox}$ , not for $\beta$ !!!
84	$C_{ol}$	COL	Fm <sup>-1</sup>	Gate overlap capacitance per unit channel width
85	$N_{TR}$	NTR	J	Coefficient of the thermal noise for the reference transistor
86	$NFMOD$	NFMOD	-	Switch that selects either old or new flicker noise model
87	$N_{FR}$	NFR	V <sup>2</sup>	Flicker noise coefficient of the reference transistor (for NFMOD = 0)
88	$N_{FAR}$	NFAR	V <sup>-1</sup> m <sup>-4</sup>	First coefficient of the flicker noise of the reference transistor (for NFMOD = 1)
89	$N_{FBR}$	NFBR	V <sup>-1</sup> m <sup>-2</sup>	Second coefficient of the flicker noise of the reference transistor (for NFMOD = 1)
90	$N_{FCR}$	NFCR	V <sup>-1</sup>	Third coefficient of the flicker noise of the reference transistor (for NFMOD = 1)
91	$L$	L	m	Drawn channel length in the lay-out of the actual transistor

No.	Symbol	Progr. Name	Units	Description
92	$W$	W	m	Drawn channel width in the lay-out of the actual transistor
93	$\Delta T_A$	DTA	°C	Temperature offset of the device with respect to $T_A$
94	$N_{MULT}$	MULT	-	Number of devices in parallel
95	$TH3MOD$	TH3MOD	-	Flag for $\theta_3$ clipping

**Remark:** The parameters  $L$ ,  $W$ , and  $DTA$  are used to calculate the electrical parameters of the actual transistor, as specified in the section on parameter preprocessing.

### Default and clipping values (geometrical model)

The default values and clipping values as used for the parameters of the geometrical MOS model, level 903 (n-channel) are listed below.

No.	Parameter	Units	Default	Clip low	Clip high
1	<i>LEVEL</i>	-	903	-	-
2	<i>LER</i>	m	$1.10 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
3	<i>WER</i>	m	$20.00 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
4	<i>LVAR</i>	m	$-0.220 \times 10^{-6}$	-	-
5	<i>LAP</i>	m	$0.100 \times 10^{-6}$	-	-
6	<i>WVAR</i>	m	$-0.025 \times 10^{-6}$	-	-
7	<i>WOT</i>	m	$0.000 \times 10^{-6}$	-	-
8	<i>TR</i>	°C	21.00	-273.15	-
9	<i>VTOR</i>	V	0.730	-	-
10	<i>STVTO</i>	VK <sup>-1</sup>	$-1.20 \times 10^{-3}$	-	-
11	<i>SLVTO</i>	Vm	$-0.135 \times 10^{-6}$	-	-
12	<i>SL2VTO</i>	Vm <sup>2</sup>	0.0	-	-
13	<i>SL3VTO</i>	V	0.0	-	-
14	<i>SWVTO</i>	Vm	$0.130 \times 10^{-6}$	-	-
15	<i>KOR</i>	V <sup>1/2</sup>	0.650	-	-
16	<i>SLKO</i>	V <sup>1/2</sup> m	$-0.130 \times 10^{-6}$	-	-
17	<i>SL2KO</i>	V <sup>1/2</sup> m <sup>2</sup>	0.0	-	-
18	<i>SWKO</i>	V <sup>1/2</sup> m	$0.002 \times 10^{-6}$	-	-
19	<i>KR</i>	V <sup>1/2</sup>	0.110	-	-
20	<i>SLK</i>	V <sup>1/2</sup> m	$-0.280 \times 10^{-6}$	-	-
21	<i>SL2K</i>	V <sup>1/2</sup> m <sup>2</sup>	0.0	-	-

No.	Parameter	Units	Default	Clip low	Clip high
22	<i>SWK</i>	$V^{1/2}m$	$0.275 \times 10^{-6}$	-	-
23	<i>PHIBR</i>	V	0.650	-	-
24	<i>VSBR</i>	V	0.660	-	-
25	<i>SLVSBX</i>	Vm	$0.000 \times 10^{-6}$	-	-
26	<i>SWVSBX</i>	Vm	$-0.675 \times 10^{-6}$	-	-
27	<i>BETSQ</i>	$AV^{-2}$	$83.00 \times 10^{-6}$	-	-
28	<i>ETABET</i>	-	1.600	-	-
29	<i>LP1</i>	m	$1.0 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
30	<i>FBET1</i>	-	0.0	-	-
31	<i>LP2</i>	m	$1.0 \times 10^{-8}$	$1.0 \times 10^{-10}$	-
32	<i>FBET2</i>	-	0.0	-	-
33	<i>THE1R</i>	$V^{-1}$	0.190	-	-
34	<i>STTHE1R</i>	$V^{-1}K^{-1}$	$0.000 \times 10^{-3}$	-	-
35	<i>SLTHE1R</i>	$V^{-1}m$	$0.140 \times 10^{-6}$	-	-
36	<i>STLTHE1</i>	$V^{-1}mK^{-1}$	$0.000 \times 10^{-3}$	-	-
37	<i>GTHE1</i>	-	0.0	0.0	1.0
38	<i>SWTHE1</i>	$V^{-1}m$	$-0.058 \times 10^{-6}$	-	-
39	<i>WDOG</i>	m	0.0	0.0	-
40	<i>FTHE1</i>	-	0.0	-	-
41	<i>THE2R</i>	$V^{-1/2}$	0.012	-	-
42	<i>STTHE2R</i>	$V^{-1/2}K^{-1}$	$0.000 \times 10^{-9}$	-	-
43	<i>SLTHE2R</i>	$V^{-1/2}m$	$-0.033 \times 10^{-6}$	-	-
44	<i>STLTHE2</i>	$V^{-1/2}mK^{-1/2}$	$0.000 \times 10^{-3}$	-	-
45	<i>SWTHE2</i>	$V^{-1/2}m$	$0.030 \times 10^{-6}$	-	-

No.	Parameter	Units	Default	Clip low	Clip high
46	<i>THE3R</i>	V <sup>-1</sup>	0.145	-	-
47	<i>STTHE3R</i>	V <sup>-1</sup> K <sup>-1</sup>	-0.660 × 10 <sup>-3</sup>	-	-
48	<i>SLTHE3R</i>	V <sup>-1</sup> m	0.185 × 10 <sup>-6</sup>	-	-
49	<i>STLTHE3</i>	V <sup>-1</sup> mK <sup>-1</sup>	-0.620 × 10 <sup>-9</sup>	-	-
50	<i>SWTHE3</i>	V <sup>-1</sup> m	0.020 × 10 <sup>-6</sup>	-	-
51	<i>GAMIR</i>	V <sup>(1-η<sub>DS</sub>)</sup>	0.145	-	-
52	<i>SLGAMI</i>	V <sup>(1-η<sub>DS</sub>)</sup> m	0.160 × 10 <sup>-6</sup>	-	-
53	<i>SWGAMI</i>	V <sup>(1-η<sub>DS</sub>)</sup> m	-0.010 × 10 <sup>-6</sup>	-	-
54	<i>ETADSR</i>	-	0.600	-	-
55	<i>ALPR</i>	-	0.003	-	-
56	<i>ETAALP</i>	-	0.0	-	-
57	<i>SLALP</i>	m <sup>η<sub>α</sub></sup>	-5.65 × 10 <sup>-3</sup>	-	-
58	<i>SWALP</i>	m	1.67 × 10 <sup>-9</sup>	-	-
59	<i>VPR</i>	V	0.340	-	-
60	<i>GAMOOR</i>	-	0.018	-	-
61	<i>SLGAMOO</i>	m <sup>2</sup>	20.00 × 10 <sup>-15</sup>	-	-
62	<i>SL2GAMOO</i>	-	0.0	-	-
63	<i>ETAGAMR</i>	-	2.0	-	-
64	<i>MOR</i>	-	0.500	-	-
65	<i>STMO</i>	K <sup>-1</sup>	0.000 × 10 <sup>+0</sup>	-	-
66	<i>SLMO</i>	m <sup>1/2</sup>	0.280 × 10 <sup>-3</sup>	-	-
67	<i>ETAMR</i>	-	2.0	-	-
68	<i>ZET1R</i>	-	0.420	-	-
69	<i>ETAZET</i>	-	0.50	-	-

No.	Parameter	Units	Default	Clip low	Clip high
70	<i>SLZET1</i>	m <sup>η<sub>ζ</sub></sup>	-0.390	-	-
71	<i>VSBR</i>	V	2.10	-	-
72	<i>SLVSBT</i>	Vm	-4.40 × 10 <sup>-6</sup>	-	-
73	<i>AIR</i>	-	6.00	-	-
74	<i>STA1</i>	K <sup>-1</sup>	0.000 × 10 <sup>+0</sup>	-	-
75	<i>SLA1</i>	m	1.30 × 10 <sup>-6</sup>	-	-
76	<i>SWA1</i>	m	3.00 × 10 <sup>-6</sup>	-	-
77	<i>A2R</i>	V	38.0	-	-
78	<i>SLA2</i>	Vm	1.00 × 10 <sup>-6</sup>	-	-
79	<i>SWA2</i>	Vm	2.00 × 10 <sup>-6</sup>	-	-
80	<i>A3R</i>	-	0.650	-	-
81	<i>SLA3</i>	m	-0.550 × 10 <sup>-6</sup>	-	-
82	<i>SWA3</i>	m	0.000 × 10 <sup>-6</sup>	-	-
83	<i>TOX</i>	m	25.0 × 10 <sup>-9</sup>	-	-
84	<i>COL</i>	Fm <sup>-1</sup>	0.320 × 10 <sup>-9</sup>	-	-
85	<i>NTR</i>	J	0.244 × 10 <sup>-19</sup>	-	-
86	<i>NFMOD</i>	-	0	-	-
87	<i>NFR</i>	V <sup>2</sup>	70.000 × 10 <sup>-12</sup>	-	-
88	<i>NFAR</i>	V <sup>-1</sup> m <sup>-4</sup>	7.15 × 10 <sup>22</sup>	10 <sup>-12</sup>	-
89	<i>NFBR</i>	V <sup>-1</sup> m <sup>-2</sup>	2.16 × 10 <sup>7</sup>	-	-
90	<i>NFCR</i>	V <sup>-1</sup>	0	-	-
91	<i>L</i>	m	1.50 × 10 <sup>-6</sup>	-	-
92	<i>W</i>	m	20.0 × 10 <sup>-6</sup>	-	-
93	<i>DTA</i>	°C	0.0	-	-

---

<b>No.</b>	<b>Parameter</b>	<b>Units</b>	<b>Default</b>	<b>Clip low</b>	<b>Clip high</b>
94	<i>MULT</i>	-	1.0	0.0	-
95	<i>TH3MOD</i>	-	1.0	0.0	1.0

The default values and clipping values as used for the parameters of the geometrical MOS model, level 903 (p-channel) are listed below.

<b>No.</b>	<b>Parameter</b>	<b>Units</b>	<b>Default</b>	<b>Clip low</b>	<b>Clip high</b>
1	<i>LEVEL</i>	-	903	-	-
2	<i>LER</i>	m	$1.25 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
3	<i>WER</i>	m	$20.00 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
4	<i>LVAR</i>	m	$-0.460 \times 10^{-6}$	-	-
5	<i>LAP</i>	m	$0.025 \times 10^{-6}$	-	-
6	<i>WVAR</i>	m	$-0.130 \times 10^{-6}$	-	-
7	<i>WOT</i>	m	$0.000 \times 10^{-6}$	-	-
8	<i>TR</i>	°C	21.0	-273.15	-
9	<i>VTOR</i>	V	1.100	-	-
10	<i>STVTO</i>	VK <sup>-1</sup>	$-1.7 \times 10^{-3}$	-	-
11	<i>SLVTO</i>	Vm	$0.035 \times 10^{-6}$	-	-
12	<i>SL2VTO</i>	Vm	0.0	-	-
13	<i>SL3VTO</i>	V	0.0	-	-
14	<i>SWVTO</i>	Vm	$0.050 \times 10^{-6}$	-	-
15	<i>KOR</i>	V <sup>1/2</sup>	0.470	-	-
16	<i>SLKO</i>	V <sup>1/2</sup> m	$-0.200 \times 10^{-6}$	-	-
17	<i>SL2KO</i>	V <sup>1/2</sup> m <sup>2</sup>	0.0	-	-
18	<i>SWKO</i>	V <sup>1/2</sup> m	$0.115 \times 10^{-6}$	-	-
19	<i>KR</i>	V <sup>1/2</sup>	0.470	-	-
20	<i>SLK</i>	V <sup>1/2</sup> m	$-0.200 \times 10^{-6}$	-	-
21	<i>SL2K</i>	V <sup>1/2</sup> m <sup>2</sup>	0.0	-	-
22	<i>SWK</i>	V <sup>1/2</sup> m	$0.115 \times 10^{-6}$	-	-

No.	Parameter	Units	Default	Clip low	Clip high
23	<i>PHIBR</i>	V	0.650	-	-
24	<i>VSBXR</i>	V	$1.000 \times 10^{-12}$	-	-
25	<i>SLVSBX</i>	Vm	0.0	-	-
26	<i>SWVSBX</i>	Vm	0.0	-	-
27	<i>BETSQ</i>	$AV^{-2}$	$26.1 \times 10^{-6}$	-	-
28	<i>ETABET</i>	-	1.6	-	-
29	<i>LP1</i>	m	$1.0 \times 10^{-6}$	$1.0 \times 10^{-10}$	-
30	<i>FBET1</i>	-	0.0	-	-
31	<i>LP2</i>	m	$1.0 \times 10^{-8}$	$1.0 \times 10^{-10}$	-
32	<i>FBET2</i>	-	0.0	-	-
33	<i>THE1R</i>	$V^{-1}$	0.190	-	-
34	<i>STTHE1R</i>	$V^{-1}K^{-1}$	$0.000 \times 10^{-3}$	-	-
35	<i>SLTHE1R</i>	$V^{-1}m$	$70.000 \times 10^{-9}$	-	-
36	<i>STLTHE1</i>	$V^{-1}mK^{-1}$	$0.000 \times 10^{-3}$	-	-
37	<i>GTHE1</i>	-	0.0	0.0	1.0
38	<i>SWTHE1</i>	$V^{-1}m$	$-0.080 \times 10^{-6}$	-	-
39	<i>WDOG</i>	m	0.0	0.0	-
40	<i>FTHE1</i>	-	0.0	-	-
41	<i>THE2R</i>	$V^{-1/2}$	0.165	-	-
42	<i>STTHE2R</i>	$V^{-1/2}K^{-1}$	$0.000 \times 10^{-9}$	-	-
43	<i>SLTHE2R</i>	$V^{-1/2}m$	$-0.075 \times 10^{-6}$	-	-
44	<i>STLTHE2</i>	$V^{-1/2}mK^{-1/2}$	$0.000 \times 10^{-3}$	-	-
45	<i>SWTHE2</i>	$V^{-1/2}m$	$0.020 \times 10^{-6}$	-	-
46	<i>THE3R</i>	$V^{-1}$	0.027	-	-

No.	Parameter	Units	Default	Clip low	Clip high
47	<i>STTHE3R</i>	$V^{-1}K^{-1}$	$0.000 \times 10^{-9}$	-	-
48	<i>SLTHE3R</i>	$V^{-1}m$	$0.027 \times 10^{-6}$	-	-
49	<i>STLTHE3</i>	$V^{-1}mK^{-1}$	$0.000 \times 10^{-3}$	-	-
50	<i>SWTHE3</i>	$V^{-1}m$	$0.011 \times 10^{-6}$	-	-
51	<i>GAMIR</i>	$V^{(1-\eta_{DS})}$	0.077	-	-
52	<i>SLGAMI</i>	$V^{(1-\eta_{DS})} m$	$0.105 \times 10^{-6}$	-	-
53	<i>SWGAMI</i>	$V^{(1-\eta_{DS})} m$	$-0.011 \times 10^{-6}$	-	-
54	<i>ETADSR</i>	-	$0.600 \times 10^{+0}$	-	-
55	<i>ALPR</i>	-	0.044	-	-
56	<i>ETAALP</i>	-	1.0	-	-
57	<i>SLALP</i>	$m^{\eta_{\alpha}}$	$9.00 \times 10^{-3}$	-	-
58	<i>SWALP</i>	m	$0.180 \times 10^{-9}$	-	-
59	<i>VPR</i>	V	0.235	-	-
60	<i>GAMOOR</i>	-	0.007	-	-
61	<i>SLGAMOO</i>	$m^2$	$11.0 \times 10^{-15}$	-	-
62	<i>SL2GAMOO</i>	-	0.0	-	-
63	<i>ETAGAMR</i>	-	1.0	-	-
64	<i>MOR</i>	-	0.375	-	-
65	<i>STMO</i>	$K^{-1}$	$0.000 \times 10^{+0}$	-	-
66	<i>SLMO</i>	$m^{1/2}$	$0.047 \times 10^{-3}$	-	-
67	<i>ETAMR</i>	-	1.0	-	-
68	<i>ZETIR</i>	-	1.30	-	-
69	<i>ETAZET</i>	-	1.0	-	-

No.	Parameter	Units	Default	Clip low	Clip high
70	<i>SLZET1</i>	$m^{\eta_{\alpha}}$	-2.80	-	-
71	<i>VSBTR</i>	V	100.0	-	-
72	<i>SLVSBT</i>	Vm	$0.00 \times 10^{-6}$	-	-
73	<i>AIR</i>	-	10.0	-	-
74	<i>STA1</i>	$K^{-1}$	$0.000 \times 10^{+0}$	-	-
75	<i>SLA1</i>	m	$-15.0 \times 10^{-6}$	-	-
76	<i>SWA1</i>	m	$30.0 \times 10^{-6}$	-	-
77	<i>A2R</i>	V	59.0	-	-
78	<i>SLA2</i>	Vm	$-8.00 \times 10^{-6}$	-	-
79	<i>SWA2</i>	Vm	$15.0 \times 10^{-6}$	-	-
80	<i>A3R</i>	-	0.520	-	-
81	<i>SLA3</i>	m	$-0.450 \times 10^{-6}$	-	-
82	<i>SWA3</i>	m	$-0.140 \times 10^{-6}$	-	-
83	<i>TOX</i>	m	$25.0 \times 10^{-9}$	-	-
84	<i>COL</i>	$Fm^{-1}$	$0.320 \times 10^{-9}$	-	-
85	<i>NTR</i>	J	$0.211 \times 10^{-19}$	-	-
86	<i>NFMOD</i>	-	0	-	-
87	<i>NFR</i>	$V^2$	$21.400 \times 10^{-12}$	-	-
88	<i>NFAR</i>	$V^{-1}m^{-4}$	$1.53 \times 10^{22}$	$10^{-12}$	-
89	<i>NFBR</i>	$V^{-1}m^{-2}$	$4.06 \times 10^6$	-	-
90	<i>NFCR</i>	$V^{-1}$	$2.92 \times 10^{-10}$	-	-
91	<i>L</i>	m	$1.50 \times 10^{-6}$	-	-
92	<i>W</i>	m	$20.0 \times 10^{-6}$	-	-
93	<i>DTA</i>	$^{\circ}C$	0.0	-	-

---

<b>No.</b>	<b>Parameter</b>	<b>Units</b>	<b>Default</b>	<b>Clip low</b>	<b>Clip high</b>
94	<i>MULT</i>	-	1.0	0.0	-
95	<i>TH3MOD</i>	-	1.0	0.0	1.0

## Parameters of the electrical model

These parameter correspond to the electrical model (MNE, MPE).

No.	Symbol	Progr. Name	Units	Description
1		LEVEL	-	Must be 903
2	$V_{T0}$	VTO	V	Threshold voltage at zero back-bias for the actual transistor at the actual temperature
3	$K_0$	K0	$V^{1/2}$	Low-backbias body factor for the actual transistor
4	$K$	K	$V^{1/2}$	High-backbias body factor for the actual transistor
5	$\phi_B$	PHIB	V	Surface potential at strong inversion for the actual transistor at the actual temperature
6	$V_{SBX}$	VSBX	V	Transition voltage for the dual-k-factor model for the actual transistor
7	$\beta$	BET	$AV^{-2}$	Gain factor for the actual transistor at the actual temperature
8	$\theta_1$	THE1	$V^{-1}$	Coefficient of the mobility reduction due to the gate-induced field for the actual transistor at the actual temperature
9	$\theta_2$	THE2	$V^{-1/2}$	Coefficient of the mobility reduction due to the back-bias for the actual transistor at the actual temperature
10	$\theta_3$	THE3	$V^{-1}$	Coefficient of the mobility reduction due to the lateral field for the actual transistor at the actual temperature
11	$\gamma_1$	GAM1	$V^{(1-\eta_{DS})}$	Coefficient for the drain induced threshold shift for large gate drive for the actual transistor
12	$\eta_{DS}$	ETADS	-	Exponent of the $V_{DS}$ dependence of $\gamma_1$ for the actual transistor
13	$\alpha$	ALP	-	Factor of the channel-length modulation for the actual transistor

No.	Symbol	Progr. Name	Units	Description
14	$V_P$	VP	V	Characteristic voltage of the channel-length modulation for the actual transistor
15	$\gamma_0$	GAM00	-	Coefficient of the drain induced threshold shift at zero gate drive for the actual transistor
16	$\eta_\gamma$	ETAGAM	-	Exponent of the back-bias dependence of $\gamma_0$ for the actual transistor
17	$m_0$	MO	-	Factor of the subthreshold slope for the actual transistor at the actual temperature
18	$\eta_m$	ETAM	-	Exponent of the back-bias dependence $m$ for the actual transistor
19	$\phi_T$	PHIT	V	Thermal voltage at the actual temperature
20	$\zeta_1$	ZET1	-	Weak-inversion correction factor for the actual transistor
21	$V_{SBT}$	VSBT	V	Limiting voltage of $V_{SB}$ dependence of $m$ and $\gamma_0$ for the actual transistor
22	$a_1$	A1	-	Factor of the weak-avalanche current for the actual transistor
23	$a_2$	A2	V	Exponent of the weak-avalanche current for the actual transistor
24	$a_3$	A3	-	Factor of the drain-source voltage above which weak-avalanche occurs for the actual transistor
25	$C_{ox}$	COX	F	Gate-to-channel capacitance for the actual transistor
26	$C_{GDO}$	CGDO	F	Gate-drain overlap capacitance for the actual transistor
27	$C_{GSO}$	CGSO	F	Gate-source overlap capacitance for the actual transistor
28	$N_T$	NT	J	Coefficient of the thermal noise for the actual transistor
29	$NFMOD$	NFMOD	-	Switch that selects either old or new flicker noise model

No.	Symbol	Progr. Name	Units	Description
30	$N_F$	NF	$V^2$	Flicker noise coefficient of the actual transistor (for NFMOD = 0)
31	$N_{FA}$	NFA	$V^{-1}m^{-4}$	First coefficient of the flicker noise of the actual transistor (for NFMOD = 1)
32	$N_{FB}$	NFB	$V^{-1}m^{-2}$	Second coefficient of the flicker noise of the actual transistor (for NFMOD = 1)
33	$N_{FC}$	NFC	$V^{-1}$	Third coefficient of the flicker noise of the actual transistor (for NFMOD = 1)
34	$t_{ox}$	TOX	m	Thickness of the gate-oxide layer 3
35	<i>MULT</i>	MULT	-	Number of devices operating in parallel
36	<i>TH3MOD</i>	TH3MOD	-	Flag for $\theta_3$ clipping

### 3 Note

$t_{ox}$  is used for calculation of 1/f noise, not for  $\beta$  !!!

### Default and clipping values (electrical model)

The default values and clipping values as used for the parameters of the electrical MOS model, level 903 (n-channel) are listed below.

No.	Parameter	Units	Default	Clip low	Clip high
1	<i>LEVEL</i>	-	903	-	-
2	<i>VTO</i>	V	$7.099154 \times 10^{-01}$	-	-
3	<i>KO</i>	$V^{1/2}$	$6.478116 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
4	<i>K</i>	$V^{1/2}$	$4.280174 \times 10^{-01}$	See note <sup>a</sup>	-
5	<i>PHIB</i>	V	$6.225999 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
6	<i>VSBX</i>	V	$6.599578 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
7	<i>BET</i>	$AV^{-2}$	$1.418789 \times 10^{-03}$	0.0	-
8	<i>THE1</i>	$V^{-1}$	$1.923533 \times 10^{-01}$	0.0	-
9	<i>THE2</i>	$V^{-1/2}$	$1.144632 \times 10^{-02}$	0.0	1.0
10	<i>THE3</i>	$V^{-1}$	$1.381597 \times 10^{-01}$	-	-
11	<i>GAMI</i>	$V^{(1-\eta_{DS})}$	$1.476930 \times 10^{-01}$	0.0	-
12	<i>ETADS</i>	-	$6.000000 \times 10^{-01}$	-	-
13	<i>ALP</i>	-	$2.878165 \times 10^{-03}$	0.0	-
14	<i>VP</i>	V	$3.338182 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
15	<i>GAM00</i>	-	$1.861785 \times 10^{-02}$	0.0	-
16	<i>ETAGAM</i>	-	$2.000000 \times 10^{+00}$	-	-
17	<i>MO</i>	-	$5.024606 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
18	<i>ETAM</i>	-	$2.000000 \times 10^{+00}$	-	-
19	<i>PHIT</i>	V	$2.662680 \times 10^{-02}$	0.0	-
20	<i>ZET1</i>	-	$4.074464 \times 10^{-01}$	$1.0 \times 10^{-12}$	-

No.	Parameter	Units	Default	Clip low	Clip high
21	<i>VSBT</i>	V	$2.025926 \times 10^{+00}$	0.0	-
22	<i>A1</i>	-	$6.022073 \times 10^{+00}$	0.0	-
23	<i>A2</i>	V	$3.801696 \times 10^{+01}$	$1.0 \times 10^{-12}$	-
24	<i>A3</i>	-	$6.407407 \times 10^{-01}$	0.0	-
25	<i>COX</i>	F	$2.979787 \times 10^{-14}$	0.0	-
26	<i>CGDO</i>	F	$6.392000 \times 10^{-15}$	0.0	-
27	<i>CGSO</i>	F	$6.392000 \times 10^{-15}$	0.0	-
28	<i>NT</i>	J	$2.563182 \times 10^{-20}$	0.0	-
29	<i>NFMOD</i>	-	0	-	-
30	<i>NF</i>	V <sup>2</sup>	-	-	-
31	<i>NFA</i>	V <sup>-1</sup> m <sup>-4</sup>	$7.15 \times 10^{22}$	$10^{-12}$	-
32	<i>NFB</i>	V <sup>-1</sup> m <sup>-2</sup>	$2.16 \times 10^7$	-	-
33	<i>NFC</i>	V <sup>-1</sup>	0	-	-
34	<i>TOX</i>	m	$25 \times 10^{-9}$	-	-
35	<i>MULT</i>	-	1.0	0.0	-
36	<i>TH3MOD</i>	-	1.0	0.0	1.0

a. The lower bound for  $K = K_0 \cdot \frac{\sqrt{\text{hyp}_1(-V_{SBX}, \varepsilon_2)}}{\sqrt{V_{SBX} + \phi_B}}$

The default values and clipping values as used for the parameters of the electrical MOS model, level 903 (p-channel) are listed below.

No.	Parameter	Units	Default	Clip low	Clip high
1	<i>LEVEL</i>	-	903	-	-
2	<i>VTO</i>	V	$1.082125 \times 10^{+00}$	-	-
3	<i>KO</i>	$V^{1/2}$	$4.280174 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
4	<i>K</i>	$V^{1/2}$	$4.280174 \times 10^{-01}$	See note <sup>a</sup>	-
5	<i>PHIB</i>	V	$6.225999 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
6	<i>VSBX</i>	V	$1.000000 \times 10^{-12}$	$1.0 \times 10^{-12}$	-
7	<i>BET</i>	$AV^{-2}$	$4.841498 \times 10^{-04}$	0.0	-
8	<i>THE1</i>	$V^{-1}$	$2.046809 \times 10^{-01}$	0.0	-
9	<i>THE2</i>	$V^{-1/2}$	$1.492490 \times 10^{-01}$	0.0	1.0
10	<i>THE3</i>	$V^{-1}$	$3.267633 \times 10^{-02}$	-	-
11	<i>GAMI</i>	$V^{(1-\eta_{DS})}$	$9.905701 \times 10^{-01}$	0.0	-
12	<i>ETADS</i>	-	$6.000000 \times 10^{-01}$	-	-
13	<i>ALP</i>	-	$4.766925 \times 10^{-02}$	0.0	-
14	<i>VP</i>	V	$1.861200 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
15	<i>GAM00</i>	-	$1.118334 \times 10^{-02}$	0.0	-
16	<i>ETAGAM</i>	-	$1.000000 \times 10^{+00}$	-	-
17	<i>MO</i>	-	$3.801987 \times 10^{-01}$	$1.0 \times 10^{-12}$	-
18	<i>ETAM</i>	-	$1.000000 \times 10^{+00}$	-	-
19	<i>PHIT</i>	V	$2.662680 \times 10^{-02}$	0.0	-
20	<i>ZET1</i>	-	$1.270446 \times 10^{+00}$	$1.0 \times 10^{-12}$	-
21	<i>VSBT</i>	V	$1.000000 \times 10^{+02}$	0.0	-
22	<i>A1</i>	-	$6.858299 \times 10^{+00}$	0.0	-

No.	Parameter	Units	Default	Clip low	Clip high
23	<i>A2</i>	V	$5.732410 \times 10^{+01}$	$1.0 \times 10^{-12}$	-
24	<i>A3</i>	-	$4.254087 \times 10^{-01}$	0.0	-
25	<i>COX</i>	F	$2.717113 \times 10^{-14}$	0.0	-
26	<i>CGDO</i>	F	$6.358400 \times 10^{-15}$	0.0	-
27	<i>CGSO</i>	F	$6.358400 \times 10^{-15}$	0.0	-
28	<i>NT</i>	J	$2.216522 \times 10^{-20}$	0.0	-
29	<i>NFMOD</i>	-	0	-	-
30	<i>NF</i>	V <sup>2</sup>	-	-	-
31	<i>NFA</i>	V <sup>-1</sup> m <sup>-4</sup>	$1.53 \times 10^{22}$	$10^{-12}$	-
32	<i>NFB</i>	V <sup>-1</sup> m <sup>-2</sup>	$4.06 \times 10^6$	-	-
33	<i>NFC</i>	V <sup>-1</sup>	$2.92 \times 10^{-10}$	-	-
34	<i>TOX</i>	m	$25 \times 10^{-9}$	-	-
35	<i>MULT</i>	-	1.0	0.0	-
36	<i>TH3MOD</i>	-	1.0	0.0	1.0

a. The lower bound for  $K = K_0 \cdot \frac{\sqrt{\text{hyp}_1(-V_{SBX}, \epsilon_2)}}{\sqrt{V_{SBX} + \phi_B}}$

### 12.3.3 Model constants

The following is a list of constants hardcoded in the model.

No.	Constant	Units	Description
1	$T_0$	K	Offset for conversion from Celsius to Kelvin temperature scale (273.15)
2	$k$	$\text{JK}^{-1}$	Boltzmann constant ( $1.3806226 \cdot 10^{-23}$ )
3	$q$	C	Elementary unit charge ( $1.6021918 \cdot 10^{-19}$ )
4	$\epsilon_{ox}$	$\text{Fm}^{-1}$	Absolute permittivity of the oxide layer ( $3.453143800 \cdot 10^{-11}$ )

## 12.4 Parameter scaling

### 12.4.1 Geometrical scaling and temperature scaling

#### Calculation of Transistor Geometry

$$L_E = L + \Delta L_{PS} - 2 \cdot \Delta L_{\text{overlap}} \quad (12.62)$$

$$W_E = W + \Delta W_{OD} - 2 \cdot \Delta W_{\text{narrow}} \quad (12.63)$$

**WARNING :**  $L_E$  and  $W_E$  after calculation can not be less than 0 !

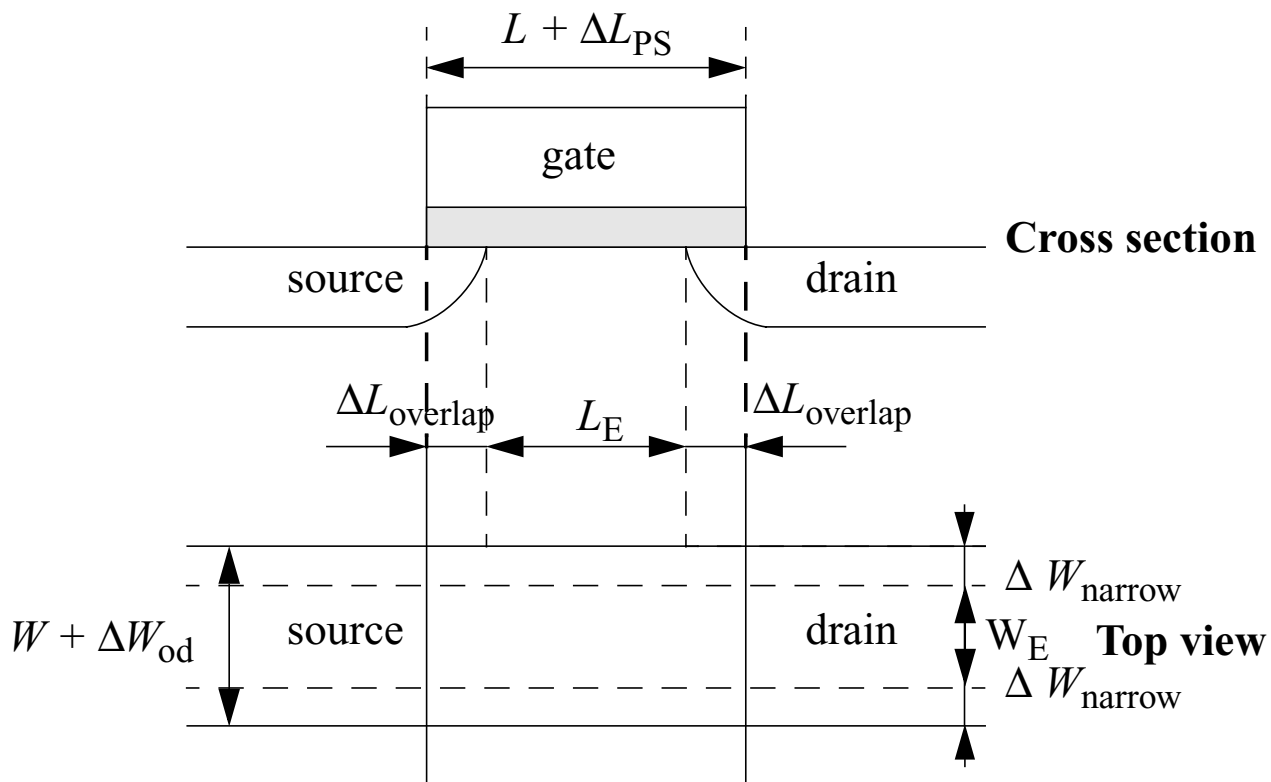


Figure 49: Specification of the dimensions of an MOS transistor

### Calculation of Transistor Temperature

$T_A$  is the ambient or the circuit temperature.

$$T_{KR} = T_0 + T_R \quad (12.64)$$

$$T_{KD} = T_0 + T_A + \Delta T_A \quad (12.65)$$

### Calculation of Threshold-Voltage Parameters

$$\tilde{V}_{T0} = V_{T0R} + (T_{KD} - T_{KR}) \cdot S_{T;V_{Tc}} \quad (12.66)$$

$$G_{P,E} = f_{\beta,1} \cdot \frac{L_{P,1}}{L_E} \left\{ 1 - \exp\left(-\frac{L_E}{L_{P,1}}\right) \right\} + \quad (12.67)$$

$$f_{\beta,2} \cdot \frac{L_{P,2}}{L_E} \left\{ 1 - \exp\left(-\frac{L_E}{L_{P,2}}\right) \right\}$$

$$G_{P,ER} = f_{\beta,1} \cdot \frac{L_{P,1}}{L_{ER}} \left\{ 1 - \exp\left(-\frac{L_{ER}}{L_{P,1}}\right) \right\} + \quad (12.68)$$

$$f_{\beta,2} \cdot \frac{L_{P,2}}{L_{ER}} \left\{ 1 - \exp\left(-\frac{L_{ER}}{L_{P,2}}\right) \right\}$$

### 3 Note

In the circuit simulator care should be taken that

$$1 + G_{P,E} \geq 10^{-15}$$

$$1 + G_{P,ER} \geq 10^{-15}$$

$$V_{T0} = \tilde{V}_{T0} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;V_{T0}} + \left( \frac{1}{L_E^2} - \frac{1}{L_{ER}^2} \right) \cdot S_{L2;V_{T0}} + \quad (12.69)$$

$$(G_{P,E} - G_{P,ER}) \cdot S_{L3;V_{T0}} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;V_{T0}}$$

$$K_0 = K_{0R} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;K_0} + \left( \frac{1}{L_E^2} - \frac{1}{L_{ER}^2} \right) \cdot S_{L2;K_0} + \quad (12.70)$$

$$\left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;K_0}$$

$$K = K_R + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;K} + \left( \frac{1}{L_E^2} - \frac{1}{L_{ER}^2} \right) \cdot S_{L2;K} + \quad (12.71)$$

$$\left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;K}$$

$$S_{T;\phi_B} = \frac{\phi_{BR} - 1.13 - 2.5 \cdot 10^{-4} \cdot T_{KR}}{300} \quad (12.72)$$

$$\phi_B = \phi_{BR} + (T_{KD} - T_{KR}) \cdot S_{T;\phi_B} \quad (12.73)$$

$$V_{SBX} = V_{SBXR} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;V_{SBX}} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;V_{SBX}} \quad (12.74)$$

### Calculation of Channel-Current Parameters

$$\tilde{\beta} = \beta_{sq} \cdot \left( \frac{T_{KR}}{T_{KD}} \right)^{\eta_{\beta}} \quad (12.75)$$

$$\beta = \frac{\tilde{\beta}}{1 + G_{P,E}} \cdot \frac{W_E}{L_E} \quad (12.76)$$

$$\tilde{\theta}_1 = \theta_{1R} + (T_{KD} - T_{KR}) \cdot S_{T;\theta_1,R} \quad (12.77)$$

$$S_{L;\theta_1} = S_{L;\theta_1,R} + (T_{KD} - T_{KR}) \cdot S_{T,L;\theta_1} \quad (12.78)$$

$$W_{EDOG} = W_{DOG} + \Delta W_{OD} - 2 \cdot \Delta W_{\text{narrow}} \quad (12.79)$$

$$W_{EDOG} \leq W_{ER}$$

$W \geq W_{DOG}$ :

$$\theta_1 = \tilde{\theta}_1 + \left\{ \frac{1}{L_E \cdot (1 + g_{\theta_1} \cdot G_{P,E})} - \frac{1}{L_{ER} \cdot (1 + g_{\theta_1} \cdot G_{P,ER})} \right\} \cdot S_{L;\theta_1} + \quad (12.80)$$

$$\left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\theta_1}$$

$$W < W_{DOG}: \\ \theta_1 = \tilde{\theta}_1 + \left\{ \frac{1}{L_E \cdot (1 + g_{\theta_1} \cdot G_{P,E})} - \frac{1}{L_{ER} \cdot (1 + g_{\theta_1} \cdot G_{P,ER})} \right\} \cdot S_{L;\theta_1} + \quad (12.81)$$

$$\left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\theta_1} + \left( \frac{W_E}{W_{EDOG}} - 1 \right) \cdot \frac{f_{\theta_1}}{L_E \cdot (1 + g_{\theta_1} \cdot G_{P,E})} \cdot S_{L;\theta_1}$$

$$\tilde{\theta}_2 = \theta_{2R} + (T_{KD} - T_{KR}) \cdot S_{T;\theta_2,R} \quad (12.82)$$

$$S_{L;\theta_2} = S_{L;\theta_2,R} + (T_{KD} - T_{KR}) \cdot S_{T,L;\theta_2} \quad (12.83)$$

$$\theta_2 = \tilde{\theta}_2 + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;\theta_2} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\theta_2} \quad (12.84)$$

$$\tilde{\theta}_3 = \theta_{3R} + (T_{KD} - T_{KR}) \cdot S_{T;\theta_3,R} \quad (12.85)$$

$$S_{L;\theta_3} = S_{L;\theta_3,R} + (T_{KD} - T_{KR}) \cdot S_{T,L;\theta_3} \quad (12.86)$$

$$\theta_3 = \tilde{\theta}_3 + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;\theta_3} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\theta_3} \quad (12.87)$$

### Calculation of Drain-Feedback Parameters

$$\gamma_1 = \gamma_{1R} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;\gamma_1} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\gamma_1} \quad (12.88)$$

$$\eta_{DS} = \eta_{DSR} \quad (12.89)$$

$$\alpha = \alpha_R + \left( \frac{1}{L_E \eta_\alpha} - \frac{1}{L_{ER} \eta_\alpha} \right) \cdot S_{L;\alpha} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;\alpha} \quad (12.90)$$

$$V_P = V_{PR} \cdot \left( \frac{L_E}{L_{ER}} \right) \quad (12.91)$$

### Calculation of Sub-Threshold Parameters

$$\gamma_{00} = \gamma_{00R} + \left( \frac{1}{L_E^2} - \frac{1}{L_{ER}^2} \right) \cdot S_{L;\gamma_{00}} + (G_{P,E} - G_{P,ER}) \cdot S_{L2;\gamma_{00}} \quad (12.92)$$

$$\eta_\gamma = \eta_{\gamma R} \quad (12.93)$$

$$\tilde{m}_0 = m_{0R} + (T_{KD} - T_{KR}) \cdot S_{T;m_0} \quad (12.94)$$

$$m_0 = \tilde{m}_0 + \left( \frac{1}{\sqrt{L_e}} - \frac{1}{\sqrt{L_{ER}}} \right) \cdot S_{L;m_0} \quad (12.95)$$

$$\eta_m = \eta_{mR} \quad (12.96)$$

$$\phi_T = \frac{k \cdot T_{KD}}{q} \quad (12.97)$$

$$\varsigma_1 = \varsigma_{1R} + \left( \frac{1}{L_E \eta_\varsigma} - \frac{1}{L_{ER} \eta_\varsigma} \right) \cdot S_{L;\varsigma_1} \quad (12.98)$$

$$V_{SBT} = V_{SBTR} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;V_{SBT}} \quad (12.99)$$

### Calculation of Weak-Avalanche Parameters

$$\tilde{a}_1 = a_{1R} + (T_{KD} - T_{KR}) \cdot S_{T;a_1} \quad (12.100)$$

$$a_1 = \tilde{a}_1 + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;a_1} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;a_1} \quad (12.101)$$

$$a_2 = a_{2R} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;a_2} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;a_2} \quad (12.102)$$

$$a_3 = a_{3R} + \left( \frac{1}{L_E} - \frac{1}{L_{ER}} \right) \cdot S_{L;a_3} + \left( \frac{1}{W_E} - \frac{1}{W_{ER}} \right) \cdot S_{W;a_3} \quad (12.103)$$

### Calculation of Charge Parameters

$$C_{ox} = \epsilon_{ox} \cdot \frac{W_E \cdot L_E}{t_{ox}} \quad (12.104)$$

$$C_{GDO} = W_E \cdot C_{ol} \quad (12.105)$$

$$C_{GSO} = W_E \cdot C_{ol} \quad (12.106)$$

### Calculation of Noise Parameters

$$N_T = \frac{T_{KD}}{T_{KR}} \cdot N_{TR} \quad (12.107)$$

$$N_F = \frac{W_{ER} \cdot L_{ER}}{W_E \cdot L_E} \cdot N_{FR} \quad (12.108)$$

$$N_{FA} = \frac{W_{ER} \cdot L_{ER}}{W_E \cdot L_E} \cdot N_{FAR} \quad (12.109)$$

$$N_{FB} = \frac{W_{ER} \cdot L_{ER}}{W_E \cdot L_E} \cdot N_{FBR} \quad (12.110)$$

$$N_{FC} = \frac{W_{ER} \cdot L_{ER}}{W_E \cdot L_E} \cdot N_{FCR} \quad (12.111)$$

## 12.4.2 MULT scaling

The *MULT* factor determines the number of equivalent parallel devices of a specified model. The *MULT* factor has to be applied on the electrical parameters. Hence after the temperature scaling and other parameter processing. Some electrical parameters cannot be specified by the user as parameters but must always be computed from geometrical parameters. They are called electrical quantities here.

The parameters:  $\beta$ ,  $C_{OX}$ ,  $C_{GDO}$ ,  $C_{GSO}$ ,  $N_F$ ,  $N_{FA}$ ,  $N_{FB}$  and  $N_{FC}$  are affected by the *MULT* factor:

$$\beta = \beta \times MULT$$

$$C_{OX} = C_{OX} \times MULT$$

$$C_{GDO} = C_{GDO} \times MULT$$

$$C_{GSO} = C_{GSO} \times MULT$$

$$N_F = N_F / MULT$$

$$N_{FA} = N_{FA} / MULT$$

$$N_{FB} = N_{FB} / MULT$$

$$N_{FC} = N_{FC} / MULT$$

Convention:

No distinction is made between the symbol before and after the *MULT* scaling, e.g: the symbol  $\beta$  represents the actual parameter after the *MULT* processing and temperature scaling. This parameter may be used to put several MOSTs in parallel.

## 12.5 Model Equations

### 12.5.1 Extended equations

Although the basic equations, given in section 12.2.2, form a complete set of model equations, they are not yet suited for a circuit simulator. Several equations have to be adapted in order to obtain smooth transitions of the characteristics between adjacent regions of operation conditions and to prevent numerical problems during the iteration process for solving the network equations. In the following section a list of numerical adaptations and elucidations is given, followed by the extended set of model equations.

The definitions of the hyp functions are found in the appendix *A Hyp functions*.

#### DC current model

$$\varepsilon_1 = 10^{-2} \quad (12.112)$$

$$\lambda_{10} = 0.9 \quad (12.113)$$

$$h_1 = \text{hyp}_1(V_{SB} + \lambda_{10} \cdot \phi_B; \varepsilon_1) + (1 - \lambda_{10}) \cdot \phi_B \quad (12.114)$$

$$u_s = \sqrt{h_1} \quad (12.115)$$

$$u_{s0} = \sqrt{\phi_B} \quad (12.116)$$

$$u_{st} = \sqrt{V_{SBT} + \phi_B} \quad (12.117)$$

$$u_{sx} = \sqrt{V_{SBX} + \phi_B} \quad (12.118)$$

$$\varepsilon_2 = 0.1 \quad (12.119)$$

$$\Delta V_{T0} = K \cdot \left\{ \sqrt{\text{hyp}_4(V_{SB}; V_{SBX}, \epsilon_2) + \left(\frac{K}{K_0}\right)^2 \cdot u_{sx}^2 - \left(\frac{K}{K_0}\right) \cdot u_{sx}} \right\} + \quad (12.120)$$

$$K_0 \cdot \left\{ \sqrt{h_1 - \text{hyp}_4(V_{SB}; V_{SBX}, \epsilon_2)} - u_{s0} \right\}$$

$$V_{T1} = V_{T0} + \Delta V_{T0} \quad (12.121)$$

$$\epsilon_3 = 10^{-2} \quad (12.122)$$

$$u_{s1} = \text{hyp}_2(u_s; u_{st}, \epsilon_3) \quad (12.123)$$

$$\gamma_0 = \gamma_{00} \cdot \left(\frac{u_{s1}}{u_{s0}}\right)^{\eta_\gamma} \quad (12.124)$$

$$\epsilon_4 = 5 \cdot 10^{-4} \quad (12.125)$$

$$V_{GT1} = \text{hyp}_1(V_{GS} - V_{T1}; \epsilon_4) \quad (12.126)$$

$$\lambda_1 = 0.1 \quad (12.127)$$

$$\lambda_2 = 10^{-4} \quad (12.128)$$

$$V_{GTX} = \frac{1}{2} \cdot \sqrt{2} \quad (12.129)$$

$$\Delta V_{T1} = \left[ -\gamma_0 - \left\{ \gamma_1 \cdot (V_{DS} + \lambda_2)^{\eta_{DS} - 1} - \gamma_0 \right\} \cdot \frac{V_{GT1}^2}{V_{GTX}^2 + V_{GT1}^2} \right] \cdot \frac{V_{DS}^2}{V_{DS} + \lambda_1} \quad (12.130)$$

$$V_{T2} = V_{T1} + \Delta V_{T1} \quad (12.131)$$

$$m = 1 + m_0 \cdot \left( \frac{u_{s0}}{u_{s1}} \right)^{\eta_m} \quad (12.132)$$

$$V_{GT2} = V_{GS} - V_{T2} \quad (12.133)$$

$$\lambda_7 = 37 \quad (12.134)$$

$$V_{GTA} = 2 \cdot m \cdot \phi_T \cdot \lambda_7 \quad (12.135)$$

$$G_1 = \begin{cases} \exp\left(\frac{V_{GT2}}{2 \cdot m \cdot \phi_T}\right), & V_{GT2} < V_{GTA} \\ \text{No assignment is necessary,} & V_{GT2} \geq V_{GTA} \end{cases} \quad (12.136)$$

$$\lambda_3 = 10^{-8} \quad (12.137)$$

$$V_{GT3} = \begin{cases} 2 \cdot m \cdot \phi_T \cdot \ln(1 + G_1) + \lambda_3, & V_{GT2} < V_{GTA} \\ V_{GT2} + \lambda_3, & V_{GT2} \geq V_{GTA} \end{cases} \quad (12.138)$$

$$\lambda_4 = 0.3 \quad (12.139)$$

$$\lambda_5 = 0.1 \quad (12.140)$$

$$\delta_1 = \frac{\lambda_4}{u_s} \cdot \left\{ K + \frac{(K_0 - K) \cdot V_{SBX}^2}{V_{SBX}^2 + (\lambda_5 \cdot V_{GT1} + V_{SB})^2} \right\} \quad (12.141)$$

$$\lambda_9 = 0.1 \quad (12.142)$$

$$\varepsilon_8 = 0.001 \quad (12.143)$$

$$V_{DSS1} = \frac{V_{GT3}}{1 + \delta_1} \cdot \frac{2}{1 + \sqrt{\lambda_9 + \text{hyp}_1 \cdot \left( 1 - \lambda_9 + \frac{2 \cdot \theta_3 \cdot V_{GT3}}{1 + \delta_1}; \varepsilon_8 \right)}} \quad (12.144)$$

$$\lambda_6 = 0.3 \quad (12.145)$$

$$V_{DSSX} = 1 \quad (12.146)$$

$$\varepsilon_5 = \lambda_6 \cdot \frac{V_{DSS1}}{V_{DSSX} + V_{DSS1}} \quad (12.147)$$

$$V_{DS1} = \text{hyp}_5(V_{DS}; V_{DSS1}, \varepsilon_5) \quad (12.148)$$

$$G_2 = 1 + \alpha \cdot \ln \left( 1 + \frac{V_{DS} - V_{DS1}}{V_P} \right) \quad (12.149)$$

$$G_3 = \begin{cases} \frac{\zeta_1 \cdot \left\{ 1 - \exp\left(\frac{-V_{DS}}{\phi_T}\right) \right\} + G_1 \cdot G_2}{\frac{1}{\zeta_1} + G_1}, & V_{GT2} < V_{GTA} \\ G_2, & V_{GT2} \geq V_{GTA} \end{cases} \quad (12.150)$$

$$I_{DS} = \beta \cdot G_3 \quad (12.151)$$

$$\cdot \frac{V_{GT3} \cdot V_{DS1} - \left(\frac{1 + \delta_1}{2}\right) \cdot V_{DS1}^2}{\{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\} \cdot (\lambda_9 + \text{hyp}_1 \cdot (1 - \lambda_9 + \theta_3 \cdot V_{DS1}; \epsilon_8))}$$

$$V_{DSA} = a_3 \cdot V_{DSS1} \quad (12.152)$$

$$I_{AVL} = \begin{cases} 0, & V_{DS} \leq V_{DSA} \\ I_{DS} \cdot a_1 \cdot \exp\left(\frac{-a_2}{V_{DS} - V_{DSA}}\right), & V_{DS} > V_{DSA} \end{cases} \quad (12.153)$$

**Charge model**

$$V_{DB} = V_{DS} + V_{SB} \quad (12.154)$$

$$h_2 = \text{hyp}_1(V_{DB} + \lambda_{10} \cdot \phi_B; \epsilon_1) + (1 - \lambda_{10}) \cdot \phi_B \quad (12.155)$$

$$\Delta V_{T0d} = K \cdot \left\{ \sqrt{\text{hyp}_4(V_{DB}; V_{SBX}, \epsilon_2) + \left(\frac{K}{K_0}\right)^2 \cdot u_{sx}^2 - \left(\frac{K}{K_0}\right) \cdot u_{sx}} \right\} + \quad (12.156)$$

$$K_0 \cdot \left\{ \sqrt{h_2 - \text{hyp}_4(V_{DB}; V_{SBX}, \epsilon_2) - u_{s0}} \right\}$$

$$V_{T1d} = V_{T0} + \Delta V_{T0d} \quad (12.157)$$

$$\delta_2 = \frac{\partial V_{T2}}{\partial V_{SB}} - \frac{\partial V_{T2}}{\partial V_{GS}} - \frac{\partial V_{T2}}{\partial V_{DS}} \quad (12.158)$$

$$\Delta_2 = \frac{\partial V_{GT3}}{\partial V_{SB}} + \frac{\partial V_{GT3}}{\partial V_{GS}} + \frac{\partial V_{GT3}}{\partial V_{DS}} \quad (12.159)$$

$$V_{DSS2} = \frac{V_{GT3}}{1 + \delta_2} \cdot \frac{2}{1 + \sqrt{\lambda_9 + \text{hyp}_1 \cdot \left(1 - \lambda_9 + \frac{2 \cdot \theta_3 \cdot V_{GT3}}{1 + \delta_2}; \epsilon_8\right)}} \quad (12.160)$$

$$\lambda_8 = 0.1 \quad (12.161)$$

$$\epsilon_7 = \lambda_8 \cdot \frac{V_{DSS2}}{V_{DSSX} + V_{DSS2}} \quad (12.162)$$

$$V_{DS2} = \text{hyp}_5(V_{DS}; V_{DSS2}, \epsilon_7) \quad (12.163)$$

$$F_J = \frac{(1 + \delta_2) \cdot \{\lambda_9 + \text{hyp}_1 \cdot (1 - \lambda_9 + \theta_3 \cdot V_{DS2}; \epsilon_8)\} \cdot V_{DS2}}{2 \cdot V_{GT3} - (1 + \delta_2) \cdot V_{DS2}} \quad (12.164)$$

$$Q_D = -C_{OX} \cdot \left[ \frac{1}{2} \cdot V_{GT3} + \Delta 2 \cdot V_{DS2} \cdot \left( \frac{1}{12} \cdot F_J + \frac{1}{60} \cdot F_J^2 - \frac{1}{3} \right) \right] \quad (12.165)$$

$$Q_S = -C_{OX} \cdot \left[ \frac{1}{2} \cdot V_{GT3} + \Delta 2 \cdot V_{DS2} \cdot \left( \frac{1}{12} \cdot F_J - \frac{1}{60} \cdot F_J^2 - \frac{1}{6} \right) \right] \quad (12.166)$$

$$\epsilon_6 = 0.03 \quad (12.167)$$

$$V_{GB} = V_{GS} + V_{SB} \quad (12.168)$$

$$V_{FB} = V_{T0} - \phi_B - K_0 \sqrt{\phi_B} \quad (12.169)$$

$$Q_{BS} = \begin{cases} -C_{OX} \cdot \text{hyp}_3(V_{GB} - V_{FB}; V_{SB} + V_{T1} - V_{FB}, \epsilon_6), & V_{GB} < V_{FB} \\ -C_{OX} \cdot K_0 \left[ -\frac{K_0}{2} + \right. \\ \left. \left[ \sqrt{\left( \frac{K_0}{2} \right)^2 + \text{hyp}_3(V_{GB} - V_{FB}; V_{SB} + V_{T1} - V_{FB}, \epsilon_6)} \right] \right], & V_{GB} \geq V_{FB} \end{cases} \quad (12.170)$$

$$Q_{BD} = \begin{cases} -C_{OX} \cdot \text{hyp}_3(V_{GB} - V_{FB}; V_{DS2} + V_{SB} + V_{T1d} - V_{FB}, \epsilon_6), & V_{GB} < V_F \\ -C_{OX} \cdot K_0 \left[ -\frac{K_0}{2} + \right. \\ \left. \left[ \sqrt{\left( \frac{K_0}{2} \right)^2 + \text{hyp}_3(V_{GB} - V_{FB}; V_{DS2} + V_{SB} + V_{T1d} - V_{FB}, \epsilon_6)} \right] \right], & V_{GB} \geq V_{FB} \end{cases} \quad (12.171)$$

$$Q_B = \frac{1}{2} \cdot (Q_{BS} + Q_{BD}) \quad (12.172)$$

$$Q_G = -(Q_D + Q_S + Q_B) \quad (12.173)$$

### Noise model

In these equations  $f$  represents the operation frequency of the transistor.

$$g_m = \frac{\partial I_{DS}}{\partial V_{GS}} \quad (12.174)$$

$$F_I = \frac{(1 + \delta_1) \cdot \{\lambda_9 + \text{hyp}_1 \cdot (1 - \lambda_9 + \theta_3 \cdot V_{DS1}; \epsilon_8)\} \cdot V_{DS1}}{2 \cdot V_{GT3} - (1 + \delta_1) \cdot V_{DS1}} \quad (12.175)$$

$$h_3 = \beta \cdot G_3 \quad (12.176)$$

$$\cdot \left[ \frac{V_{GT3} - \frac{1}{2} \cdot (1 + \delta_1) \cdot V_{DS1}}{\{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\} \cdot \{\lambda_9 + \text{hyp}_1 \cdot (1 - \lambda_9 + \theta_3 \cdot V_{DS1}; \epsilon_8)\}} \right]$$

$$h_4 = \lambda_9 + \text{hyp}_1 \cdot (1 - \lambda_9 + \theta_3 \cdot V_{DS1}; \epsilon_8) + \frac{1}{3} \cdot F_I^2 \quad (12.177)$$

$$h_5 = \frac{V_{DSS1}}{2 \cdot \phi_T} \quad (12.178)$$

$$h_6 = \begin{cases} h_3 \cdot h_4, & h_4 < h_5 \\ h_3 \cdot h_5, & h_4 \geq h_5 \end{cases} \quad (12.179)$$

$$S_{th} = N_T \cdot h_6 \quad (12.180)$$

$$\text{if NFMOD} = 0 \text{ then: } S_{fl} = N_F \cdot \frac{g_m^2}{f} \quad (12.181)$$

if NFMOD = 1 then equations: (12.182), (12.183), (12.184), (12.185), (12.186) and (12.187).

$$N_0 = \frac{\epsilon_{ox}}{qt_{ox}} \cdot V_{GT3} \quad (12.182)$$

$$N_L = \frac{\epsilon_{ox}}{qt_{ox}} \cdot (V_{GT3} - V_{DS1}) \quad (12.183)$$

$$N'' = \frac{\epsilon_{ox}}{qt_{ox}} \cdot \phi_T \cdot (m_0 + 1) \quad (12.184)$$

$$S_{wi} = N_{FA} \cdot \frac{\phi_T \cdot I_{DS}^2}{f \cdot N''^2} \quad (12.185)$$

$$\begin{aligned}
S_{si} = & \frac{\phi_T \cdot q^2 \cdot I_{DS} \cdot \beta \cdot t_{ox}^2}{f \cdot \epsilon_{ox}^2 \cdot \{1 + \theta_1 \cdot V_{GT1} + \theta_2 \cdot (u_s - u_{s0})\}} \\
& \cdot \left[ N_{FA} \cdot \ln \frac{N_0 + N''}{N_L + N''} + N_{FB} \cdot (N_0 - N_L) + \frac{1}{2} \cdot N_{FC} \cdot (N_0^2 - N_L^2) \right] \\
& + \frac{\phi_T \cdot I_{DS}^2}{f} \cdot \frac{G_2 - 1}{G_2} \cdot \left\{ \frac{N_{FA} + N_{FB} \cdot N_L + N_{FC} \cdot N_L^2}{(N_L + N'')^2} \right\}
\end{aligned} \tag{12.186}$$

$$S_{fl} = \frac{S_{si} \cdot S_{wi}}{S_{si} + S_{wi}} \tag{12.187}$$

$$S_{ig} = N_T \cdot \frac{(2 \cdot \pi \cdot f \cdot C_{OX})^2}{3 \cdot g_m} \cdot \left( 1 + 0.075 \cdot \left( \frac{2 \cdot \pi \cdot f \cdot C_{OX}}{g_m} \right)^2 \right)^{-1} \tag{12.188}$$

$$\rho_{igth} = 0.4j \tag{12.189}$$

$$\begin{aligned}
S_{igth} = & \rho_{igth} \cdot N_T \cdot 2 \cdot \pi \cdot f \cdot C_{OX} \cdot \sqrt{\frac{g_m \cdot h_6}{3 \cdot (g_m^2 + 0.075 \cdot (2 \cdot \pi \cdot f \cdot C_{OX})^2)}} \\
& g_m \geq 0
\end{aligned} \tag{12.190}$$

## 12.5.2 Numerical adaptation

- The electrical equations of MOS model 9 to be implemented are essentially based on the physical description in section 12.2. Because in circuit design equal parallel circuited transistors are frequently applied the specification of one transistor together with a multiplication factor  $N_{MULT}$  in the circuit description is convenient and saves computation time. The general and safe method to implement this mechanism into the model is to evaluate the currents, charges, noise spectral densities and their derivatives with respect to the external voltages and, at the end, to multiply them by  $N_{MULT}$ . In MOS model 9 it is allowed to circumvent these multiplications for each model evaluation during circuit simulation by adjusting some parameters.
- The dependence of the threshold voltage on the back-bias voltage is described by the Eqs. (12.1) through (12.7). Because this description is valid for  $V_{SB} \geq 0$  V, and negative values of  $V_{SB}$  can occur during the iteration process of the circuit simulator, Eq. (12.1) has been replaced by the Eqs. (12.112), (12.114) and (12.115). The difference between  $u_s$  calculated according to Eq. (12.115) and  $u_s$  of Eq. (12.1) does not exceed  $2 \cdot 10^{-4} \text{ V}^{1/2}$  for  $V_{SB} \geq 0$  V.
- The threshold-voltage shift  $V_{T0}$  of Eq. (12.5) yields satisfactory results for the channel current. It is desirable to use the same threshold-voltage shift for the charge equations, which causes a problem. Because all differential capacitances have to be continuous functions of the nodal voltages, it is obvious that via Eq. (12.34) the second derivative of  $\Delta V_{T0}$  with respect to  $V_{SB}$  has to be continuous. Unfortunately this does not hold for  $V_{SB} = V_{SBX}$ . Therefore Eq. (12.5) has been replaced by Eq. (12.120). For  $V_{SB} = 0$  V the results of Eq. (12.5) and of Eq. (12.120) are equal, while the largest deviation ( $< 4$  mV) is obtained at  $V_{SB} = V_{SBX}$ .
- The threshold-voltage shift  $\Delta V_{T1}$ , described in Eq. (12.11), contains two parts, the first part dominates for  $V_{GT1} < V_{GTX}$  and the second part for  $V_{GT1} > V_{GTX}$ . To balance these parts for a monotonic behaviour of  $I_{DS}$  versus  $V_{SB}$   $\gamma_0$  should not increase unlimited with  $V_{SB}$ . This clipping: Eqs. (12.7) and (12.8), occurs at  $V_{SB} = V_{SBT}$ , which is far out of the practical region of operation. For mathematical reasons a smooth clipping, Eq. (12.123), has to be implemented instead of Eq. (12.7).
- The equation of the threshold-voltage shift  $\Delta V_{T1}$ , Eq. (12.11), provides first and second derivative functions with respect to  $V_{DS}$ , which are not well-behaved functions for  $V_{DS} = 0$  V due to  $\eta_{DS} \approx 0.6$ . Therefore Eq. (12.11) has to be replaced by:

$$\Delta V_{T1} = \left\{ -\gamma_0 \frac{V_{GTx}^2}{V_{GTx}^2 + V_{GT1}^2} - \gamma_1 \frac{V_{GT1}^2}{V_{GTx}^2 + V_{GT1}^2} (V_{DS} + \lambda_2)^{\eta_{DS}-1} \right\} \cdot \left( \frac{V_{DS}^2}{V_{DS} + \lambda_1} \right)$$

in which  $\lambda_1$  and  $\lambda_2$  are model constants. This equation can be simplified. The expression between braces smoothly transits from  $-\gamma_0$  to  $-\gamma_1 \cdot (V_{DS} + \lambda_2)^{\eta_{DS}-1}$  which is controlled by the two weighting functions of  $V_{GT1}$  which sum equals one. Using one of these functions only, we obtain Eq. (12.130).

- The voltage  $V_{GS}$  controls via  $V_{GT2}$ , Eq. (12.14), and  $G_1$ , Eq. (12.15), the functional behaviour of  $V_{GT3}$ , Eq.(12.16) and  $G_3$ , Eq. (12.26). For the subthreshold region:

$$V_{GT3} \approx 2 \cdot m \cdot \phi_T \cdot \exp\left(\frac{V_{GT2}}{2 \cdot m \cdot \phi_T}\right)$$

and:

$$G_3 \approx \zeta_1^2 \cdot \left\{ 1 - \exp\left(\frac{-V_{DS}}{\phi_T}\right) \right\},$$

and for large values of  $V_{GS}$   $V_{GT3} \approx V_{GT2}$  and  $G_3 \approx G_2$ . Although the Eqs. (12.16) and (12.26) are well-behaved analytical functions of  $G_1$ , they will cause numerical problems due to the limited value range of the numbers, which can be represented by the computer. If  $x$  exceeds the allowed maximum value of the argument range of the exp-function  $\ln\{\exp(x)\} \neq x$  and  $\exp(x) \cdot y / \exp(x) \neq y$  with  $y > 1$ . To prevent this a maximum value for the argument range  $\lambda_7$  has been specified, which is the lowest-value of the computer implementations of the circuit simulator, Eq. (12.134). For small values of the arguments i.e.  $V_{GT2} < V_{GTA}$ , Eq. (12.135),  $G_1$ ,  $V_{GT3}$  and  $G_3$  are calculated according to Eqs. (12.15), (12.16) and (12.26). But for  $V_{GT2} \geq V_{GTA}$  no assignment is done to  $G_1$ , Eq. (12.136), calculated asymptotic values are assigned to  $V_{GT3}$  and  $G_3$  Eqs. (12.138) and (12.150).

- As  $V_{GT3}$  decreases to zero the denominator of Eq. (12.37) approaches zero. The addition of a small constant to the denominator is not a good solution for this problem because the first derivatives of  $Q_D$  and  $Q_S$  will become discontinuous functions. Therefore a small constant  $\lambda_3$  has been added to  $V_{GT3}$ , Eq. (12.138).

- At the outset the charge equations for  $Q_D$  and  $Q_S$  has been derived for  $V_{GS} > V_{T2}$ . To extend the validity range of these original equations to the subthreshold region  $V_{GT3}$  has been introduced. The remaining problem, the discontinuous transition between the derivatives  $dQ_D/dV_S$  and  $dQ_S/dV_D$  around  $V_{DS} = 0$ , can be solved by replacing  $1 + \delta$  in Eqs. (12.38) and (12.39) by  $\Delta_2$ , Eq. (12.159). This yields the Eqs. (12.165) and (12.166).
- The derivation of the equation for the bulk charges  $Q_{BS}$  and  $Q_{BD}$ , Eqs. (12.42) and (12.43), had to be performed for three successive ranges of  $V_{GB}$ . Unfortunately, the first derivatives of  $Q_{BS}$  and  $Q_{BD}$  with respect to  $V_{GB}$  are not continuous at the boundaries  $V_{SB} + V_{T2}$  and  $V_{DB} + V_{T1d}$ , respectively. A simple remedy is the introduction of the smoothing function  $\text{hyp}_3$  into Eqs. (12.42) and (12.43), leading to Eqs. (12.170) and (12.171).
- Calculating the value of the spectral densities for frequency zero leads to a division by zero in Eq. (12.181) and also in Eqs. (12.188), (12.190) when  $g_m = 0$ . For these exceptional cases the noise spectral densities should be put to zero.

## 12.6 DC operating point output

The DC operating point output facility gives information on the state of a device at its operation point. Besides terminal currents and voltages, the magnitudes of linearized internal elements are given. In some cases meaningful quantities can be derived which are then also given (e.g.  $F_{ug}$ ). The objective of the DCOP-facility is twofold:

- Calculate small-signal equivalent circuit element values.
- Open a window on the internal bias conditions of the device and its basic capabilities (e.g.  $F_{ug}$ ).

Below the printed items are described.  $C_{x(y)}$  indicates the derivate of the charge  $Q$  at terminal  $x$  to the voltage at terminal  $y$ , when all other terminals remain constant.

Quantity	Equation	Description
Level	903	Model level
$I_{ds}$		Drain current, excluding substrate current
$I_{avl}$		Substrate current
$V_{ds}$		Drain-Source voltage
$V_{gs}$		Gate-Source voltage
$V_{sb}$		Source-Bulk voltage
$V_{TO}$		Threshold voltage after geometric and T-scaling
$V_{TS}$	$V_{T1}$	$V_{TO}$ including backbias effects
$V_{GT}$	$V_{GT2}$	Effective gate drive including backbias and drain effects
$V_{dss}$	$ V_{DSS1} $	Saturation voltage at actual bias
$V_{sat}$	$ V_{ds}  - V_{dss}$	Saturation limit
$g_m$	$dI_{ds}/dV_{gs}$	transconductance (assumed $V_{ds}>0$ )
$g_{mb}$	$dI_{ds}/dV_{bs}$	bulk transconductance (assumed $V_{ds}>0$ )
$g_{ds}$	$dI_{ds}/dV_{ds}$	output conductance

Quantity	Equation	Description
$C_{d(d)}$	$+CDDS$	$+dQ_d/dV_d$
$C_{d(g)}$	$-CDGS$	$-dQ_d/dV_g$
$C_{d(s)}$	$+CDDS+CDGS-CDSB$	$-dQ_d/dV_s$
$C_{d(b)}$	$+CDSB$	$-dQ_d/dV_b$
$C_{g(d)}$	$-CGDS$	$-dQ_g/dV_d$
$C_{g(g)}$	$+CGGS$	$+dQ_g/dV_g$
$C_{g(s)}$	$+CGDS+CGGS-CGSB$	$-dQ_g/dV_s$
$C_{g(b)}$	$+CGSB$	$-dQ_g/dV_b$
$C_{s(d)}$	$-CSDS$	$-dQ_s/dV_d$
$C_{s(g)}$	$-CSGS$	$-dQ_s/dV_g$
$C_{s(s)}$	$-CSDS-CSGS+CSSB$	$+dQ_s/dV_s$
$C_{s(b)}$	$+CSSB$	$-dQ_s/dV_b$
$C_{b(d)}$	$-CBDS$	$-dQ_b/dV_d$
$C_{b(g)}$	$-CBGS$	$-dQ_b/dV_g$
$C_{b(s)}$	$+CBDS+CBGS-CBSB$	$-dQ_b/dV_s$
$C_{b(b)}$	$-CBSB$	$+dQ_b/dV_b$
$C_{GDOL}$	$C_{OL} \cdot W_E$	Drain overlap capacitance of the actual transistor
$C_{GSOL}$	$C_{OL} \cdot W_E$	Gate overlap capacitance of the actual transistor
$W_{\text{eff}}$		Effective channel width for geometrical models
$L_{\text{eff}}$		Effective channel length for geometrical models
$u$	$g_m/g_{ds}$	Transistor gain
$R_{\text{out}}$	$1/g_{ds}$	Small signal output resistance
$V_{\text{m early}}$	$ I_d /g_{ds}$	Equivalent Early voltage

Quantity	Equation	Description
$K_{\text{eff}}$	$\frac{(V_{T1} - V_{T0})}{\sqrt{V_{SB} + 2\phi_B} - \sqrt{2\phi_B}}$	Describes body effect at actual bias
$B_{\text{eff}}$	$\frac{2 I_{ds} }{V_{GT}^2}$	Effective $\beta$ at actual bias in the simple MOS model
$F_{ug}$	$g_m / (2\pi C_{in})$	Unity gain frequency at actual bias
$SQRT(S_{fw})$	$\sqrt{S_{th}} / g_m$	input-referred RMS white noise voltage
$SQRT(S_{ff})$	$\sqrt{S_{fl}(1\text{kHz})} / g_m$	input-referred RMS 1/f noise voltage at 1 kHz
$F_{\text{knee}}$	$1\text{Hz} \cdot S_{fl}(1\text{Hz}) / S_{th}$	Cross-over frequency above which white noise is dominant

### Remarks:

- When  $V_{ds} < 0$ ,  $g_m$  and  $g_{mb}$  are calculated with drain and source terminals interchanged (see section on Channel Type Declarations). The terminal voltages and  $I_{DS}$  keep their sign.
- The signs of  $V_{T0}$  and  $V_{T1}$  follow the conventions of the model parameter set. The parameter set is always assumed to correspond to an n-channel device.
- The *simple model* mentioned above states that:

$$I_d = \begin{cases} \beta_{\text{eff}} \cdot [V_{GT} V_{ds} - V_{ds}^2 / 2] & V_{ds} \leq V_{dss} \\ \beta_{\text{eff}} \cdot V_{GT}^2 / 2 & V_{ds} > V_{dss} \end{cases}$$

- The calculation of  $F_{ug}$  assumes that the total load capacitance on the drain is identical to  $C_{ox}$  so that the actual load in the circuit is not taken into account! Intrinsically  $F_{ug}$  is related to the transit time:

$$T_{tr} = \frac{3}{4} \frac{L^2_{\text{eff}}}{\mu_{\text{eff}} V_{GT}}$$

where  $\mu_{eff} = B_{eff}/C_{ox}$ . However as this transit time has no practical meaning, the rough estimation of the unity gain frequency is preferred.

- The input referred noise power densities  $S_{fw}$  and  $S_{ff}$  are only defined when  $g_m > 0$ .
- $W$  and  $L$  are not available for the electrical MOS models.
- $MULT$  is a scaling parameter that multiplies all currents and charges by the value of  $MULT$ . This is equivalent to putting  $MULT$  (a number) MOS transistors in parallel. And as a consequence  $MULT$  effects the operating point output.

A non-existent conductance,  $G_{min}$ , is connected between the nodes  $D$  and  $S$ . This conductance  $G_{min}$  does not influence the DC-operating point.

- $$C_{in} = C_{g(g)} + C_{gsol} + C_{gdol}$$

## 12.7 Embedding

### 12.7.1 Model embedding in a circuit simulator

Although CMOS processes support n- and p-channel MOS's, Model 9 only knows n-channel devices. This can easily be circumvented by mapping a p-channel device with its bias conditions and parameter set onto an equivalent n-channel device with appropriately changed bias conditions and parameters. The criterion is that the equivalent model plus bias conditions plus parameter set should attribute the same charge and the same current value and current direction (DC, AC and noise) to any physical node involved when compared to a hypothetical model that supports both device types.

As said earlier, any circuit simulator internally identifies the terminals of a MOS transistor by a number. However, designers are used to the standard terminology of source, drain, gate and bulk. Therefore, in the context of a circuit simulator it is traditionally possible to address, say, the drain of MOS number 17, even if in reality the corresponding source is at a higher potential (n-channel case). More strongly, most circuit simulators provide for model evaluation a so-called  $V_{DS}$ ,  $V_{GS}$ , and  $V_{SB}$  based on an a priori assignment of source, drain and bulk that is independent of the actual bias conditions. The basic Model 903 cannot cope with bias conditions that correspond to  $V_{DS} < 0$ . Again a transformation of the bias conditions is necessary. In this case, the transformation corresponds to internally reassigning source and drain, applying the standard electrical model, and then reassigning the currents and charges to the original terminals. Especially in combination with weak avalanche and with noise calculations, enormous care should be taken in incorporating these changes.

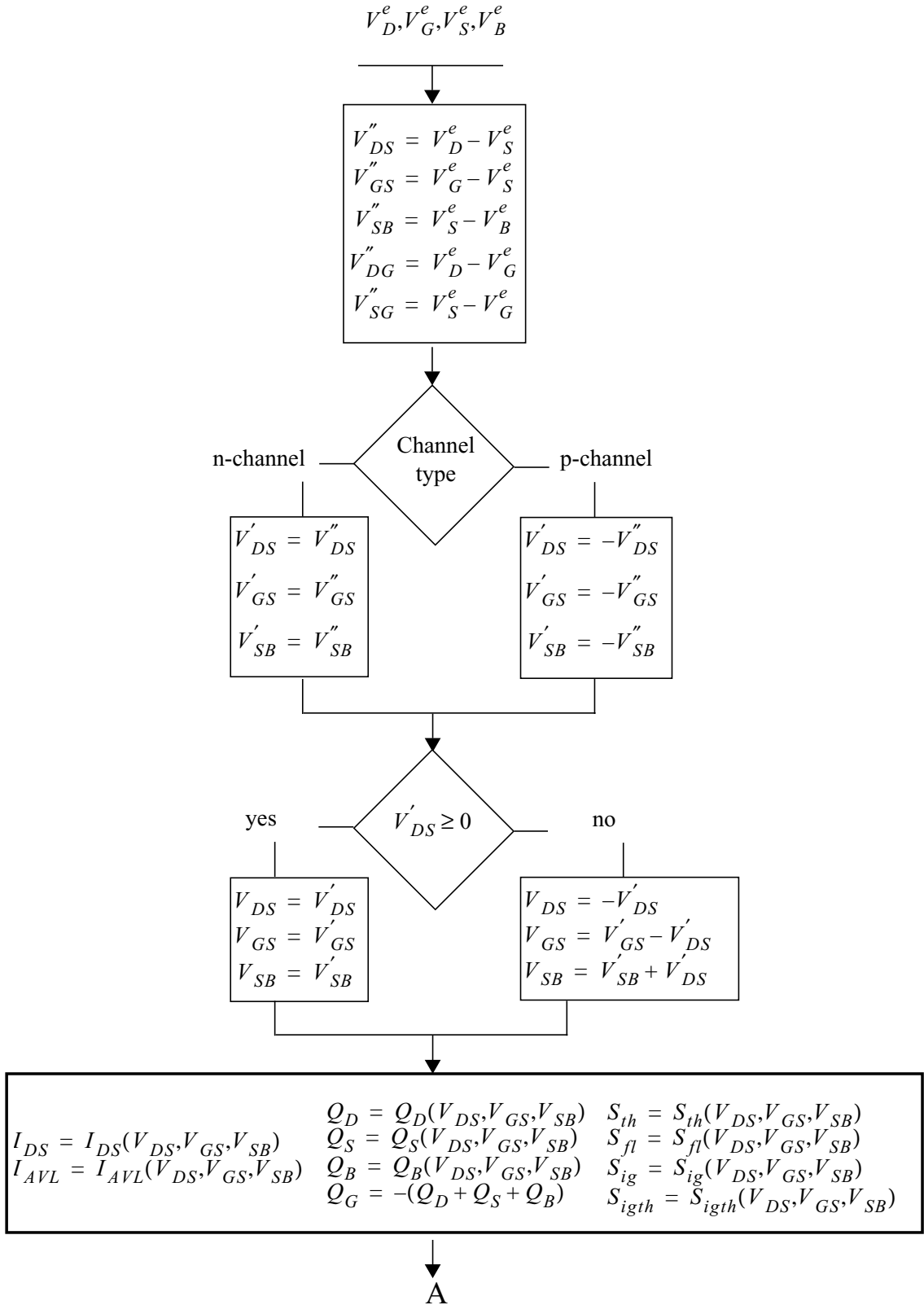
In detail, in order to embed Model 903 correctly into a circuit simulator, the following procedure, illustrated in Figure 50 should be followed.

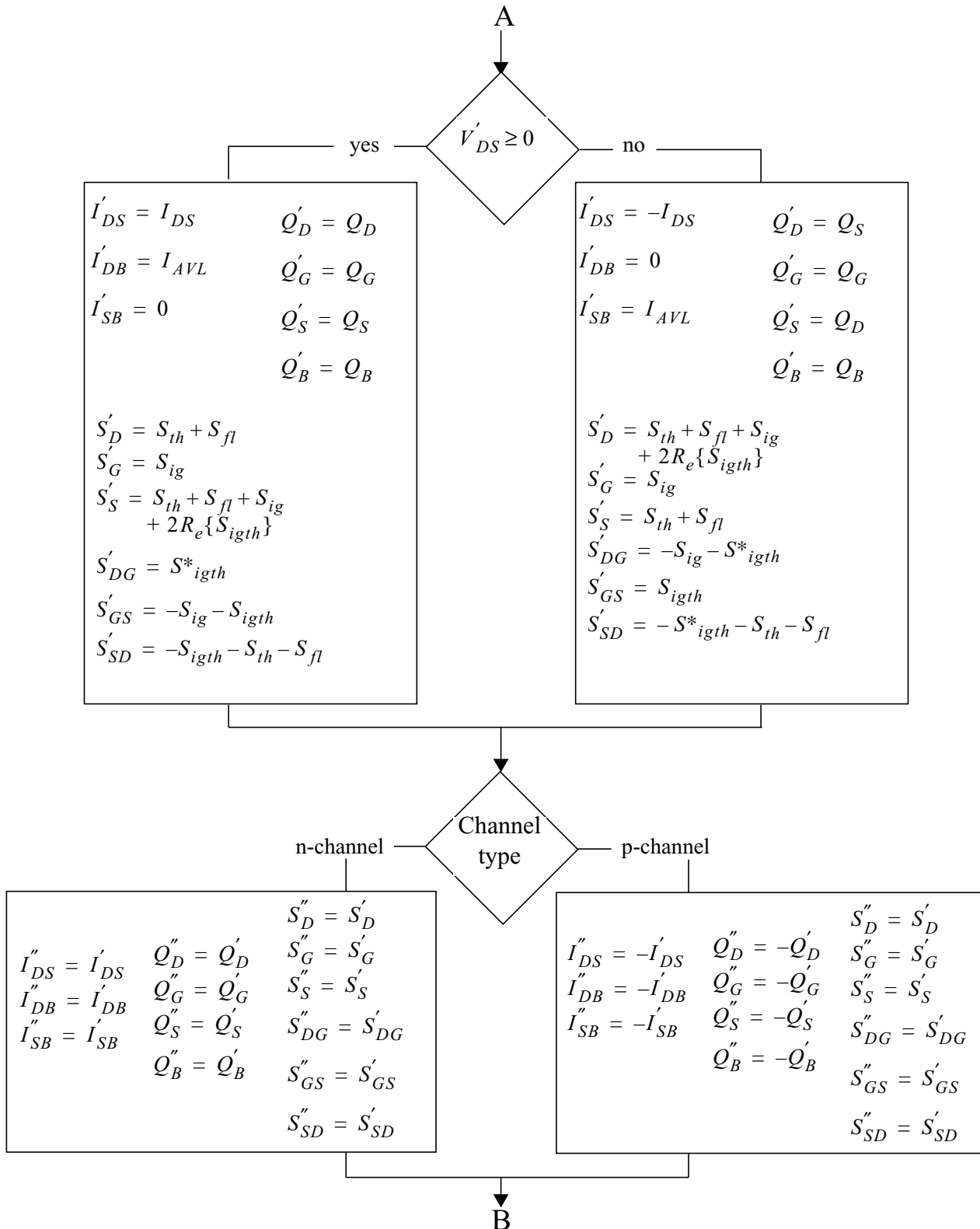
We have assumed that indeed the simulator provides the nodal potentials  $V_D^e$ ,  $V_G^e$ ,  $V_S^e$  and  $V_B^e$  based on an a priori assignment of drain, gate, source and bulk.

**Step 1** Calculate the voltages  $V_{DS}''$ ,  $V_{GS}''$  and  $V_{SB}''$ , and the additional voltages  $V_{DG}''$  and  $V_{SG}''$ . The latter are used for calculating the charges associated with overlap capacitances.

**Step 2** Based on n- or p-channel devices, calculate the modified voltages  $V'_{DS}$ ,  $V'_{GS}$  and  $V'_{SB}$ . From here onwards only n-channel behaviour needs to be considered.

**Step 3** Based on a positive or negative  $V'_{DS}$ , calculate the internal nodal voltages. At this level, the voltages - and the parameters, see below - comply to all the requirements for input quantities of Model 9.





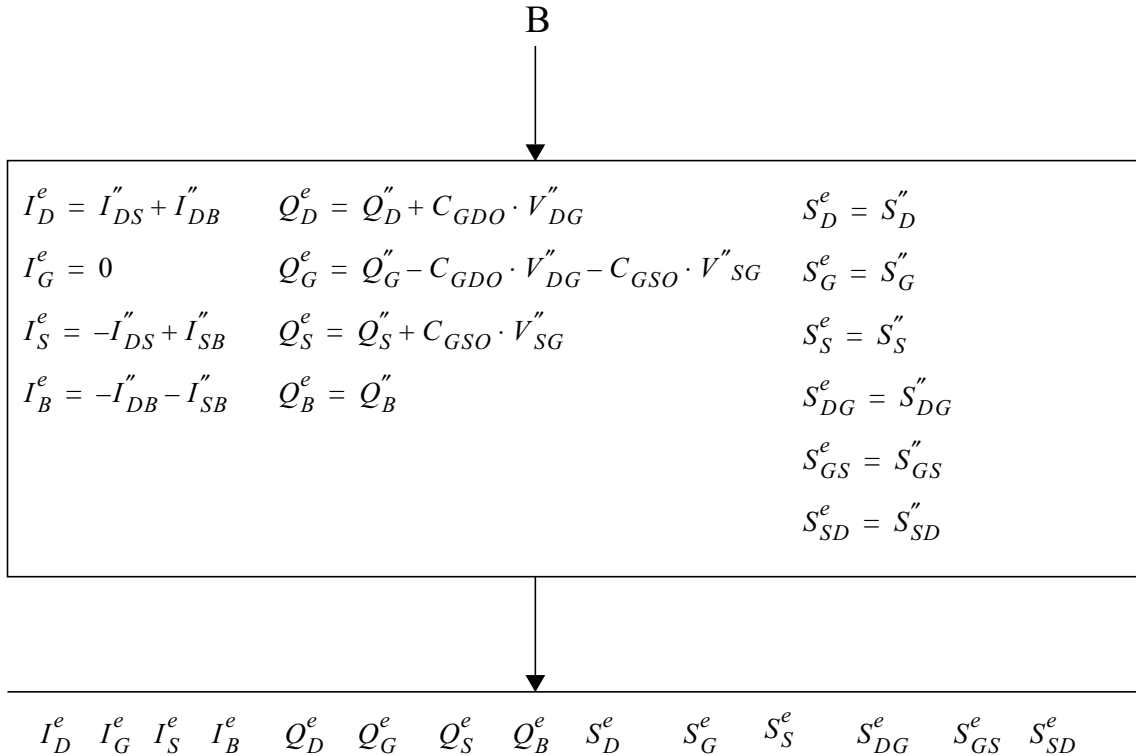


Figure 50: Transformation scheme

- Step 4** Evaluate all the internal output quantities - channel current, weak-avalanche current, nodal charges, and noise-power spectral densities - using the standard Model 9 equations and the internal voltages.
- Step 5** Correct the internal output quantities for a possible source-drain interchange. In fact, this directly establishes the external noise-power spectral densities.
- Step 6** Correct for a possible p-channel transformation.
- Step 7** Change from branch current to nodal currents, establishing the external current output quantities. Calculate the overlap charges that are related to the physical regions and add them to the nodal charges, thus forming the external charge output quantities.

It is customary to have separate user models in the circuit simulators for p- and n-channel transistors. In that manner it is easy to use different "maxi-set" parameters for the two channel types. As a consequence, the changes in the parameter values necessary for a p-channel-type transistor are normally already included in the parameter sets on file. The changes should not be included in the simulator. It is the responsibility of the persons that do the parameter determination to do so!

## 12.7.2 Implementation issues

### Cross spectral densities of noise currents in MOS MODEL 9

The cross spectral densities as mentioned in Figure 50 are found in the following way (See also Figure 45, [10] and [11]):

The noise currents  $i_s$ ,  $i_d$  and  $i_g$ , (all in  $A/\sqrt{Hz}$ ) are defined as in Figure 51 below:

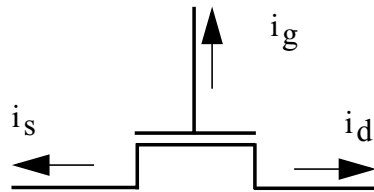


Figure 51: Noise currents in a MOSFET

Here  $i_d$  consists of two (uncorrelated) parts  $i_{D,th}$  and  $i_{D,fl}$ , describing the thermal noise and flicker noise respectively:

$$i_D = i_{D,th} + i_{D,fl} \quad (12.191)$$

Conservation of current and no noise current flowing to the bulk, leads to:

$$i_S = -i_D - i_G \quad (12.192)$$

Noise spectral densities are defined by:

$$S_{th} \equiv \langle i_{D,th} i_{D,th}^* \rangle \quad (12.193)$$

$$S_{fl} \equiv \langle i_{D,fl} i_{D,fl}^* \rangle \quad (12.194)$$

$$S_{ig} \equiv \langle i_G i_G^* \rangle \quad (12.195)$$

where  $\langle \rangle$  denotes the time average. Gate current and drain current thermal noise are correlated. The correlation is given by the complex spectral density  $S_{igth}$ :

$$S_{igth} \equiv \langle i_G i_{D,th}^* \rangle \quad (12.196)$$

$$\begin{aligned} S_S &\equiv \langle i_S i_S^* \rangle \\ &= \langle (-i_D - i_G)(-i_D - i_G)^* \rangle \\ &= \langle i_D i_D^* \rangle + \langle i_G i_G^* \rangle + \langle i_D i_G^* \rangle + \langle i_G i_D^* \rangle \end{aligned} \quad (12.197)$$

$$= S_{th} + S_{fl} + S_{ig} + 2Re \cdot (S_{igth}) \quad (12.198)$$

The noise spectral densities  $S_D$  and  $S_G$  are simply:

$$S_D = S_{th} + S_{fl} \quad (12.199)$$

$$S_G = S_{ig} \quad (12.200)$$

Now we turn to the cross-spectral densities and calculate  $S_{DG}$ :

$$\begin{aligned} S_{DG} &= \langle i_D i_G^* \rangle \\ &= \langle i_{D,th} i_G^* \rangle + \langle i_{D,fl} i_G^* \rangle \\ &= S_{igth}^* \end{aligned} \quad (12.201)$$

$S_{GD}$  is the complex conjugate of  $S_{DG}$ :

$$S_{GD} = \langle i_G i_D^* \rangle = S_{igth}$$

Similarly,  $S_{GS}$  is given by:

$$\begin{aligned}
 S_{GS} &= \langle i_G i^*_S \rangle \\
 &= \langle i_G (-i_D - i_G)^* \rangle \\
 &= -\langle i_G i^*_D \rangle - \langle i_G i^*_G \rangle \\
 &= -\langle i_G i^*_{D, th} \rangle - \langle i_G i^*_{D, fl} \rangle - \langle i_G i^*_G \rangle \\
 &= -S_{igth} - S_{ig} \tag{12.202}
 \end{aligned}$$

$S_{SG}$  is the complex conjugate of  $S_{GS}$ :

$$= -S^*_{igth} - S_{ig} \tag{12.203}$$

$$\begin{aligned}
 S_{SD} &= \langle i_S i^*_D \rangle \\
 &= \langle (-i_D - i_G) i^*_D \rangle \\
 &= S_{th} - S_{fl} - S_{igth} \tag{12.204}
 \end{aligned}$$

$$S_{DS} = -S_{th} - S_{fl} - S^*_{igth} \tag{12.205}$$

It is convenient to summarize the results in matrix form:

$$\bar{\bar{S}} = \begin{bmatrix} S_D & S_{DG} & S_{DS} \\ S_{GD} & S_G & S_{GS} \\ S_{SD} & S_{SG} & S_S \end{bmatrix}$$

$$= \begin{bmatrix} S_{th} + S_{fl} & S_{igth}^* & -S_{th} - S_{fl} - S_{igth}^* \\ S_{igth} & S_{ig} & -S_{igth} - S_{ig} \\ -S_{th} - S_{fl} - S_{igth} & -S_{igth}^* - S_{ig} & S_{th} + S_{fl} + S_{ig} + 2Re \cdot (S_{igth}) \end{bmatrix} \quad (12.206)$$

The above applies to the case  $V_{DS} \geq 0$ . In case  $V_{DS} < 0$  we obtain the right equations from equation 12.206 by switching columns 1 and 3 and then switching rows 1 and 3:

$$\bar{S} = \begin{bmatrix} S_D & S_{DG} & S_{DS} \\ S_{GD} & S_G & S_{GS} \\ S_{SD} & S_{SG} & S_S \end{bmatrix}$$

$$= \begin{bmatrix} S_{th} + S_{fl} + S_{ig} + 2Re \cdot (S_{igth}) & -S_{igth}^* - S_{ig} & -S_{th} - S_{fl} - S_{igth} \\ -S_{igth} - S_{ig} & S_{ig} & S_{igth} \\ -S_{th} - S_{fl} - S_{igth}^* & S_{igth}^* & S_{th} + S_{fl} \end{bmatrix} \quad (12.207)$$

## 12.8 Simulator specific items

### 12.8.1 Pstar syntax

n channel electrical model:mne\_n (d,g,s,b)level=903, <parameters>  
 p channel electrical model:mpe\_n(d,g,s,b)level=903, <parameters>  
 n channel geometrical model:mn\_n (d,g,s,b)level=903, <parameters>  
 p channel geometrical model:mp\_n (d,g,s,b)level=903, <parameters>

n           :occurrence indicator  
 <parameters>:list of model parameters  
 d,g,s and b are drain, gate, source and bulk terminals respectively.

### 12.8.2 Spectre syntax

n channel geometrical model:model modelname mos903 type=n <modpar>  
                   componentname d g s b modelname <inpar>  
 p channel geometrical model:model modelname mos903 type=p <modpar>  
                   componentname d g s b modelname <inpar>

modelname:name of model, user-defined  
 componentname:occurrence indicator  
 <modpar>:list of model parameters  
 <inpar>   :list of instance parameters  
 d,g,s and b are drain, gate, source and bulk terminals respectively.

### 3 Note

---

There is no electrical model MOS903 available in *Spectre*.

---

### 3 Note

---

Warning! In Spectre, use only the parameter statements type=n or type=p. Using any other string and/or numbers will result in unpredictable and possibly erroneous results.

---

### 12.8.3 ADS syntax

MOS9 level 903 is not supported in ADS.

### 12.8.4 The ON/OFF condition for Pstar

The solution for a circuit involves a process of successive calculations. The calculations are started from a set of 'initial guesses' for the electrical quantities of the nonlinear elements. A simplified DCAPPROX mechanism for devices using ON/OFF keywords is mentioned in [12]. By default the devices start in the default state.

n-channel				p-channel			
	Default	ON	OFF		Default	ON	OFF
$V_{DS}$	2.5	2.5	5.0	$V_{DS}$	-2.5	-2.5	-5.0
$V_{GS}$	2.5	2.5	0.0	$V_{GS}$	-2.5	-2.5	0.0
$V_{SB}$	0.0	0.0	0.0	$V_{SB}$	0.0	0.0	0.0

### 12.8.5 The ON/OFF condition for Spectre

	OFF	Triode	Saturation	Subthreshold
$Gds$	0.0	2.0*BETA	1e-4	1e-4

### 12.8.6 The ON/OFF condition for ADS

MOS9 level 903 is not supported in ADS.

## 12.9 Parameter Extraction

The parameter extraction for MOST model 9 using an **optimisation method** is described step-by-step in the scheme below. The equations used for the parameter extraction are the basic equations of section 12.2. The simultaneous determination of all parameters is not possible, because the value of some parameters can be wrong due to suboptimisation. Therefore it is more practical to split the parameters into five groups, and, for each group, to measure the characteristics according to the indicated conditions and to determine the particular parameters. It should be noticed that for the p-channel MOST all voltage and current values have to change sign upon entering the optimisation programme as a p-MOST is treated as an equivalent n-MOST.

The bias conditions to be used for the measurements are dependent on the supply voltage of the process. Of course it is advisable to restrict the range of voltages to this supply voltage  $V_{\text{sup}}$ . Otherwise physical effects, atypical for normal transistor operation and therefore less well described by MOST model 9, may dominate the characteristics. This can lead for certain processes to parameter values dependent on the selected range of voltages.

Before the optimisation starts a parameter set has to be determined which contains a first estimation of the parameters to be extracted and the parameters which remain constant. The values of  $\phi_{\text{B}}$  and  $\phi_{\text{T}}$  are calculated from the device temperature  $T_{\text{KD}}$  and  $\phi_{\text{BR}}$  according eqn. Eq. (12.73) and Eq. (12.96). From our experience with different processes  $\eta_{\text{DS}}$  is set to 0.6. The values of  $\eta_{\gamma}$  and  $\eta_{\text{m}}$  which characterise the subthreshold behaviour, are 2 for the double  $k$ -factor model and 1 for the single  $k$ -factor model.

With this parameter set a first optimisation following the scheme below, is performed. After this the new parameter set serves as an estimation for the second optimisation, which is performed following the same scheme. This method yields a proper set of parameters after the second optimisation. Experiments with transistors of different processes show that the parameter set does not change very much after a third optimisation.

The parameter extraction contains the following steps:

- $I_D$ - $V_{GS}$ :

- n-channel :  $V_{GS} = 0 \dots V_{sup}$  (at least 10 steps).  
 $V_{DS} = 0.1 \text{ V}$   
 $V_{BS} = 0 \text{ V}$
- p-channel :  $V_{GS} = 0 \dots -V_{sup}$  (at least 10 steps).  
 $V_{DS} = -0.1 \text{ V}$   
 $V_{BS} = 0 \text{ V}$

Determination of  $V_{T0}$ ,  $\beta$  and  $\theta_1$ .

- $I_D$ - $V_{GS}$ :

- n-channel :  $V_{GS} = 0 \dots V_{sup}$  (at least 10 steps).  
 $V_{DS} = 0.1 \text{ V}$   
 $V_{BS} = 0 \dots -V_{sup}$
- p-channel :  $V_{GS} = 0 \dots -V_{sup}$  (at least 10 steps).  
 $V_{DS} = -0.1 \text{ V}$   
 $V_{BS} = 0 \dots V_{sup}$

Determination of  $\theta_2$ ,  $k$ ,  $k_0$  and  $V_{SBX}$  for a n-channel and determination of  $\theta_2$  and  $k$  for a p-channel.

It is recommended not to incorporate the subthreshold description in the optimisation of the parameters for the  $I_D$ - $V_{GS}$  behaviour in the linear region because suboptimisations may result in wrong values and strange characteristics. So during such an optimisation, values of  $I_D$  with  $V_{GS}$  under  $V_T$  have to be neglected.

Normally the value of  $k_0$  is larger than the value of  $k$ . But for certain processes the value of  $V_T$  versus  $V_{BS}$  shows a different behaviour and the value of  $k_0$  is smaller than the value of  $k$ . This behaviour can also be described with the model, but the parameters for this description are very difficult to determine from the above measurements. Therefore these parameters have to be determined from the measurements in the subthreshold region.

- Subthreshold:

n-channel :  $V_{GS} = V_{GS1} \dots V_{GS2}$  with  $I_{DS}(V_{GS1}) \approx 10$  pA and  $V_{GS2} > V_{T1}$ .  
 $V_{DS} = 3$  values starting from 1 V to  $V_{sup}$   
 $V_{BS} = 0$  V

p-channel :  $V_{GS} = -V_{GS1} \dots -V_{GS2}$  with  $I_{DS}(-V_{GS1}) \approx -10$  pA and  $V_{GS2} > V_{T1}$ .  
 $V_{DS} = 3$  values starting from -1 V to  $-V_{sup}$   
 $V_{BS} = 0$  V

Determination of  $\gamma_{00}$ ,  $m_0$ ,  $\zeta_1$ .

For short-channel transistors  $V_{SBT}$  also has to be determined. Therefore three  $V_{BS}$  are used starting from 0 V to  $-V_{sup}$  (for n-channel transistors) or  $V_{sup}$  (for p-channel transistors).

If  $V_{SBT}$  is not important, this parameter has to be large! In this case its value is set 100 V. In the subthreshold region it is in principle possible to determine the values of  $\eta_\gamma$  and  $\eta_m$ . It is also possible to verify in the subthreshold region the correctness of the values of  $k$  and  $k_0$ . If necessary these parameters can be corrected in order to obtain a better subthreshold behaviour fit.

The output conductance values are extracted from the measurements of  $I_D$ - $V_{DS}$  by calculating in a numerical way the derivative of  $I_D$  to  $V_{DS}$ .

- Output conductance:

n-channel :  $V_{DS} = 0.1 \dots V_{sup}$  (step 0.2 V).  
 $V_{GS} = 3$  values starting above threshold, not above  $V_{sup}$   
 $V_{BS} = 3$  values starting from 0 V to  $-V_{sup}$

p-channel :  $V_{DS} = -0.1 \dots -V_{sup}$  (step -0.2 V).  
 $V_{GS} = 3$  values starting below threshold, not below  $-V_{sup}$   
 $V_{BS} = 3$  values starting from 0 V to  $V_{sup}$

For analogue purposes the behaviour of the output conductance for values at  $V_T + 100$  mV is also important.

Determination of  $\gamma_1$ ,  $\alpha$ . For long-channel transistors,  $V_P$  is also determined.

Because  $V_P \sim L_E$ , it is difficult to determine this parameter for short-channel transistors. Therefore the proportionality factor for a long-channel transistor is determined and then  $V_P$  for a short-channel transistor is calculated. With this calculated value of  $V_P$ , the values of  $\alpha$  and  $\gamma_1$  are determined for a short-channel transistor.

If there is no long-channel transistor available one can determine the parameters  $\gamma_1$ ,  $\alpha$  and  $V_P$  from the measurements of the output conductance at  $V_{BS} = 0$  V. Experiments with C300 transistors show that these values are in good agreement with the values, obtained with calculation and optimisation.

Measurements with  $V_{GS}$  near threshold, can be used to check the value of  $\gamma_{00}$  after the optimisation of  $V_P$ ,  $\gamma_1$  and  $\alpha$ .

Especially for short-channel transistors, the weak avalanche parameters also affect the behaviour of the output conductance for large  $V_{DS}$  values. The output conductance will increase again when the weak avalanche parameters are taken into account. If these parameters are not available, these output conductance values have to be neglected. Also the values in the corresponding  $I_D$ - $V_{DS}$  characteristic have to be neglected to eliminate their influence on the value of  $\theta_3$ .

- $I_D$ - $V_{DS}$ :

n-channel	:	$V_{DS} = 0 \dots V_{sup}$ (step 0.2 V). $V_{GS} = 3$ values starting above threshold, not above $V_{sup}$ $V_{BS} = 3$ values starting from 0 V to $-V_{sup}$
p-channel	:	$V_{DS} = -0 \dots -V_{sup}$ (step -0.2 V). $V_{GS} = 3$ values starting below threshold, not below $-V_{sup}$ $V_{BS} = 3$ values starting from 0 V to $V_{sup}$

Determination of  $\theta_3$ .

## 12.9.1 Scaling of Parameters

Using the formulae of chapter 12.2 it is possible to calculate a parameter set for a process, given the parameter set of typical transistors of this process. To accomplish this, transistors of different lengths, widths and at different temperatures have to be measured. With the results of these measurements the sensitivities of the parameters on length, width and temperature can be found. In the formulae Eq. (12.90) (for  $\alpha$ ) and Eq. (12.98) the length dependence term contains an exponent. This exponent was introduced to be able to distinguish n- and p-channels. Out of measurements in C3DM a different behaviour of these parameters with the length was found.

For n-channels :  $\eta_\alpha = 0$  and  $\eta_\zeta = 0.5$

For p-channels :  $\eta_\alpha = 1$  and  $\eta_\zeta = 1$

During the determination of a parameter set the exponents of the two formulae are best kept constant. Optimising these exponents can lead to strange results and can become very time consuming.

Using the new parameters  $W_{DOG}$  and  $f_{\theta_1}$  generally results in better modelling accuracy. A good strategy is to keep  $W_{DOG}$  fixed at the value calculated from the minimum design rules, i.e. the contact dimension plus two times the minimum OD-CO spacing. The parameter  $f_{\theta_1}$  must be optimized. Care must be taken that the reference transistor is chosen in such a way that  $W_{ER} \geq W_{EDOG}$ .

For the determination of a geometry-scaled parameter set a three-step procedure is recommended:

1. determine minisets ( $V_{T0}$ ,  $\beta$ , ...) for all measured devices, as explained above.
2. the width and length sensitivity coefficients are optimized by fitting the appropriate scaling rules to these miniset parameters.
3. finally the width and length sensitivity coefficients are optimized by fitting the result of the scaling rules and current equations to the measured currents of all devices simultaneously.

Note that this extraction procedure is implemented in IC-CAP, which is the standard parameter extraction tool within Philips.

Since the development of MOST model 9, parameter sets have been determined for several processes (e.g. C200, C150, C100 and C075). These can be found in the Design Manuals. For all processes good results have been obtained.

## 12.9.2 Parameter extraction 1/f noise

### Devices

Selection of geometries suitable for the 1/f noise measurements is done as follows:

- because of the sample-to-sample spread, inherent to 1/f noise in MOSFETS, one always has to measure a large number of devices.
- because this sample-to-sample spread increases inversely proportional to the device area, one should use sufficiently large devices (area larger than  $\sim 50\mu\text{m}^2$ ).
- use wide and short devices to keep the noise measurable (the measured noise is proportional to  $W/L^3$ ).
- “very wide” devices (eg. 100/1, 400/0.25, etc.) may be used to get some data around or even below  $V_{TO}$ , where it is difficult to perform measurements on standard geometries.
- especially when the devices are to be packaged, a gate protection is recommended.

### Bias conditions

It suffices to measure data as a function of  $V_{GS}$  in the saturation regime, with  $V_{DS} = V_{supply}$ , because the saturation region is the most important region for circuit simulation. But of course data in the linear regime may also be taken into account in parameter extraction.

### Parameter extraction

The parameter extraction strategy is as follows:

- Fit a  $A \cdot \frac{1}{f} + B$  relationship to the measured drain current noise spectra. This yields, for every spectrum, the coefficient  $A$ , which is the (modelled) drain current noise spectral density at  $f = 1$  Hz.
- Use the measured  $g_m$  to calculate the input-referred noise voltage spectral density at 1 Hz by dividing  $A$  by  $g_m^2$ .

- Adjust the three noise parameters  $N_{FAR}$  ,  $N_{FBR}$  , and  $N_{FCR}$  to fit the data of the input-referred noise of all measured geometries simultaneously. For  $NFMOD = 0$  , the  $N_{FR}$  parameter should be fitted to the measurements at low gate overdrive and in saturation. For  $NFMOD = 1$  , one should be able to fit the entire bias range.

## 12.10References

- [1] Klaassen, F.M., *Compact models for circuit simulation*, Springer, Vienna, chapter 7: Models for the enhancement - type MOSFET (1989)
- [2] Klaassen, F.M., *Compact models for circuit simulation*, Springer, Vienna, chapter 6: MOSFET - physics (1989)
- [3] Wright, G.T., *Physical and CAD models for the VLSI mosfet*, IEEE Trans. on Electron Devices, vol ED-34, page 823 (1987)
- [4] Oh, S.Y., Ward D.E. and Dutton R.W., *Transient analysis of MOS transistors*, IEEE Journal Solid-State Circuits, Vol. SC-15, page 636 (1980)
- [5] A.J. Scholten and D.B.M. Klaassen, *Geometrical scaling of  $\theta_1$  in MOS Model 9*, Nat. Lab. Report 6992
- [6] A.J. Scholten and D.B.M. Klaassen, *Anomalous geometry dependence of source/drain resistance in narrow-width MOSFETs*, Proc. IEEE 1998 Int. Conference on Microelectronic Test Structures Vol. II, March 1998
- [7] Kwok K. Hung *et al.*, IEEE Trans El. Dev. Vol. 37, No. 3, March 1990
- [8] Kwok K. Hung *et al.*, IEEE Trans El. Dev. Vol. 37, No. 5, May 1990
- [9] A.J. Scholten and D.B.M. Klaassen, *New  $1/f$  noise model in MOS Model 9, level 903*, Nat.Lab Unclassified Report, NL-UR 816/98
- [10] Bittel und Sturm, *Rauschen*, Springer, page 241, (1971)
- [11] Ir. A. v. Steenwijk, *Private communication*, (1994)
- [12] **Pstar** User Manual.



# **A Hyp functions**

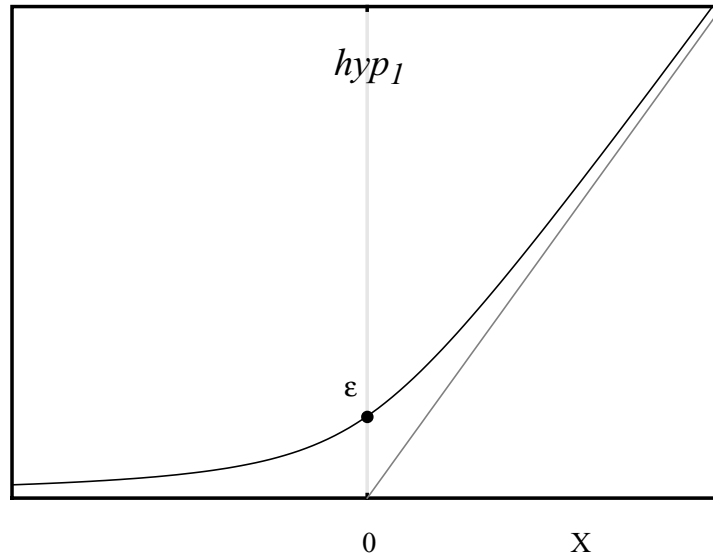


Figure 5:  $hyp_1(x;\epsilon) = \frac{1}{2} \cdot (x + \sqrt{x^2 + 4 \cdot \epsilon^2})$

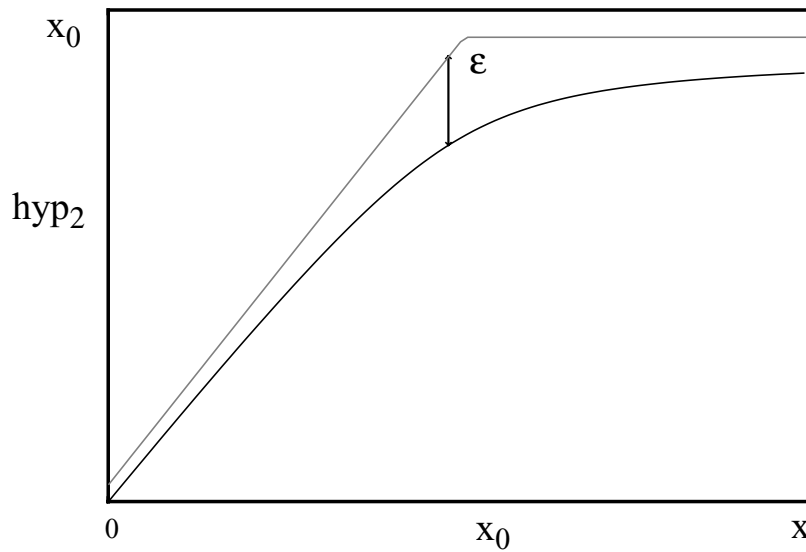


Figure 6:  $hyp_2(x;x_0;\epsilon) = x - hyp_1(x - x_0;\epsilon)$

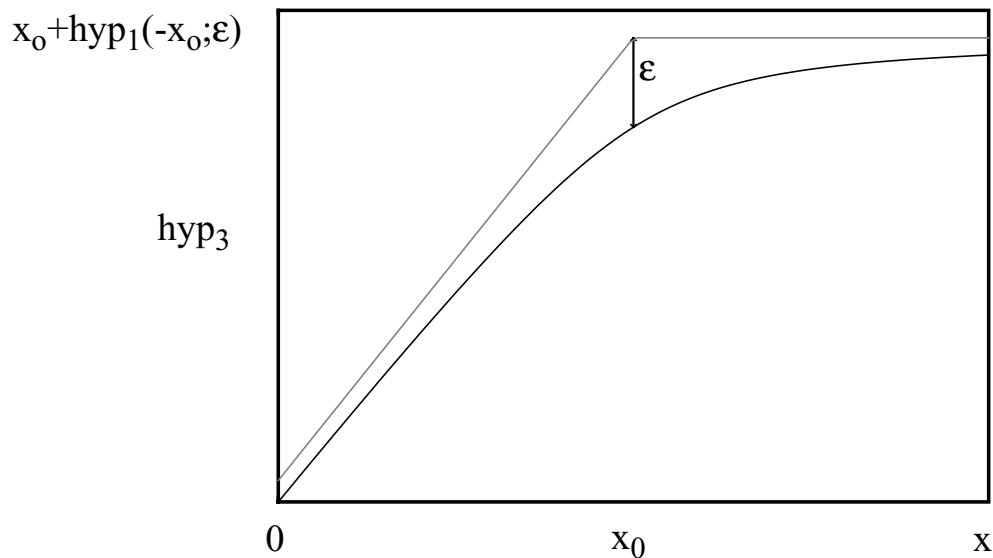


Figure 7:  $hyp_3(x; x_0; \epsilon) = hyp_2(x; x_0; \epsilon) - hyp_2(0; x_0; \epsilon)$  for  $\epsilon = \epsilon(x_0)$

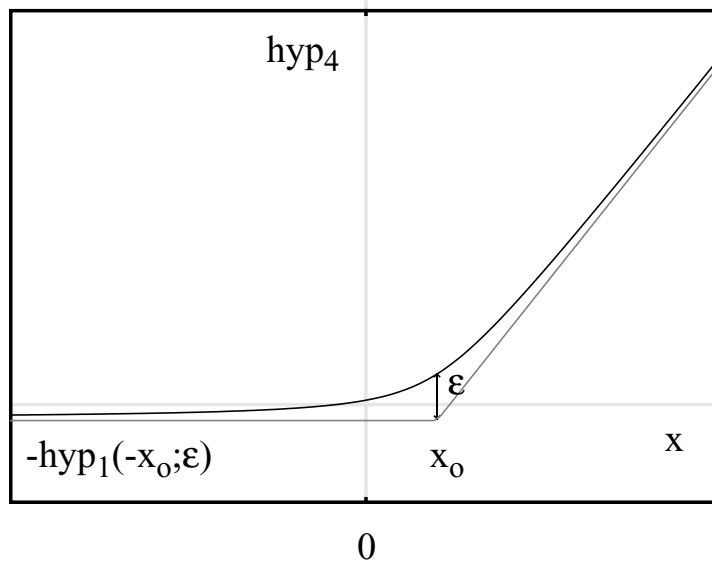


Figure 8:  $hyp_4(x; x_0; \epsilon) = hyp_1(x - x_0; \epsilon) - hyp_1(-x_0; \epsilon)$

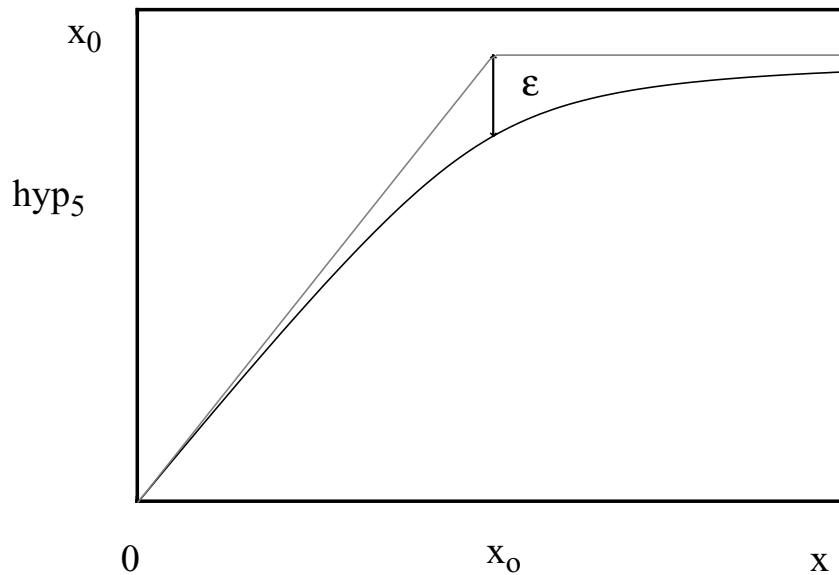


Figure 9:  $\text{hyp}_5(x; x_0; \epsilon) = x_0 - \text{hyp}_1\left(x_0 - x - \frac{\epsilon^2}{x_0}, \epsilon\right)$  for  $\epsilon = \epsilon(x_0)$

**The hypm-function:**

$$\text{hypm}[x, y; m] = \frac{x \cdot y}{(x^{2 \cdot m} + y^{2 \cdot m})^{1/(2 \cdot m)}} \quad (1.188)$$

# **B** Spectre Specific Information

## Imax, Imelt, Jmelt parameters

### Introduction

Imax, Imelt and Jmelt are Spectre-specific parameters used to help convergence and to prevent numerical problems. We refer in this text only to the use of Imax model parameter in Spectre with SiMKit devices since the other two parameters, Imelt and Jmelt, are not part of the SiMKit code. For information on Imelt and Jmelt refer to Cadence documentation.

### Imax model parameter

Imax is a model parameter present in the following SiMKit models:

- juncap and juncap2
- psp and pspnqs (since they contain juncap models)

In Mextram 504 (bjt504) and Modella (bjt500) SiMKit models, Imax is an internal parameter and its value is set through the adapter via the Spectre-specific parameter Imax.

In models that contain junctions, the junction current can be expressed as:

$$I = I_s \exp\left(\frac{V}{N \cdot \phi_{TD}} - 1\right) \quad (1.189)$$

The exponential formula is used until the junction current reaches a maximum (explosion) current Imax.

$$I_{max} = I_s \exp\left(\frac{V_{expl}}{N \cdot \phi_{TD}} - 1\right) \quad (1.190)$$

The corresponding voltage for which this happens is called Vexpl (explosion voltage). The voltage explosion expression can be derived from (1):

$$V_{expl} = N \cdot \phi_{TD} \log\left(\frac{I_{max}}{I_s}\right) + 1 \quad (1.191)$$

For  $V > V_{expl}$  the following linear expression is used for the junction current:

$$I = I_{max} + (V - V_{expl}) \frac{I_s}{N \cdot \phi_{TD}} \exp\left(\frac{V_{expl}}{N \cdot \phi_{TD}}\right) \quad (1.192)$$

The default value of the  $I_{max}$  model parameter for SiMKit is 1000A. The default value of  $I_{max}$  for Mextram 504 and Modella is 1A.  $I_{max}$  should be set to a value which is large enough so it does not affect the extraction procedure.

## Region parameter

Region is an Spectre-specific model parameter used as a convergence aid and gives an estimated DC operating region. The possible values of region depend on the model:

- For Bipolar models:
  - subth: Cut-off or sub-threshold mode
  - fwd: Forward
  - rev: Reverse
  - sat: Saturation.
  - off<sup>1</sup>
  -
- For MOS models:
  - subth: Cut-off or sub-threshold mode;
  - triode: Triode or linear region;
  - sat: Saturation
  - off<sup>1</sup>

For PSP and PSPNQS all regions are allowed, as the PSP(NQS) models both have a MOS part and a juncap (diode). Not all regions are valid for each part, but when e.g. region=forward is set, the initial guesses for the MOS will be set to zero. The same holds for setting a region that is not valid for the JUNCAP.

- For diode models:
  - fwd: Forward
  - rev: Reverse
  - brk: Breakdown
  - off<sup>1</sup>

---

<sup>1</sup>.Off is not an electrical region, it just states that the user does not know in what state the device is operating

## Model parameters for device reference temperature in Spectre

This text describes the use of the `tnom`, `tref` and `tr` model parameters in Spectre with SiMKit devices to set the device reference temperature.

A Simkit device in Spectre has three model parameter aliases for the model reference temperature, `tnom`, `tref` and `tr`. These three parameters can only be used in a model definition, not as instance parameters.

There is no difference in setting `tnom`, `tref` or `tr`. All three parameters have exactly the same effect. The following three lines are therefore completely equivalent:

```
model nmos11020 mos11020 type=n tnom=30
model nmos11020 mos11020 type=n tref=30
model nmos11020 mos11020 type=n tr=30
```

All three lines set the reference temperature for the `mos11020` device to 30 C.

Specifying combinations of `tnom`, `tref` and `tr` in the model definition has no use, only the value of the last parameter in the model definition will be used. E.g.:

```
model nmos11020 mos11020 type=n tnom=30 tref=34
```

will result in the reference temperature for the `mos11020` device being set to 34 C, `tnom=30` will be overridden by `tref=34` which comes after it.

When there is no reference temperature set in the model definition (so no `tnom`, `tref` or `tr` is set), the reference temperature of the model will be set to the value of `tnom` in the options statement in the Spectre input file. So setting:

```
options1 options tnom=23 gmin=1e-15 reltol=1e-12 \
  vabstol=1e-12 iabstol=1e-16
model nmos11020 mos11020 type=n
```

will set the reference temperature of the `mos11020` device to 23 C.

When no `tnom` is specified in the options statement and no reference temperature is set in the model definition, the default reference temperature is set to 27 C.

So the lines:

```
options1 options gmin=1e-15 reltol=1e-12 vabstol=1e-12 \
  iabstol=1e-16
model nmos11020 mos11020 type=n
```

will set the reference temperature of the mos11020 device to 27 C.

The default reference temperature set in the SiMKit device itself is in the Spectre simulator never used. It will always be overwritten by either the default "options tnom", an explicitly set option tnom or by a tnom, tref or tr parameter in the model definition.

